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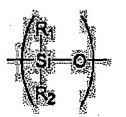
(54) ELECTROLYTE COMPOSITION, PHOTOELECTRIC CONVERSION ELEMENT AND PHOTOELECTRIC CELL

(57)Abstract:

PROBLEM TO BE SOLVED: To provide an electrolyte composition having excellent durabilities and charge transporting ability as well as a photoelectric conversion element and a photoelectric cell using the composition that have excellent durabilities and photoelectric conversion properties.

SOLUTION: This electrolyte composition comprises a siloxane compound having a repeating unit represented by general formula (1) [R1 is L1-Q01 (L1 is a bond or a divalent bonding group; Q01 is a substituent group when L1 is a bond; and Q01 is a hydrogen atom or a substituent group when L1 is a divalent bonding group); and R2 is L2-Q02 (L2 is a bond or a divalent bonding group; Q02 is a substituent group when L2 is a bond; and Q02 is a hydrogen atom or a substituent group when L2 is a divalent bonding group)], and having at least two substituent groups that can form a covalent bond when reacted with an electrophilic agent. The composition may comprise a polymer obtained by reacting the siloxane compound with an electrophilic agent having at least two leaving groups. The composition is

used for forming a photoconversion element and a photoelectric cell.







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(書誌+要約+請求の範囲)

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4J002

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5G301

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【Fターム(参考)】

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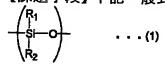
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(57)【要約】

【課題】耐久性及び電荷輸送能に優れた電解質組成物、並びにこの電解質組成物を用いたために優れた耐久性及び光電変換特性を示す光電変換素子及び光電池を提供する。 【課題手段】下記一般式(1):【化1】

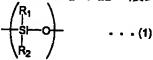


R₁: L₁-Q₀₁ R₂: L₂-Q₀₂

(ただし、 R_1 は L_1 - Q_{01} (L_1 は結合又は2価連結基を表し、 L_1 が結合を表すとき Q_{01} は置換基を表し、 L_1 が2価連結基を表すとき Q_{01} は水素原子又は置換基を表す。)を表し、 R_2 は L_2 - Q_{02} (L_2 は結合又は2価連結基を表し、 L_2 が結合を表すとき Q_{02} は置換基を表し、 L_2 が2価連結基を表すとき Q_{02} は水素原子又は置換基を表す。)を表す。)により表される繰り返し単位を含み、求電子剤と反応して共有結合を形成しうる置換基を少なくとも2つ有するシロキサン化合物を含有する電解質組成物、並びにこのシロキサン化合物と少なくとも2個の脱離基を有する求電子剤とを反応させて得られる重合体を含有する電解質組成物。また本発明の光電変換素子及び光電池は該電解質組成物を含む。

【特許請求の範囲】

【請求項1】下記一般式(1):【化1】



R₁: L₁-Q₀₁ R₂: L₂-Q₀₂

(ただし、 R_1 は L_1 - Q_{01} (L_1 は結合又は2価連結基を表し、 L_1 が結合を表すとき Q_{01} は置換基を表し、 L_1 が2価連結基を表すとき Q_{01} は水素原子又は置換基を表す。)を表し、 R_2 は L_2 - Q_{02} (L_2 は結合又は2

価連結基を表し、 L_2 が結合を表すとき Q_{02} は置換基を表し、 L_2 が2価連結基を表すとき Q_{02} は水素原子又は置換基を表す。)を表す。)により表される繰り返し単位を含み、求電子剤と反応して共有結合を形成しうる置換基を少なくとも2つ有するシロキサン化合物を含有することを特徴とする電解質組成物。

【請求項2】請求項1に記載の電解質組成物において、前記求電子剤と反応して共有結合を形成しうる置換基が塩基性基であることを特徴とする電解質組成物。

【請求項3】請求項2に記載の電解質組成物において、前記塩基性基に水素を付加してなる化合物の共役酸のpKaが3~15であることを特徴とする電解質組成物。

【請求項4】請求項2又は3に記載の電解質組成物において、前記塩基性基が置換若しくは無置換のピリジル基又は置換若しくは無置換のイミダゾリル基であることを特徴とする電解質組成物。

【請求項5】請求項1~4のいずれかに記載の電解質組成物において、前記シロキサン化合物が下記一般式(2):【化2】

$$Q_{1}-L_{11}-S_{12}-O-S_{14}-O-S_{18}-C_{12}-Q_{2} \qquad ... (2)$$

(ただし、 Q_1 及び Q_2 はそれぞれ独立に前記求電子剤と反応して共有結合を形成しうる置換基を表し、 $R_{11} \sim R_{16}$ はそれぞれ独立に置換若しくは無置換のアルキル基又は置換若しくは無置換のアリール基を表し、 L_{11} 及び L_{12} はそれぞれ独立に2価連結基を表し、nは1~1000の整数を表す。)により表されることを特徴とする電解質組成物。

【請求項6】請求項5に記載の電解質組成物において、前記シロキサン化合物が下記一般式(3):【化3】

$$\begin{pmatrix}
Q_{11} \\
N
\end{pmatrix} - L_{11} - Si - O \begin{pmatrix}
R_{13} \\
Si - O
\end{pmatrix} - Si - L_{12} - \begin{pmatrix}
Q_{21} \\
N
\end{pmatrix}$$
. . . (3)

(ただし、 Q_{11} 及び Q_{21} はそれぞれ独立に窒素原子と共に5又は6員環を形成する原子団を表し、 R_{11} ~ R_{16} はそれぞれ独立に置換若しくは無置換のアルキル基又は置換若しくは無置換のアリール基を表し、 L_{11} 及び L_{12} はそれぞれ独立に2価連結基を表し、 R_{11} 000の整数を表す。)により表されることを特徴とする電解質組成物。

【請求項7】請求項6に記載の電解質組成物において、前記Q₁₁及びQ₂₁がそれぞれ炭素原子、水素原子、窒素原子、酸素原子及び硫黄原子からなる群から選ばれる1種以上の原子により構成されることを特徴とする電解質組成物。

【請求項8】請求項6又は7に記載の電解質組成物において、前記5又は6員環がイミダゾール環又はピリジン環であることを特徴とする電解質組成物。

【請求項9】少なくとも2個の脱離基を有する求電子剤と、下記一般式(1):【化4】

R₁: L₁-Q₀₁ R₂: L₂-Q₀₂

(ただし、 R_1 は L_1 - Q_{01} (L_1 は結合又は2価連結基を表し、 L_1 が結合を表すとき Q_{01} は置換基を表し、 L_1 が2価連結基を表すとき Q_{01} は水素原子又は置換基を表す。)を表し、 R_2 は L_2 - Q_{02} (L_2 は結合又は2価連結基を表し、 L_2 が結合を表すとき Q_{02} は置換基を表し、 L_2 が2価連結基を表すとき Q_{02} は水素原

子又は置換基を表す。)を表す。)により表される繰り返し単位を含み、前記求電子剤と反応して共有結合を形成しうる置換基を少なくとも2つ有するシロキサン化合物とを反応させて得られる重合体を含有することを特徴とする電解質組成物。

【請求項10】請求項9に記載の電解質組成物において、前記シロキサン化合物が下記一般式(2): 【化5】

$$Q_{1} - L_{11} - S_{12}^{R_{11}} - O \begin{pmatrix} R_{13} \\ S_{1} \\ S_{1} \\ R_{12} \end{pmatrix} - S_{1}^{R_{15}} - C_{2}$$
 . . . (2)

(ただし、 Q_1 及び Q_2 はそれぞれ独立に前記求電子剤と反応して共有結合を形成しうる置換基を表し、 $R_{11} \sim R_{16}$ はそれぞれ独立に置換若しくは無置換のアルキル基又は置換若しくは無置換のアリール基を表し、 L_{11} 及び L_{12} はそれぞれ独立に2価連結基を表し、nは1~1000の整数を表す。)により表されることを特徴とする電解質組成物。

【請求項11】請求項10に記載の電解質組成物において、前記シロキサン化合物が下記一般式(3): 【化6】

$$\begin{pmatrix}
Q_{11} \\
N
\end{pmatrix} = \begin{pmatrix}
R_{11} \\
S_{12}
\end{pmatrix} = \begin{pmatrix}
R_{13} \\
S_{14}
\end{pmatrix} = \begin{pmatrix}
R_{15} \\
S_{15}
\\
S_{12}
\end{pmatrix} = \begin{pmatrix}
Q_{21} \\
N
\end{pmatrix}$$
(3)

(ただし、 Q_{11} 及び Q_{21} はそれぞれ独立に窒素原子と共に5又は6員環を形成する原子団を表し、 R_{11} \sim R_{16} はそれぞれ独立に置換若しくは無置換のアルキル基又は置換若しくは無置換のアリール基を表し、 L_{11} 及び L_{12} はそれぞれ独立に2価連結基を表し、 R_{11} の00の整数を表す。)により表されることを特徴とする電解質組成物。

【請求項12】請求項9~11のいずれかに記載の電解質組成物において、前記脱離基が脱離して生じるアニオンの共役酸のpKaが10以下であることを特徴とする電解質組成物。

【請求項13】請求項9~12のいずれかに記載の電解質組成物において、前記脱離基がそれぞれハロゲン原子、アルキルスルホニルオキシ基又はアリールスルホニルオキシ基であることを特徴とする電解質組成物。

【請求項14】請求項1~13のいずれかに記載の電解質組成物において、溶媒含有量が電解質組成物全体の10質量%以下であることを特徴とする電解質組成物。

【請求項15】請求項1~14のいずれかに記載の電解質組成物において、前記シロキサン化合物及び前記重合体以外にヨウ素塩及び/又はヨウ素を含有することを特徴とする電解質組成物。

【請求項16】請求項1~15のいずれかに記載の電解質組成物において、光電池に用いられることを 特徴とする電解質組成物。

【請求項17】導電層、感光層、電荷輸送層及び対極を有する光電変換素子において、前記電荷輸送層が請求項1~16のいずれかに記載の電解質組成物を含有することを特徴とする光電変換素子。

【請求項18】請求項17に記載の光電変換素子において、前記感光層が色素によって増感された半導体微粒子を含有することを特徴とする光電変換素子。

【請求項19】請求項18に記載の光電変換素子において、前記半導体微粒子が金属カルコゲニド微粒子を含むことを特徴とする光電変換素子。

【請求項20】請求項19に記載の光電変換素子において、前記金属カルコゲニド微粒子が酸化チタン 微粒子を含むことを特徴とする光電変換素子。

【請求項21】請求項17~20のいずれかに記載の光電変換素子において、前記色素が金属錯体色素及び/又はポリメチン色素であることを特徴とする光電変換素子。

【請求項22】請求項17~21のいずれかに記載の光電変換素子を用いた光電池。

(19)日本国特許庁 (JP)

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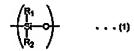
(54) 【発明の名称】 電解質組成物、光電変換素子及び光電池

(57)【要約】

【課題】 耐久性及び電荷輸送館に優れた電解質組成物. 並びにこの電解質組成物を用いたために優れた耐久性及び光電変換特性を示す光電変換素子及び光電池を提供する。

【課題手段】 下記一般式(1):

[{t1}



R1: L7:Q01 R2: L2:Q02

(ただし、RはL-Q.(Lは結合又は2価連結基を表し、Lが2価連結基を表し、Lが2価連結基を表すときQ.は置換基を表し、Lが2価連結基を表すときQ.は水素原子又は置換基を表す。)を表し、RはL-Q.(Lは結合又は2価連結基を表し、Lが2価連結基を表し、Lが2価連結基を表すときQ.は置換基を表し、Lが2価連結基を表すときQ.は水素原子又は置換基を表す。)を表す。)により表される繰り返し単位を含み、水電子剤と

反応して共有結合を形成しうる置換基を少なくとも2つ 有するシロキサン化合物を含有する電解質組成物. 並び にこのシロキサン化合物と少なくとも2個の脱離基を有 する求電子剤とを反応させて得られる重合体を含有する 電解質組成物。また本発明の光電変換素子及び光電池は 該電解質組成物を含む。 【特許請求の範囲】

【 節求項 1 】 下記一般式(1):

【化1】

$$\begin{array}{c}
\begin{pmatrix} R_1 \\ S_1 \\ R_2 \end{pmatrix} \cdots (1)$$

Ry: Ly-Qos Ry: Ly-Qos

(ただし、RはL-Q.(Lは結合又は2価連結基を表し、Lが2価連結基を表すときQ.は置換基を表し、Lが2価連結基を表すときQ.は水素原子又は置換基を表す。)を表し、RはL-Q.(Lは結合又は2価連結基を表し、Lが2価連結基を表し、Lが2価連結基を表すときQ.は置換基を表し、Lが2価連結基を表すときQ.は一般基を表す。)を表す。)により表される繰り返し単位を含み、水電子剤と反応して共有結合を形成しうる置換基を少なくとも2つ有するシロキサン化合物を含有することを特徴とする電解質組成物。

【論求項2】 論求項1 に記載の電解貿租成物において、前記求電子剤と反応して共有結合を形成しうる置換基が塩基性基であることを特徴とする電解質租成物。 【論求項3】 論求項2 に記載の電解質組成物におい

て、前記塩基性益に水素を付加してなる化合物の共役酸米

【請求項4】 請求項2 又は3 に記載の高解質組成物に おいて、前記塩基性基が置換若しくは無置換のビリジル 基又は置換若しくは無置換のイミダゾリル基であること を特徴とする電解質組成物。

【論求項5】 論求項1~4のいずれかに記載の電解質 組成物において 前記シロキサン化合物が下記一般式 (2):

[ft2]

(2)

10

(ただし、Q及びQはそれぞれ独立に前記求電子剤と反応して共有結合を形成しうる置換基を表し、R.~R.はそれぞれ独立に置換若しくは無置換のアルキル基又は置換若しくは無置換のアリール基を表し、L.,及びL.,はそれぞれ独立に2価連結基を表し、nは1~1000の整数を表す。)により表されることを特徴とする電解質組成20 物。

【請求項6】 請求項5に記載の電解質組成物において、前記シロキサン化合物が下記一般式(3): 【化3】

$$\begin{pmatrix} Q_{11} \\ N \end{pmatrix} = L_{11} + \begin{pmatrix} R_{10} \\ Si \end{pmatrix} + \begin{pmatrix} R_{10} \\ Si \end{pmatrix} + \begin{pmatrix} R_{10} \\ Si \end{pmatrix} + \begin{pmatrix} Q_{21} \\ N \end{pmatrix} + \begin{pmatrix} Q_{21}$$

(ただし、Q.及びQ.はそれぞれ独立に窒素原子と共に 5又は6員環を形成する原子団を表し、R.、~R.はぞれ 30 ぞれ独立に置換若しくは無置換のアルキル基又は置換若 しくは無置換のアリール基を表し、L.及びL.はそれぞれ独立に2 価連結基を表し、rは1~1000の整数を表す。)により表されることを特徴とする電解質組成物。【簡求項7】 節求項6に記載の電解質組成物において、前記Q.及びQ.がそれぞれ炭素原子、水素原子、窒素原子、酸素原子及び硫黄原子からなる群から遺ばれる1種以上の原子により構成されることを特徴とする電解質組成物。

【論求項8】 請求項6又は7に記載の電解質組成物に 40 おいて、前記5又は6員環がイミダゾール環又はピリジン環であることを特徴とする電解質組成物。

【曽水項9】 少なくとも2個の脱離基を有する求電子 剤と、下記一般式(1):

[化4]

$$\begin{array}{c}
\begin{pmatrix} R_1 \\ S_1 \\ R_2 \end{pmatrix} \qquad \dots (1)$$

Re: La-Clos Re: La-Clos

(ただし、RはL-Q1(Lは結合又は2価連結益を表し、Lが2価連結益を表すときQ1は水素原子又は置換益を表し、Lが2価連結益を表すときQ1は水素原子又は置換益を表す。)を表し、RはL-Q1(Lは結合又は2価連結基を表し、Lが2価連結基を表すときQ1は型換益を表し、Lが2価連結基を表すときQ1は水素原子又は置換基を表す。)を表す。)により表される繰り返し単位を含み、前記求電子剤と反応して共有結合を形成しうる置換基を少なくとも2つ有するシロキサン化合物とを反応させて得られる宣合体を含有することを特徴とする電解質組成物。

【節求項10】 節求項9に記載の電解質組成物において、 前記シロキサン化合物が下記一般式(2): 【化5】

http://www6.ipdl.jpo.go.jp/tjcontenttrns.ipdl?N0000=21&.../;%3e;%3e%3a%3a%3e;=/////

(ただし、Q及びQはそれぞれ独立に前記求電子剤と反応して共有結合を形成しうる置換基を表し、R,~R,は それぞれ独立に置換若しくは無置換のアルキル差又は置*

【論水項11】 論永項10に記載の電解質組成物において、前記シロキサン化台物が下記一般式(3): 【化6】

$$\begin{pmatrix} Q_{11} \\ N \end{pmatrix} - L_{11} - \begin{pmatrix} R_{13} \\ S_{1} \\ R_{12} \end{pmatrix} - \begin{pmatrix} R_{13} \\ S_{1} \\ R_{16} \\ R_{16} \end{pmatrix} - \begin{pmatrix} R_{13} \\ R_{16} \\ R_{16} \\ R_{16} \end{pmatrix} - \begin{pmatrix} Q_{21} \\ R_{16} \\ R_{16} \\ R_{16} \end{pmatrix} - \dots (3)$$

(ただし、Q.及びQ.はそれぞれ独立に窒素原子と共に5又は6貝環を形成する原子団を表し、R.、~R.はぞれぞれ独立に置換苦しくは無置換のアルキル基又は置換若しくは無置換のアリール基を表し、L.及びL.はそれぞれ独立に2価連結基を表し、Rは1~1000の整数を表す。)により表されることを特徴とする電解質組成物。

【 請求項12】 請求項9~11のいずれかに記載の電解費 組成物において、前記脱離益が脱離して生じるアニオン の共役敵のjkaが10以下であることを特徴とする電解質 組成物。

【請求項13】 請求項9~12のいずれかに記載の電解質 組成物において、前記脱離益がそれぞれハロゲン原子、 アルキルスルホニルオキン益又はアリールスルホニルオ キン益であることを特徴とする電解質組成物。

【請求項14】 請求項1~13のいずれかに記載の電解質組成物において、溶媒営有量が電解質組成物全体の10質量%以下であることを特徴とする電解質組成物。

【請求項15】 請求項1~14のいずれかに記載の電解質組成物において、前記シロキサン化合物及び前記重合体 30以外にヨウ素塩及び/又はヨウ素を含有することを特徴とする電解質組成物。

【論求項16】 論求項1~15のいずれかに記載の電解質 組成物において、光電池に用いられることを特徴とする 電解質組成物。

【請求項17】 導電層、感光層、電荷輸送層及び射極を 有する光電変換素子において、前記電荷輸送層が請求項 1~16のいずれかに記載の電解質組成物を含有すること を特徴とする光電変換素子。

【論求項19】 論求項18に記載の光電変換素子において、前記半導体微粒子が金属カルコゲニド微粒子を含むことを特徴とする光電変換素子。

【請求項20】 請求項19に記載の光電変換素子において、前記金属カルコゲニド歳粒子が酸化チタン歳粒子を含むことを特徴とする光電変換素子。

リメチン色素であることを特徴とする光電変換素子。 【詰求項22】 詰求項17~21のいずれかに記載の光電変 換素子を用いた光電池。

【発明の詳細な説明】

[0001]

【発明の属する技術分野】本発明は、耐久性及び電荷輸送能に優れた電解質組成物、並びにこの電解質組成物を用いたために優れた耐久性及び光電変換特性を示す光電20 変換素子及び光電池に関する。

[0002]

【従来の技術】従来から電池、キャパンター、センサー、表示素子、記録素子等の電気化学的素子の電解質として、溶媒に電解質塩を溶解した液状電解質組成物(電解液)が用いられてきた。しかしながら、このような液状電解質組成物を用いた電気化学的素子においては、長期間の使用又は保存の間に該組成物が過洩することがあり、信頼性に欠ける。

【0003】Nature、第352巻、第737~740頁、1991年、米国特許4927721号等は色素により増感した半導体機位于を用いた光電変換素子及びこれを用いた光電気化学電池を開示しているが、これらにおいても電荷輸送層に被伏電解質組成物を用いているため、長期間の使用又は保存の間に該組成物が扇洩又は枯渇し、光電変換効率が着しく低下したり、案子として機能しなくなる場合がある。

【0004】とのような状況下、約 93/20565号は固体 電解質を用いた光高変換素子を提案した。また日本化学 会誌、7、484頁 (1997)、特開平7-288142号、Solid Sta te Ionics、89、263 (1986)及び特開平9-273立号は、架 續ポリエチレンオキサイド系高分子化合物を用いた固体 電解質を含む光電変換素子を提案した。しかしながら、 これらの固体電解質を用いた光高変換素子は光電変換特 性、特に短格電流密度が不十分であり、加えて耐久性も 十分ではない。

【0005】また、電解資組成物の超速及び枯渇を防止 し光電変換素子の耐久性を向上させるために、ビリジニ ウム塩、イミダゾリウム塩、トリアゾリウム塩等を用い る方法が開示されている(WO 95/18456号、特開平8-259 543号、電気化学、第65巻、11号、923頁 (1997年) (4)

等)。これらの塩は富温 (25°C付近) において溶融状態 にあり、室温溶融塩と呼ばれる。この方法では水や有機 溶媒等の溶媒が不要或いは少量で済むため、電池の耐久

性が向上する。しかしながら、これらの室温溶融塩を用 いた光常変換素子は特に開放電圧が低く、光電変換効率 が良くない。

[0006]

【発明が解決しようとする課題】従って本発明の目的 は、耐久性及び電向輸送能に優れた電解質組成物、並び にこの電解質組成物を用いたために優れた耐久性及び光 10 電変換特性を示す光電変換索子及び光電池を提供すると とである。

[0007]

【課題を解決するための手段】上記目的に鑑み鋭意研究 の結果、本発明者は、特定の繰り返し単位を含むシロキ サン化合物を含有する電解貿組成物。並びに該シロキサ ン化合物を求電子剤と反応させて得られる宣合体を含有 する電解質組成物は優れた電筒輸送能及び耐久性を示す ことを発見し、本発明に想到した。

一般式(1):

【化7】

R1: LT-Q01 الي: لي- ال

(ただし、RはL-Q」(Lは結合又は2価連結基を表 し、しが結合を表すときひ。は置換基を表し、し、が2価 連結基を表すときる。は水素原子又は置換基を表す。) を表し、R.はL.-Q. (しは結合又は2価連結基を表し、 しが結合を表すときな」は置換益を表し、しか2 価連結 基を表すとき0.は水素原子又は置換基を表す。)を表 す。) により表される繰り返し単位を含み、求電子剤と 反応して共有結合を形成しうる置換基を少なくとも2つ 有するシロキサン化合物を含有することを特徴とする。

【0009】また、本発明の第二の電解質組成物は少な米

*くとも2個の脱離基を有する求電子剤と、上記一般式 (1)により表される繰り返し単位を含み、求電子剤と反 応して共有結合を形成しうる置換基を少なくとも2つ有 するシロキサン化合物とを反応させて得られる重合体を 含有することを特徴とする。

【0010】本発明の第一及び第二の電解質組成物は光 電池に好ましく用いることができる。本発明の光電変換 素子は導气層、感光層、電荷輸送層及び対極を有し、該 電荷輸送層が上記第一の電解質組成物又は第二の電解質 組成物を含有することを特徴とする。本発明の光電池は この光電変換素子を用いたものである。

【0011】本発明では下記条件を満たすことにより、 一層優れた耐久性又は電荷輸送能を有する電解質組成 物。並びに一層優れた耐久性及び光電変換特性を示す光 電変換索子及び光電池が得られる。

【0012】(1)第一及び第二の電解質組成物におい て. 求電子剤と反応して共有結合を形成しうる置換基は 塩基性基であるのが好ましく、この塩基性基は特に好ま しくは置換着しくは無置換のピリジル甚又は置換若しく 【0008】即ち、本発明の第一の電解質組成物は下記 20 は無置換のイミダゾリル甚である。 設塩基性基に水素を 付加してなる化合物の共役酸のpkaは3~15であるのが 好ましい。

> 【0013】(2)第一及び第二の電解質組成物に用いる シロキサン化合物は下記一般式(2)により表されるのが 好ましく、下記一般式(3)により表されるのがより好ま

[128]

$$Q_{1} = \begin{pmatrix} R_{11} & R_{15} & R_{15} \\ S_{1} & S_{1} & S_{1} & S_{1} \\ R_{12} & R_{14} & R_{15} \end{pmatrix} \begin{pmatrix} R_{15} & R_{15} \\ R_{15} & R_{15} \end{pmatrix}$$
 (2)

一般式(2)中、Q及びQはそれぞれ独立に上記求電子創 と反応して共有結合を形成しうる置換益を表し、R₄₁~R ・・はそれぞれ独立に置換若しくは無置換のアルキル基又 は置換着しくは無置換のアリール基を表し、しょ及びしょ はそれぞれ独立に2価連結益を表し、nは1~1000の整 数を表す。

(it9)

$$\begin{pmatrix}Q_{11}\\N\end{pmatrix} - L_{11} - \begin{pmatrix}R_{12}\\Si-Q\\R_{12}\end{pmatrix} - \begin{pmatrix}R_{13}\\Si-Q_{21}\\R_{16}\end{pmatrix} - \begin{pmatrix}Q_{21}\\N\end{pmatrix} - \dots (3)$$

30

一般式(3)中、Q、及びQ、はそれぞれ独立に窒素原子と 共に5又は6員環を形成する原子団を表し、R.1~R.は それぞれ独立に置換若しくは無置換のアルキル益又は置 換若しくは無置換のアリール基を表し、し、及びし、はそ れぞれ独立に2価連結基を表し、nは1~1000の整数を

【0014】(3)第一及び第二の電解質組成物におい て、一般式(3)中の0、及び0、はそれぞれ炭素原子、水 50 素原子、窒素原子、酸素原子及び硫黄原子からなる群か 5週ばれる1種以上の原子により構成されるのが好まし Ļ,

【0015】(4)第一及び第二の電解質組成物におい て、一般式(3)中のQ、及びQ、がそれぞれ窒素原子と共 に形成する5又は6貝環はイミダゾール環又はビリジン 環であるのが特に好ましい。

【0018】(5)第二の電解質組成物において、求電子

http://www6.ipdl.jpo.go.jp/tjcontenttrns.ipdl?N0000=21&.../;%3e;%3e%3a%3a%3e;=/////

剤が有する脱離基が脱離して生じるアニオンの共役酸の pkaは10以下であるのが好ましい。

【0017】(6)第二の電解質組成物において、求電子 剤が有する脱離基はそれぞれハロゲン原子、アルキルス ルホニルオキシ基又はアリールスルホニルオキシ基であ るのが好ましい。

【0018】(7)第一及び第二の電解質組成物の溶媒含 有量は電解質組成物全体の10質量%以下であるのか特に 好ましい。

【0019】(8)第一及び第二の電解質組成物は上記シロキサン化合物及び上記重合体以外にヨウ素塩及び/又はヨウ素を含有するのが好ましい。

【0020】(9)光電変換素子の感光層は色素によって 地感された半導体微粒子を含有するのが好ましい。この 半導体微粒子は金属カルコゲナイド微粒子を含むのが好ましく、金属カルコゲナイド微粒子は酸化チタン微粒子 を含むのが好ましい。また、色素は金属蜡体色素及び/ 又はポリメチン色素であるのが好ましい。

[0021]

【発明の実施の形態】[1]電解質組成物 本発明の第一の電解質組成物は後述する特定のシロキサン化合物を含有する。また、本発明の第二の電解質組成

物はこのシロキサン化合物を少なくとも2個の脱離基を有する求電子剤と反応させて得られる重合体を含有する。本発明の第二の電解質組成物は流動性を殆ど示さず、耐久性及び電荷輸送能に優れている。本発明の第一及び第二の電解質組成物は更に電解質塩、溶媒等を含有してもよい。以下、本発明の第一及び第二の電解質組成物の各構成要素について評述する。

【0022】(A)シロキサン化合物

本発明の第一及び第二の電解質組成物に用いるシロキサン化合物は、下記一般式(1)により表される繰り返し単位を含み、且つ求電子剤と反応して共有結合を形成しうる置換基を少なくとも2つ有する。本発明の第二の電解質組成物においては、このシロキサン化台物は求電子剤によりアルキル化、4級化等の修飾を受ける。

[{£10}

$$\begin{pmatrix}
R_1 \\
S_1 - O \\
R_2
\end{pmatrix} \qquad \cdots \qquad (1)$$

Ra: La-Qua Ra: La-Qua

【0023】一般式(1)中、RはL-Q,を表し、RはL-Q。を表す。ここで、Lは結合又は2価連結益を表し、Lが2価連結基を表し、Lが2価連結基を表すときQ。は水素原子又は置換基を表す。また、Lは結合又は2価連結基を表し、Lが結合を表すときQ。は置換基を表し、Lが2価連結基を表すときQ。は置換基を表し、Lが2価連結基を表すときQ。は水素原子又は置換益を表す。シロキサン化合物は一般式(1)

により表される繰り返し単位を1つ含んでも複数含んで もよく、複数含む場合は各繰り返し単位中のR及びRは それぞれ同じでも異なっていてもよい。

【0024】 L. 又はL.が2価連結基を表す場合。その例としてはアルキレン基、アルケニレン基、アリーレン基、-0-、-S. -O-、-MR'- (R'は水素原子又はアルキル芸)、-50。、-SiR''R'''- (R''及びR'''はそれぞれアルキル基、アリール基、アルコキシ 益又はアリールオキン芸)、これちの組み合わせ等が挙げられ、中でも-(CH)。-、-O、-(OOH CH)。-、-(OOH CH)。-O-、-(OOH CH)。-O-、-(OOH CH)。-O-、-(OOH CH)。-O-、-(OOH CH)。-O-、-(OOH CH)。-O-、-(OOH CH)。-O)。-、-(OOH CH)。-O)。-、-(OOH CH)。-(Si(OH))。-O)。- 及び-O-(OH)。-(Si(OH))。-O)。-が好ましい。なお町、配はそれぞれ1~20の整数を表す。

【0025】ひ、及びひ、が置換基を表す場合、好ましい 置換基の例としてはアルキル基 (直鎖状、分岐状又は環 状であってよく、例えばメチル基、エチル基、n-プロビ ル基、イソプロビル基、t-ブチル基、n-オクチル基、エ イコシル基、2-クロロエチル基、2-シアノエチル基、2-20 エチルヘキシル基、シクロヘキシル基、シクロベンチル 基.4-n--ドデンルシクロヘキシル基等)、アリール基 (例えばフェニル基、p-トリル基、ナフチル基、p-クロ ロフェニル基等)、ヘテロ環基(好ましくは5叉は6貝 の置換又は無置換の芳香族へテロ環化合物又は非芳香族 ヘテロ環化合物から1個の水素原子を取り除いてなる1 価の益であり、例えば2-ブリル基、2-チエニル益。2-ビ リミジニル基. 2-ピリジル基、4-ピリジル基、1-イミダ ゾリル基等)、ハロゲン原子(例えば塩素原子、臭素原 子、ヨウ素原子等)、シアノ基、ニトロ基、水酸盐、ア 30 ルコキシ基(例えばメトキシ基、エトキシ基、イソプロ ポキシ基、t-ブトキシ基。n-オクチルオキシ基。2-メト キシエトキシ益. -O(Ch, Ch, O), Ch, 等)、シリルオキシ 基(例えばトリメチルシリルオキシ基_{、t}_ブチルジメチ ルシリルオキシ益、トリメトキシシリルオキシ益等)、 アンルオキシ基(例えばホルミルオキン基、アセチルオ キシ芸、ピバロイルオキシ芸、ステアロイルオキシ基、 ベンゾイルオキシ基、p-メトキシフェニルカルボニルオ キシ基等)、カルバモイルオキシ基(例えばN,N-ジメチ ルカルバモイルオキシ基、N.N-ジェチルカルバモイルオ 40 キシ基、モルホリノカルボニルオキシ基、N.N-ジ-n-オ クチルアミノカルボニルオキシ基、N-n-オクチルカルバ モイルオキシ芸等)、アルコキシカルボニルオキシ基 (例えばメトキシカルボニルオキシ益。 エトキシカルボ ニルオキシ基. t-ブトキシカルボニルオキシ基. n-オク チルカルボニルオキシ基等)、アリールオキシカルボニ ルオキシ基 (例えばフェノキシカルボニルオキシ基、p-メトキシフェノキシカルボニルオキシ芸、p-n-ヘキサデ シルオキシフェノキシカルボニルオキン基等)、アミノ 基(例えばアミノ基、メチルアミノ基、ジメチルアミノ

50 基. アニリノ益. N-メチルアニリノ益. ジフェニルアミ

ノ益等)、アシルアミノ益(例えばホルミルアミノ基、 アセチルアミノ益、ピパロイルアミノ益、ラウロイルア ミノ益、ベンゾイルアミノ益、3,4,5-トリ-n-オクチル オキシフェニルカルボニルアミノ基等)、アミノカルボ ニルアミノ基 (例えばカルバモイルアミノ基、N,N-ジメ チルアミノカルボニルアミノ基、N.N-ジエチルアミノカ ルボニルアミノ益、モルホリノカルボニルアミノ益 等)、アルコキシカルボニルアミノ益(例えばメトキシ カルボニルアミノ基、エトキシカルボニルアミノ基、t-ブトキシカルボニルアミノ益、n-オクタデシルオキシカ 10 ルボニルアミノ益、N-メチルメトキシカルボニルアミノ 基等)、アリールオキシカルボニルアミノ基(例えばつ ェノキシカルボニルアミノ益、p-クロロフェノキシカル ボニルアミノ芸、m-n-オクチルオキシフェノキシカルボ ニルアミノ基等)、スルファモイルアミノ基 (例えばス ルファモイルアミノ基、N,N-ジメチルアミノスルホニル アミノ基、N-n-オクチルアミノスルホニルアミノ基 等)、アルキルスルホニルアミノ基(例えばメチルスル ホニルアミノ基、プチルスルホニルアミノ基等)、アリ ールスルホニルアミノ基(例えばフェニルスルホニルア 20 ミン益、2,3,5-トリクロロフェニルスルホニルアミノ 基、p-メチルフェニルスルホニルアミノ基等)、メルカ プト基、アルキルチオ基(例えばメチルチオ基 エチル チオ益、n-ヘキサデシルチオ基等). アリールチオ基 (例えばフェニルチオ基、p-クロロフェニルチオ基、p-メトキシフェニルチオ基等)、ヘテロ環チオ基(例えば 2-ベンゾチアゾリルチオ基、1-フェニルテトラゾール-5 -イルチオ益等)、スルファモイル基(例えばN-エチル スルファモイル益、N-(3-Fデンルオキシプロビル)スル ファモイル基. N,N-ジメチルスルファモイル基. N-アセ 30 チルスルファモイル基、N-ベンゾイルスルファモイル 基. N-(N'-フェニルカルバモイル)スルファモイル基 等)、アルキルスルフィニル基(例えばメチルスルフィ ニル芸、エチルスルフィニル基等)、アリールスルフィ ニル益(例えばフェニルスルフィニル益、p-メチルフェ ニルスルフィニル基等)、アルキルスルホニル基(例え ばメチルスルホニル基、エチルスルホニル基等)、アリ ールスルホニル益 (例えばフェニルスルホニル益、p-メ チルフェニルスルホニル益等)、アシル基(例えばアセ チル苺、ピパロイル基、2-クロロアセチル基、ステアロ イル苗、ベンゾイル基、p-n-オクチルオキシフェニルカ ルボニル基等)、アリールオキシカルボニル基(例えば フェノキシカルボニル基、0-クロロフェノキシカルボニ ル喆、n-ニトロフェノキシカルボニル芸、p-t-ブチルフ ェノキシカルボニル基等)、アルコキシカルボニル基 (何えばメトキシカルボニル基、エトキシカルボニル 基、t-ブトキンカルボニル基、n-オクタデシルオキシカ ルボニル基等)、カルバモイル基(倒えばカルバモイル

【0026】上記シロキサン化合物は求電子剤と反応し て共有結合を形成しうる置換基を2つ以上有する。 第一 及び第二の電解質組成物において、求電子剤と反応して 共有結合を形成しうる置換益は塩基性益であるのが好ま しい。ここで塩基性基とは、それに水素を付加してなる 化合物の共役酸のpkaが3以上の基を指す。この共役酸 のpKaは3~15であるのが好ましく、4~12であるのが より好ましい。このような塩基性基は、アミノ莓(ジメ チルアミノ基、ジエチルアミノ基、アニリノ基等)、含 窒素捜索環基(モルホリノ基、キヌクリジニル基. ピベ ラジニル基、ビベリジノ基、ピロリジノ基、イミダゾリ ル益、2-メチルイミダゾリル基、キノリル基、アクリジ ニル基、ビリジル基、2-メチルビリジル基、ジアザビシ クロウンデセニル基等) 又はグアニジノ基 (トリメチル グアニジノ基等) であるのが好ましく、含窒素複素環基 であるのがより好ましく、置換若しくは無置換のビリジ ル基又は置換若しくは無置換のイミダゾリル基であるの が特に好ましい。上記シロキサン化合物はこのような塩 基性基を一般式(1)により表される繰り返し単位中の側 鎖及び/又は末端に有してよい。この塩基性基を一般式 (1)により表される繰り返し単位中の側鎖に有する場 台、一般式(1)中のQ、及び/又はQ、が該塩基性基であ

【0027】本発明の第一及び第二の電解質組成物に用いるシロキサン化台物は、下記一般式(2)により表されるのが好ましく、下記一般式(3)により表されるのがより好ましい。

[fb11]

$$Q_{1} = \begin{pmatrix} R_{11} & R_{15} & R_{15} \\ S_{1} & S_{1} & S_{15} \\ R_{12} & R_{14} & R_{18} \end{pmatrix} \begin{pmatrix} R_{15} & R_{15} \\ R_{15} & R_{15} \\ R_{15} & R_{15} \end{pmatrix}$$

[{£12}

$$\begin{pmatrix} Q_{11} \\ W \end{pmatrix} = \begin{pmatrix} R_{11} \\ Si \\ R_{12} \end{pmatrix} \begin{pmatrix} R_{13} \\ Si \\ R_{14} \end{pmatrix} \begin{pmatrix} R_{13} \\ Si \\ R_{14} \end{pmatrix} \begin{pmatrix} Q_{21} \\ R_{14} \end{pmatrix} \qquad (3)$$

【0028】一般式(2)中、Q及びQはそれぞれ独立に 求電子剤と反応して共有結合を形成しうる置換益を表 す。この置換益中の求電子剤と反応する原子は好ましく は窒素原子、リン原子又は確黄原子であり、より好まし くは窒素原子又はリン原子であり、特に好ましくは窒素 原子である。Q及びQが表す置換基としては、アミノ 基.ホスフィノ基、復素環基、アルキルチオ基等が挙げ

11

【0029】一般式(2)中、R、~R、はそれぞれ独立に 置換若しくは無置換のアルキル基、又は置換若しくは無 置換のアリール芸を表す。R、~R。は好ましくは炭素数 1~10のアルキル基であり、より好ましくは炭素数1~ 3のアルキル益であり、特に好ましくはメチル益であ

【0030】上記な、な、及びR、~R。はそれぞれ置換 基を有していてもよい。該置換基の好ましい例として は、アルキル益(メチル益、エチル益、プロピル益、イ ソプロビル基、プチル基、ペンチル基、ヘキシル基、オ クチル基、2-エチルヘキンル基、t-オクチル基。デシル 基.ドデシル基.テトラデシル基、2-ヘキシルデシル 益、オクタデシル基、シクロヘキシル基、シクロベンチ ル益. 2-カルボキシエチル益、ベンジル基等). アルケ ニル基(ビニル基、アリル基等)、ハロゲン原子(ファ 素原子、塩素原子、臭素原子、ヨウ素原子等)。シアノ 益. アルコキシ益 (メトキシ基、エトキシ基、メトキシ エトキシ基等)、アリーロキシ基(フェノキシ基等)、 アルキルチオ基 (メチルチオ基、エチルチオ基等)、ア シル益(アセチル基、プロピオニル益、ベンゾイル基 等). スルホニル基(メタンスルホニル基、ベンゼンス ルホニル基等)、アシルオキシ基(アセトキシ基)ベン ゾイルオキシ益等)、スルホニルオキシ基(メタンスル ホニリオキシ基、トルエンスルホニルオキシ基等)、ホ スポニル基 (ジエチルホスホニル基等)、アミド基 (ア セチルアミノ益、ベンゾイルアミノ益等)、カルバモイ ル益(N,N-ジメチルカルバモイル基、N-フェニルカルバ モイル基等)、アリール基(フェニル基、トルイル基 等)、複素環盤(ピリジル基、イミダゾリル基、フラニ ル益等) 等が挙げられる。

【0031】一般式(2)中、し、及びし、はそれぞれ独立 に2価連結基を表す。この2価連結基の例としては、ア ルキレン基、アルケニレン基、アリーレン基、-0-、-S -、-CO-. -NR'- (R'は水素原子又はアルキル基を患

す).-SQ-、-STRR'-(R及びR'はそれぞれアルキル基又 はアリール基を表す)。 これらを2つ以上組み合わせて なる連結基等が挙げられる。

【0032】Lュ及びLュがアルキレン益、アルケニレン 基又はアリーレン基である場合、これらはハロゲン原子 (ブゥ素原子、塩素原子、臭素原子、ヨウ素原子等)、 水酸盐、アミノ盐、ニトロ盐、カルボキシル基。カルバ モイル基、スルホン酸基。スルホンアミド基、アシル基 (ホルミル基、アセチル益等)、アシルオキシ基、アシ ルアミノ基(アセトアミノ基、ベンズアミノ基等)、ア ルキル基、アルコキシ基(メトキシ基、エトキシ基、メ トキシエトキシ基等)、アコキシカルボニル基。アルキ ルスルホニル益、アリール益、アリールオキシ益(フェ ノキシ基等). アリールスルホニル基等の置換基を有し ていてもよい。

20 【0033】一般式(2)中、nは1~1000の登数を表す。 rは好ましくは1~500の整数であり、特に好ましくは1 ~100の整数である。nが1000よりも大きいと、イオン伝 導度及び求電子剤との反応性の低下を招く。

【0034】一般式(3)中、Q、及びQ、はそれぞれ独立 に窒素原子と共に5又は6員環を形成する原子団を表 す。Q、及びQ、は炭素原子、水素原子、窒素原子、酸素 原子及び硫黄原子からなる群から選ばれる 1 程以上の原 子により構成されるのが好ましい。

【0035】0.1及び0.1により形成される5又は6貝環 30 は不飽和環であるのが好ましい。5員環としてはピロリ ジン環、オキサゾール環、チアゾール環、イミダゾール 環、ビラゾール環、イソオキサゾール環、チアジアゾー ル環、オキサジアゾール環及びトリアゾール環が好まし く.チアゾール環、イミダゾール環及びトリアゾール環 がより好ましく、イミダゾール環が特に好ましい。6月 環としてはモルホリン環、ビベリジン環、ビリジン環、 ピリミジン環、ピリダジン環、ピラジン環及びトリアジ ン環が好ましく、ビリジン環が特に好ましい。

【0036】一般式(3)中のR:~R,, L:及びL:, 並 40 びにnは一般式(2)中のそれらと同義であり、好ましい筬 様も同様である。

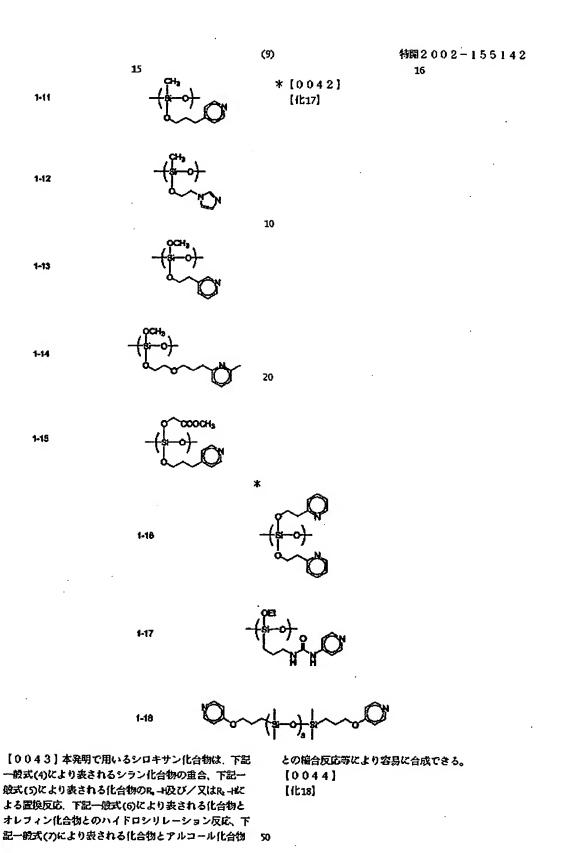
【0037】本発明の第一及び第二の電解質組成物に用 いるシロキサン化合物の具体例1-1~1-18を以下に示す が、本発明はそれらに限定されるものではない。

[0038]

[{t13}

http://www6.ipdl.jpo.go.jp/tjcontenttrns.ipdl?N0000=21&.../;%3e;%3e%3a%3a%3e;=/////

[116]



(10)

特開2002-155142

17 R₁ R₁ Si R₂ · · · (4) R₂

一般式(4)中、R、及びR、はそれぞれ独立にハロゲン原子又はアルコキン基を表す。

[0045]

[[12]

一般式(5)中、R.,及びR.,はそれぞれ独立にアルコキン 基又はアリールオキシ基を表す。

[0046] [fb20]

一般式(6)中のR、~R、及びrlは一般式(2)中のそれらと 同義であり、好ましい態様も同様である。

[0047]

[{£21}

$$a - s_{12} - (s_{14} - o) - s_{15} - a - c_{12}$$

$$R_{12} - (s_{14} - o) - s_{15} - a - c_{15}$$

$$R_{16} - a - c_{15}$$

一般式(7)中のR、~R、及びrは一般式(2)中のそれらと 同義であり、好ましい態様も同様である。

[0048](8)求電子剤

本発明の第二の電解質組成物に用いる求電子剤は少なく とも2個の脱離基を有する。該求電子剤は上記シロキサン化合物が有する「求電子剤と反応して共有結合を形成 しうる置換基」と反応し、この置換基をアルキル化、オニウム塩化、4級化等することにより直線状又は架績された重合体を形成する。

【0049】上記シロキサン化合物と求電子剤を反応させて得られる重合体の架構度を適度なものとするためには、影離基の数は2~4個であるのが好ましく、2個で 40

あるのが特に好ましい。脱離基の数が多いと架橋度が高くなり、その結果、膜質が硬くなりイオン伝導度が低下する。また、脱離基が脱離して生じるアニオンの共役酸のpKaは10以下であるのが好ましく、5以下であるのがより好ましい。

【0050】脱離基はそれぞれハロゲン原子、アルキル スルホニルオキシ基、アリールスルホニルオキシ基、ア シルオキシ基等であってよい。中でもハロゲン原子、ア ルキルスルホニルオキシ盆及びアリールスルホニルオキ 10 シ盆が好ましい。ハロゲン原子としては、ヨウ素原子、 **具素原子及び塩素原子が好ましく、ヨウ素原子及び臭素** 原子がより好ましい。アルキルスルホニルオキン益とし ては、メチルスルホニルオキシ基、クロロメチルスルホ ニルオキシ基及びパーフルオロアルキルスルホニルオキ シ基 (トリフルオロメチルスルホニルオキシ基等)が好 ましい。アリールスルホニルオキシ基としては、ベンゼ ンスルホニルオキシ基、p-トルエンスルホニルオキシ 基、p-クロロベンゼンスルホニルオキシ基及びp-ニトロ ベンゼンスルホニルオキシ基が好ましい。 アシルオキシ 20 基としては、水素原子の全部若しくは一部をファ素置換 したアルキルカルボニルオキシ基(トリフルオロメチル カルボニルオキン基等)及びアリールカルボニルオキシ 基 (p-フルオロフェニルカルボニルオキシ基等) が好ま 643.

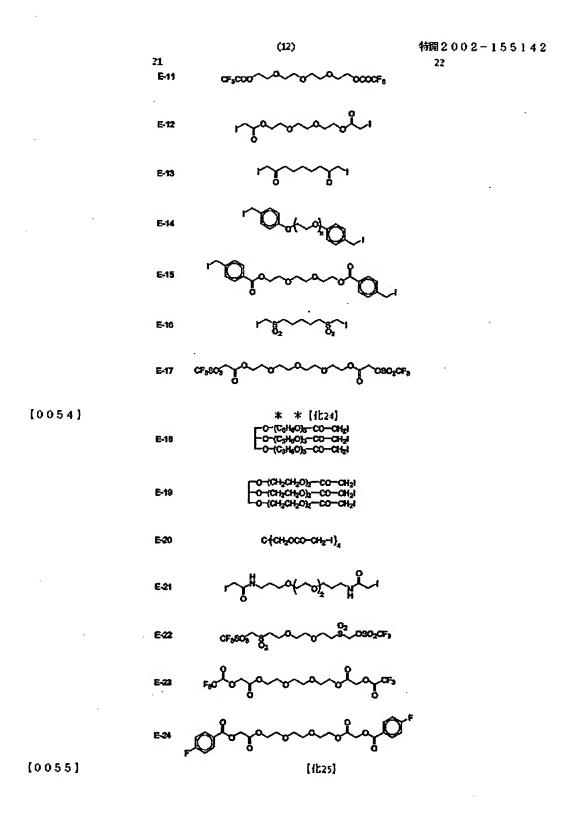
【0051】求電子剤の使用量は上記シロキサン化合物との反応速度、或いは生成する宣台体の分子量又は架循度に応じて任意に定めることができる。求電子剤の使用量は、シロキサン化台物が有する「求電子剤と反応して共有結合を形成しつる置換益」のモル数に対して好ましくは0.01~2当量、より好ましくは0.05~1.3当量、特に好ましくは0.1~1当量である。シロキサン化台物が有する求電子剤と反応して共有結合を形成しつる置換益のモル数が明確でない場合は、シロキサン化台物の質量に対する求電子剤の質量比は好ましくは1~100質量%であり、より好ましくは3~70質量%である。求電子剤は単独で用いても2程以上を併用してもよい。以下、本発明で使用可能な求電子剤の具体例E-1~E-27を示すが、本発明はそれちに限定されるものではない。

[0052]

[{k22}]

] :

	19 E-1	(II)	特開2002-155142 20
	E-2	~~ <u>~</u>	
	E-3	~~~·	
	5-4		•
	E-\$		•
	E-8	~~~	
	E-7 H ₂ O	-0^^^-O-00-O-0	+5
	E-0 H ₂ C(O)50 ₂ 0'	~~~~~~~ ~ ~~ ~ ~~ ~ ~~ ~ ~~ ~ ~~~ ~ ~~~~~~) —cn,
	E-8 CH	son-of-of-sonor ==	•
	E-10 CF ₆	,50,-01-01,50,20Fs n=8	
[0053]		[123]	



【0056】(C)重合反応

本発明の第二の電解質組成物に用いる重合体は、上記求電子剤とシロキサン化合物の宣合反応により得ることができる。詳しくは、求電子剤中の求電子部位と、シロキサン化合物中の該求電子剤と反応して共有結合を形成しうる置換基との間で起こるアルキル化反応、オニウム塩を形成する反応(例えば窒素の4級化反応)等により、それらを宣合させる。得られる宣合体の質量平均分子量は1000~100万であるのが好ましく、2000~50万であるのがより好ましい。

[0057] 重合反応は求電子剤及びシロキサン化合物の他に、後述する電解質塩が共存する条件下で行うのが好ましい。反応後に電解質塩を添加してもよいが、この場合、 重合体中に電解質塩を均一に分散させるのが困難であり好ましくない。

【0058】シロキサン化合物、求電子剤及び電解質塩を含む反応溶液を調製して重合反応を行う場合。シロキサン化合物の質量比は【シロキサン化合物+気解質塩+溶媒】を100質量%とすると、1~50質量%とするのが好ましく、3~30質量%とするのがより好ましい。シロキサン化合物が1質量%未満であると流動性が不充分となり、また60質量%を超えるとキャリア移動度が低下するので好ましくない。なお、シロキサン化合物は単独で用いても2種以上を併用してもよい。

【0059】(D)電解貿塩

電解質塩としては、例えば(a)I、とヨウ化物(LiI. Na I、KI、CSI、CaI、等の金属ヨウ化物、テトラアルキルアンモニウムヨーダイド、ビリジニウムヨーダイド、イミダゾリウムヨーダイド等の4級アンモニウムヨウ素塩等)との組み合わせ、(b)Br、と臭化物(LiBr、NaBr、KB 40 r、CsBr、CaBr、等の金属臭化物、テトラアルキルアンモニウムブロマイド、ビリジニウムブロマイド等の4級アンモニウム具素塩等)との組み合わせ、(c)金属錆体(フェロシアン酸塩ーフェリシアン酸塩やフェロセンーフェリシニウムイオン等)、(d)イオウ化合物(ボリ硫化ナトリウム、アルキルチオールーアルキルジスルフィド等)、(e)ビオロゲン色素やヒドロキノンーキノン等を用いることができる。中でも、I、と4級アンモニウムヨウ素塩との組み合わせが好ましい。電解質塩は混合して用いてもよい。

【0060】また、電解質塩としてEP718288、MD95/18456. J. Electrochem. Soc., Vol.143, No.10, 3099 (1996)、Inorq. Chem., 35, 1168~1178 (1996)、特別平8-259543号、電気化学、第65巻、11号、923頁 (1997年)等に記載されているビリジニウム塩、イミダゾリウム塩、トリアゾリウム塩等の溶融塩を使用することもできる。溶融塩電解質は耐久性及び電荷輸送能の両立という観点から特に好ましい。なお、ここでいう溶酸塩とは室温において液状であるか、又は低融点の塩であり、その融点20は100℃以下であるのが好ましく、室温付近であるのが特に好ましい。

【0061】本発明で好ましく用いることのできる溶融塩としては、下記一般式(Y-a)。 (Y-b)及び(Y-c)のいずれかにより表されるものが挙げられる。

[0062]

[1£26]

【0063】一般式(Y-a)中、Q.は窒素原子と共に5又は6員環の芳香族カチオンを形成する原子団を表す。Q.は炭素原子、水素原子、窒素原子、酸素原子及び硫黄原子からなる群から選ばれる1程以上の原子により構成されるのが好ましい。

【0064】Q.により形成される5貝環は、オキサゾール環、チアゾール環、イミダゾール環、ビラゾール環、デアジアゾール環、オキサジ環、イソオキサゾール環、チアジアゾール環、オキサジ 50 アゾール環、トリアゾール環、インドール環又はビロー (14)

ル環であるのが好ましく、オキサゾール環、チアゾール 環又はイミダゾール環であるのがより好ましく。オキサ ゾール環又はイミダゾール環であるのが特に好ましい。 Q」により形成される6貝環は、ビリジン環、ビリミジ ン環、ビリダジン環、ビラジン環又はトリアジン環であ るのが好ましく、ピリジン環であるのがより好ましい。 【0065】一般式(Y-b)中、A」は窒素原子又はリン原 子を表す。

【0066】一般式(Y-a)、(Y-b)及び(Y-c)中のR、~R 、。はそれぞれ独立に置換又は無置換のアルキル基(好ま 10 等)、アリール基(フェニル基、トルイル基等)、投索 しくは炭素原子数1~24. 直鎖状であっても分岐状であ っても、また環式であってもよく、例えばメチル益、エ チル益、プロビル基、イソプロビル益、ペンチル益、ヘ キシル基、オクチル基、2-エチルヘキシル基、t-オクチ ル基、デシル基、ドデシル基、テトラデシル基、2ペキ シルデシル基、オクタデシル基、シクロヘキシル基、シ クロペンチル基等)、或いは置換又は無置換のアルケニ ル基(好ましくは炭素原子数2~24. 直鎖状であっても 分岐状であってもよく、例えばビニル基、アリル基等) 又は炭素原子数2~18のアルケニル益であり、特に好ま しくは炭素原子数2~6のアルキル益である。

【0067】また、一般式(Y-b)中のR,~R,のうち2 つ以上が互いに連結してA、を含む非芳香族環を形成し てもよく、一般式(Y-c)中のR.~R.のうち2つ以上が 互いに連結して環構造を形成してもよい。

【0068】一般式(Y-a)、(Y-b)及び(Y-c)中のQ、及び R1~R,は置換基を有していてもよい。この置換基の好 ましい例としては、ハロゲン原子(F、C1、Br、I等)、 シアノ基、アルコキシ基(メトキシ基、エトキシ基、メ トキシエトキシ基、メトキシエトキシエトキシ益等)、 アリーロキシ苺(フェノキシ基等)、アルキルチオ基 (メチルチオ基、エチルチオ基等)、アルコキシカルボ ニル益(エトキシカルボニル基等)、炭酸エステル基 (エトキシカルボニルオキン基等) アシル基 (アセチ ル基、プロピオニル基、ベンゾイル基等)、スルホニル

基(メタンスルホニル基、ベンゼンスルホニル基等)、 アンルオキシ基(アセトキシ基、ベンゾイルオキシ基 等)、スルホニルオキシ苺(メタンスルホニルオキシ 基、トルエンスルホニルオキシ基等)、ホスホニル基 (ジエチルホスホニル基等)、アミド基(アセチルアミ ノ益、ベンゾイルアミノ益等)、カルバモイル益(N.N-ジメチルカルバモイル基等)、アルキル基(メチル基、 エチル基、プロビル基、イソプロビル基、シクロプロビ ル基.ブチル基.2-カルボキシエチル基、ベンジル基 環基(ピリジル基、イミダゾリル基、フラニル益等)、 アルケニル基 (ビニル基、1-プロペニル基等) シリル 基、シリルオキシ基等が挙げられる。

【0069】上記一般式(Y-a)~(Y-c)のいずれかにより 表される溶融塩は、Q、及びR、~R。のいずれかを介し て多量体を形成してもよい。

【0070】上記一般式(Y-a)~(Y-c)のいずれかにより 表される溶融塩は単独で使用しても2種以上混合して使 用してもよく、またヨウ化物イオンドを他のアニオンで を表し、より好ましくは炭素原子数2~18のアルキル基 20 置き換えた塩と混合して使用してもよい。Fを置き換え るアニオンとしては、ハロゲン化物イオン (CIT、Br 「等)、SON、BF。T. PF。T、ClO。T、(CF; SO;); NT、(CF; C F2 SO2)2 N° . CF2 SO2 ", OH SO2 ". CF2 COOT , PH4 B" , (CF2 S Q.)』で等が好ましい。より好ましくはSOY、BF。*. CF₂S Q 、 CF, COT 又は(CF, SQ,), N である。

> 【0071】また、LiIのような他のヨウ素塩やCF₂COOL 1、CF。COONa、LISON、NaSON等のアルカリ金属塩を添加 することもできる。アルカリ金属塩の添加量は、0.02~ 2 質量%程度とするのが好ましく、0.1~1 質量%とす るのが更に好ましい。

> 【0072】本発明で好ましく用いられる電解質塩の具 体例(Y1)~(Y29)を以下に挙げるが、それらは本発明を 限定するものではない。

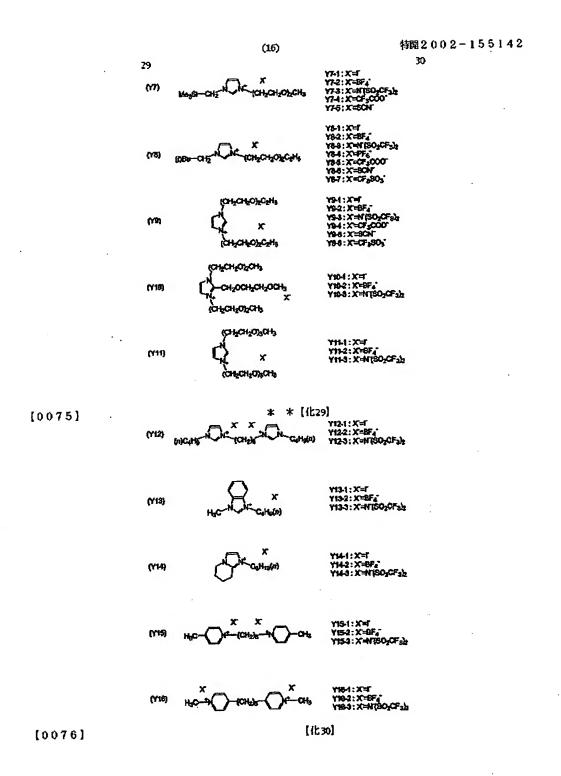
[0073] 【化27】

http://www6.ipdl.jpo.go.jp/tjcontenttrns.ipdl?N0000=21&.../;%3e;%3e%3a%3a%3e;=/////

27 (M)	(15)	特別2002-155142 28 Yt-1: X=F Yt-2: X=BF ₆ Yt-3: X=N(80 ₂ CF ₆) ₂ Yt-4: X=FF ₆
(12)	Carpon)	Y24; X=F Y22; X=BF4* Y23; X=N (302CF1)2 Y24; X=CF4COO* Y26; X=SCF* Y26; X=CF503*
(43)	CH ₂ CH ₃ x	Y3-1 : X=T Y3-2 : X=BF₄ [†] Y3-3 : X=NTSO ₂ CF ₃) ₂
(Y4)	C4+6(v)	Y4-1 : X=F Y4-2 : X=BF-4 Y4-3 : X=N-150 ₂ CF ₃ b ₂
(142)	C ₆ H ₆ (n)	Y5-1 : X'=F Y6-2 : X'=BF4" Y6-3 : X'=N'(8O ₂ CF4)2
(16)	Hach The care X	Y6-1: X=F Y6-2: X=BF ₄ * Y6-3: X=H(GOYCF ₃) ₂ Y6-4: X=BF Y6-6: X=CF ₃ COO* Y6-6: X=GCH* Y6-7: X=CF ₃ SO ₃ *
	ı	(t28)

http://www6.ipdl.jpo.go.jp/tjcontenttrns.ipdl?N0000=21&.../;%3e;%3e%3a%3a%3e;=///// 2003/06/02

[0074]



特開2002-155142 (17) 31 (Y18) (120) (YZ1) **(Y22)** [0077] (YZ3) (Y24) (126) [0078] [{t32}

(18)

特開2002-155142

MSBI X

Y29-2 : X=BF4; Y28-3 : X=N((80₂CF₂)₂

(128) X H,C (CH,CH,O);CH

Y29-1 : X=F Y29-2 : X=BF4* Y29-3 : X=N((30₇CF₃)₂

【0079】本発明では、電解質塩として常温で溶融状態であるものを用い、溶媒を使用しないのが好ましい。 後述する溶媒を添加しても帶わないが、電解質塩の含有量は電解質組成物全体に対して50質量外以上であるのが好ましく、90質量%以上であるのが特に好ましい。また、本発明の第一及び第二の電解質組成物は、上記シロキサン化合物及び上記宣合体以外のヨウ素塩を含有するのが好ましく。用いる塩のうち50質量%以上がヨウ素塩であることが好ましい。また、溶媒を使用する場合は、電解質塩の濃度を0.05~2m0/1とするのが好ましく。0.1~1.5m01/1とするのがより好ましい。

33

【0080】(E)ヨウ素

本発明の第一及び第二の電解質組成物はヨウ素を含有するのが好ましい。ヨウ素含有量は電解質組成物全体に対して0.1~20質量%であるのが好ましく、0.5~5 質量%であるのがより好ましい。また、前述したシロキサン化合物、求電子剤及び電解質塩を含む反応溶液にヨウ素や臭素を添加して酸化量元対を予め生成させておくこともできる。この反応溶液中のヨウ素又は臭素の濃度は0.01~0.3mol/1とするのが好ましい。

【0081】(F)溶媒

本発明の第一及び第二の電解質組成物は溶媒を含んでいてもよい。電解質組成物の溶媒含有量は全体の50質量%以下であるのが好ましく、20質量%以下であるのがより好ましく、10質量%以下であるのが特に好ましい。

【0082】溶媒としては、低粘度でイオン移動度が高 いか、高誘電率で有効キャリア濃度を高めるか、或いは その両方であるために、優れたイオン伝導性を発現でき るものが好ましい。このような密媒として、カーボネー ト化合物(エチレンカーボネート、プロピレンカーボネ ート等)、復素環化合物(3-メチル-2-オキサゾリジノ ン等)、エーテル化合物(ジオキサン、ジェチルエーテ 40 ル等)、鎖状エーテル類 (エチレングリコールジアルキ ルエーテル、プロピレングリコールジアルキルエーテ ル、ポリエチレングリコールジアルキルエーテル、ポリ プロビレングリコールジアルキルエーテル等)、アルコ 一ル類(メタノール、エタノール、エチレングリコール モノアルキルエーテル、プロピレングリコールモノアル キルエーテル、ポリエチレングリコールモノアルキルエ ーテル、ポリプロピレングリコールモノアルキルエーテ ル等)、多価アルコール類 (エチレングリコール、プロ

ピレングリコール、グリセリン等)。エトリル化合物 (アセトニトリル、グルタロジニトリル、メトキンアセトニトリル、プロピオニトリル、ベンゾニトリル、ピスシアノエチルエーテル等)。エステル類(カルボン酸エステル、リン酸エステル、ホスホン酸エステル等)、非プロトン性極性溶媒(ジメチルスルホキシド(DMSO)、スルフォラン等)、水等が挙げられる。中でも、カーボネート化合物。ニトリル化合物、複素環化合物が好ましい。これらの溶媒は必要に応じて二種以上を混合して用いてもよい。

【0083】(のその他

20 本発明の第一及び第二の電解質組成物には、J. Am. Cer am. Soc., 80(12), 3157-3171 (1997)等に記載のt-ブチ ルビリジン、2-ビコリン、2,6-ルチジン等の塩益性化合 物を添加するのが分ましい。塩基性化合物を添加する場 合の好ましい。遠度範囲は0.05~2 Mである。

【0084】第一及び第二の電解質組成物をゲル化するために、ポリマー添加、オイルゲル化剤添加、多官能モノマーを含むモノマー類の重合、ポリマーの架構反応等の手法を併用できる。ポリマー添加によりゲル化させる場合は、"Polymer Electrolyte Reviews-1及び2^{*}

(J. R. MacCallunとC. A. Vincentの共編、ELSEVIER A PPLIED SCIENCE) に記載の化合物等が使用可能であり、ポリアクリロニトリル又はポリフッ化ビニリデンを用いるのが好ましい。オイルゲル化剤添加によりゲル化させる場合はJ. Chem. Soc. Japan, Ind. Chem.Sec., 46, 779 (1943). J. Am. Chem. Soc., 111, 5542 (1989)、J. Chem. Soc., Chem. Commun., 1993, 390. Angew. Chem. Int. Ed. Enql., 35, 1949 (1996). Chem. Lett., 1996, 885、J. Chem. Soc., Chem. Commun., 1997, 545 等に記載されている化合物を使用することができ、アミト特徴を有する化合物を用いるのが好ましい。また、特

下保垣を有する12百切を用いるのか好ましい。また、特 関平11-185863に記載の電解液のゲル化法、及び特開200 0-58140に記載の溶融塩電解質のゲル化法も、本発明に 適用できる。また、ボリマーの架橋反応により電解質組 成物をゲル化させる場合、特開2000-17076、同2000-867 24に記載されている架橋技術も適用できる。

【0085】[2]光電変換索子

キルエーテル、ポリエチレングリコールモノアルキルエーテ 本発明の光電変換索子は導電層、感光層、電荷輸送層及 ーテル、ポリプロピレングリコールモノアルキルエーテ び対極を有する。好ましくは図1に示すように、導電層 ル等)、多価アルコール類(エチレングリコール、プロ 10. 下塗り層60. 感光層20. 電荷輸送層30. 対極導電層 ピレングリコール、ポリエチレングリコール、ポリプロ 50 40の順に積層し、感光層20を色素22によって増感された

半導体機粒子21と当該半導体機粒子21の間の空隙に浸透 した電荷輸送材料23とから構成する。電荷輸送材料23 は、電荷輸送層30に用いる材料と同じ成分からなる。ま た光電変換素子に強度を付与するため、導電層10及び/ 又は対極導電層40の下地として基板50を設けてもよい。 本発明では、導電層10及び任意で設ける基板のからなる 層を「導電性支持体」、対極導電層40及び任意で設ける 益板50からなる層を「対極」と呼ぶ。なお、図1中の導 電房10、対極導電層40、益板50は、それぞれ透明導電層 10a、透明対極導電層40a. 透明基板50aであってもよ い。この光電変換素子を外部負荷に接続して電気的仕亭 (発電)をさせるものが光電池であり、光学的情報のセ ンシングを目的に作られたものが光センサーである。 【0086】図1に示す本発明の光電変換素子におい て、半導体微粒子がn型である場合、色素22により増感 された半導体微粒子21を含む感光層20に入射した光は色 素22を励起し、励起された色素22中の高エネルギーの電 子が半導体微粒子21の伝導帯に渡され、更に拡散により 導電層10に到達する。このとき、色素22は酸化体となっ 路で仕亭をしながら対極導電層40及び電筒輸送層30を経 て色素22の酸化体に戻り、色素22が再生する。感光層20 は負極 (光アノード) として働き、対極40は正極として 働く。それぞれの層の境界(例えば導電層10と感光層20 との境界、感光層20と電荷輸送層30との境界、電荷輸送 層30と対極導電層40との境界等)では、各層の構成成分 同士が相互に拡散混合していてもよい。以下、各層につ いて詳細に説明する。

【0087】(A)導電性支持体

導電性支持体は(1)導電層の単層、又は(2)導電層及び基 30 板の2層からなる。(1)の場合は、導電層の针科として 強度及び密封性が十分に保たれるようなものを使用し、 例えば金屑材料 (白金、金、銀、銅、亜鉛、チタン、ア ルミニウム、これらの合金等)を用いることができる。 (2)の場合、感光層側に導電剤を含有する導電層を有す る益板を使用することができる。好ましい導電剤として は金属(例えば白金、金、銀、銅、亜鉛、チタン、アル ミニウム、インジウム、これらを含む合金等).炭素及 び導電性金属酸化物(インジウムースズ複合酸化物、酸 (比スズにフッ素又はアンチモンをドープしたもの等) が 挙げられる。導電層の厚さは0.02~10μm程度が好まし Ļs.

【0088】導電性支持体は表面抵抗が低い程よい。表 面抵抗は好ましくは50Ω/□以下であり、より好ましく は20Ω/口以下である。

【0089】導電性支持体側から光を照射する場合に は、導電性支持体は実質的に透明であるのが好ましい。 実質的に透明であるとは、可視~近赤外領域(400~120 Omm)の一部又は全域において光速過率が10%以上であ ることを意味する。この光透過率は50%以上であるのが 50 ナイドが好ましい。

好ましく、80%以上であるのがより好ましい。特に、感 光層が感度を有する波長域の光透過率が高いことが好ま

【0090】透明導電性支持体としては、ガラスやプラ スチック等の透明基板の表面に導高性金属酸化物からな る透明導電層を塗布又は蒸着等により形成したものが好 ましい。透明導電層はファ素又はアンチモンをドービン グした二酸化スズ、或いはインジウム-スズ酸化物(IT 0) からなるのが好ましい。透明益板としてはコストと 強度の点で有利なソーダガラス、アルカリ洛出の影響の ない無アルカリガラス等のガラス基板に加え、透明ポリ マーフィルムが使用可能である。透明ポリマーフィルム の衬料としては、トリアセチルセルロース(TAC)、ポ リエチレンテレフタレート (PET)、ポリエチレンナフ タレート (PEN)、シンジオタクチックポリスチレン(S PS)。ポリフェニレンスルフィド(PPS)。ポリカーボ ネート (PC)、ポリアリレート (PAr)、ポリスルフォ ン(PSF)、ポリエステルスルフォン(PES)、ポリイミ F (PI)、ポリエーテルイミド (EI)、環状ポリオレ ている。光気池においては、導気層10中の電子が外部回 20 フィン、ブロム化フェノキン等が使用可能である。十分 な透明性を確保するために、導電性金属酸化物の塗布量 はガラス又はプラスチックの支持体1 ㎡当たり0.01~10 Oaとするのが好ましい。

- 【1) 091】透明導電性支持体の抵抗を下げる目的で金 肩リードを用いるのが好ましい。金属リードの村質は白 金.金、ニッケル、チタン.アルミニウム、銅.銀等の 金属が好ましい。金属リードは透明基板に蒸着、スパッ タリング等で設置し、その上に導高性の酸化スズ又はIT Oからなる透明導電層を設けるのが好ましい。 金属リー **ド設置による入射光量の低下は好ましくは10%以内、よ** り好ましくは1~5%に抑える。

(1)半導体

感光層は色素によって増感された半導体微粒子を含有す るのが好ましい。感光層において半導体は感光体として 作用し、光を吸収して電荷分離を行い電子と正孔を生ず る。色素増感された半導体では、光吸収及びこれによる 電子及び正孔の発生は主として色素において起こり、半 導体はこの電子 (又は正孔) を受け取り、伝達する役割 を担う。本発明で用いる半導体は光励起下で伝導体電子 がキャリアとなりアノード電流を与えるn型半導体であ るととが好ましい。

[0093] 本発明で用いる半導体の例としては、シリ コンやゲルマニウムのような単体半導体、III-V系化合 物半導体、金属のカルコゲナイド(酸化物、硫化物、セ レン化物、それらの複合物等)、ペロブスカイト構造を 有する化台物 (チタン酸ストロンチウム、チタン酸カル シウム、チタン酸ナトリウム、チタン酸バリウム.ニオ ブ酸カリウム等)等が挙げられる。 中でも金屑カルコゲ

【0094】好ましい金属カルコゲナイドとして、チタ ン、スズ、亜鉛、鉄、タングステン、ジルコニウム、ハ フニウム、ストロンチウム、インジウム、セリウム、イ ットリヴム、ランタン、バナジウム。ニオブ又はタンタ ルの酸化物、カドミウム、亜鉛、鉛、銀、アンチモン又 はビスマスの硫化物、カドミウム又は鉛のセレン化物、 カドミウムのテルル化物等が挙げられる。他の化合物半 導体としては亜鉛、ガリウム、インジウム、カドミウム 等のリン化物、ガリウムーヒ素又は銅-インジウムのセ レン化物、銅-インジウムの硫化物等が挙げられる。更 10 に、 从のふやは、以、の(以 以及び以はそれぞれ金属原 子、Cは酸素原子、x、y及びzは価数が中性になる数を表 す)のような複合物も好ましく用いることができる。 【0095】本発明で用いる半導体は、好ましくはSi、 $T1Q_2$. SnQ_2 , Fe_2Q_3 . WQ_4 . ZnO. Nb_2Q_2 . CdS. ZnS. PbS. Bi₂S₂, CdSe. CdTe, SrT>O₂, GaP, InP, GaAs. CuIn S.又はCuInSerであり、より好ましくはTro. Sno. Fe Oa. WOa. ZnO. Nb2Oa. CdS. PbS. CdSe, SrTnOa, InP. GaAs. CuIns,又はCuInse,であり、特に好ましくはTiO, 又はNb、G.であり、最も好ましくはTiQ.である。 TiQ.は アナターゼ型結晶を70%以上含むのが好ましく。100% アナターゼ型結晶であるのがより好ましい。

【0096】半導体中の電子電導性を上げる目的で金属 をドープするのが好ましい。ドープする金属としては2 価又は3 価の金属が好ましい。半導体から電荷輸送層へ 逆電流が流れるのを防止するために半導体に1個の金属 をドープするのも有効である。

【0097】本発明に用いる半導体は単結晶でも多結晶 でもよいが、製造コスト、原材料確保及びエネルギーペ イバックタイムの観点からは多結晶が好ましい。一部ア 30 モルファス部分を含んでいてもよい。半導体は半導体級 粒子からなる多孔質膜として用いるのが好ましい。

【0098】半導体微粒子の粒径は一般にnm~μmのオ ーダーである。微粒子の投影面積を円に換算したときの 直径から求めた一次粒子平均粒径は5~200mmであるの が好ましく、8~100mmであるのがより好ましい。ま た。導電性支持体上に塗布するために作製する分散液中 の半導体微粒子 (二次粒子) の平均粒径は0.01~30μ雨 であるのが好ましい。 粒径分布の異なる2 種類以上の微 粒子を混合してもよく、この場合小さい粒子の平均サイ 40 ズは25mm以下であるのが好ましく、10mm以下であるのが より好ましい。入射光を散乱させて光捕獲率を向上させ る目的で、粒径の大きな、例えば100nm以上、300mm程度 の半導体粒子を混合することも好ましい。

【0099】種類も異なる2程以上の半導体微粒子を混 合して用いてもよい。このような場合、1程はTrQ、Zn Q Mag又はSrTigであることが好ましい。もう一方は Sno. Fe G.又はNO.であるのが好ましい。中でも、Zno とSnO。、ZnOとWO。、或いはZnO又はSnO。とWO。の組み合わ せがより好ましい。2程以上の半導体改粒子を混合して 50 シメチルセルロース等のポリマー、界面活性剤、酸、キ

用いる場合、それぞれの粒径は異なっていてもよい。特 に上記TiQ、ZnQ、Nb,Q、又はSrTiQ。の粒径は大きく、Sn Q. Fe G 又はWG の粒径は小さいのが好ましい。粒径が 100m以上の大きい粒子と粒径が15m以下の小さい粒子 の組み合わせが好ましい。

【0100】半導体版粒子の作製法としては、作花済夫 の「ゾルーゲル法の科学」アグネ承風社 (1998年)、技 術情報協会の「ゾルーゲル法による薄膜コーティング技 術」(1995年)等に記載のゾルーゲル法、杉本忠夫の 「新合成法ゲルーゾル法による単分散粒子の合成とサイ ズ形蛙制御」、まてりあ、第35巻、第9号、1012~1018 頁(1996年)等に記載のゲルーゾル法が好ましい。ま た. Degussa社が開発した塩化物を酸水素塩中で高温加 水分解により酸化物を作製する方法も好ましく適用でき

【0101】半導体微粒子が酸化チタンの場合。上記ゾ ルーゲル法、ゲルーゾル法、塩化物の酸水素塩中での高 温加水分解法はいずれも好ましく利用でき、更に治野学 の「酸化チタン 物性と応用技術」技報堂出版 (1997 20 年) に記載の確酸法及び塩素法を用いてもよい。加え て、Barteらのジャーナル・オブ・アメリカン・セラミ ック・ソサエティー, 第80巻, 第12号、3157~3171頁 (1997年)、Burnsideらのケミカル・マテリアルズ、第 10巻、第9号、2419~2425頁等に記載のゾルーゲル法も 好ましい。

【0102】(2)半導体微粒子層

半導体微粒子を導電性支持体上に塗布する際には、半導 体微粒子の分散液又はコロイド溶液を導電性支持体上に 塗布する方法に加え、前述のゾル-ゲル法等を使用する ことができる。 光電変換素子の量産化、 半導体微粒子分 散液の物性、導電性支持体の融通性等を考慮すると、湿 式製膜方法が比較的好ましい。湿式製膜方法としては塗 布法、印刷法、電解析出法及び電音法が代表的である。 また、金屑を酸化する方法、金屑溶液から配位子交換等 で液相にて折出させる方法(LPD法)、スパッタ等で蒸 若する方法、CVD法、或いは加温した基板上に熱分解す る金属酸化物プレカーサーを吹き付けて金属酸化物を形 成するSPD法を用いてもよい。

【0103】半導体機粒子の分散液を作製する方法とし ては、前述のゾルーゲル法、乳鉢ですり潰す方法、ミル を使って粉砕しながら分散する方法、半導体を合成する 限に溶媒中で微粒子として折出させそのまま使用する方 法等が挙げられる。

【0104】分散媒としては、水又は各種の有機溶媒 《例えばメタノール、エタノール、イソプロピルアルコ ール、シトロネロール、タービネオール、ジクロロメタ ン. アセトン. アセトニトリル、酢酸エチル等) が使用 可能である。分散する際には、必要に応じてポリエチレ ングリコール、ヒドロキシエチルセルロース、カルボキ

http://www6.ipdl.jpo.go.jp/tjcontenttrns.ipdl?N0000=21&.../;%3e;%3e%3a%3a%3e;=/////

レート剤等を分散助剤として用いてよい。中でも、ポリ エチレングリコールを添加するのが好ましい。添加する ポリエチレングリコールの分子量を変えることにより分

39

散波の粘度が調節でき、剝がれにくい半導体層を形成し たり、半導体層の空隙率をコントロールできる。

【0105】好ましい塗布方法としては、ローラ法、デ ィップ法等のアプリケーション系、エアーナイフ法、ブ レード法等のメータリング系、特公昭58-4589号に記載 のワイヤーバー法、米国特許2681294号、同2761419号、 同2761791号等に記載のスライドホッパー法。エクスト ルージョン法。カーテン法等のアプリケーションとメー タリングを同一部分にできる方法等が挙げられる。また 汎用機としてスピン法やスプレー法も好ましい。湿式印 刷方法としては、凸版、オフセット及びグラビアの3大 印刷法をはじめ、凹版、ゴム版、スクリーン印刷等が好 ましく利用できる。以上の方法の中から、液粘度やウェ ット厚さに応じて好ましい製膜方法を選択すればよい。 【0106】半導体微粒子層は単層に限らず、粒径の異 なる半導体微粒子分散液を多層塗布したり、異なる種類 の半導体微粒子 (或いは異なるバインダー、添加剤等) を含有する層を多層塗布したりすることもできる。一度 の塗布では肢厚が不足する場合にも、多層塗布は有効で

【0107】一般に、半導体微粒子層の厚さ(感光層の 厚さと同じ)が厚くなるほど、単位投影面精当たりの色 素担持量が増えるため光の捕獲率が高くなるが、生成し た電子の拡散距離が増すため電荷再結合によるロスも大 きくなる。従って、半導体微粒子層の好ましい厚さは0. 1~100μπである。光電池に用いる場合、半導体微粒子 層の厚さは1~30μmであるのが好ましく、2~25μmで 30 あるのがより好ましい。支持体1 が当たりの半導体微粒 子塗布量は0.5~100gとするのが好ましく、3~50gとす るのがより好ましい。

【0108】半導体微粒子を導電性支持体に塗布した 後、半導体微粒子同士を電子的に接触させると共に塗膜 強度や支持体との密着性を向上させるために、加熱処理 を崩すのが好ましい。加熱温度は40℃以上700℃未満と するのが好ましく、100°C以上600°C以下とするのがより 好ましい。また.加熱時間は10分~10時間程度とすれば よい。ポリマーフィルムのように融点や軟化点の低い支 持体を用いる場合は、高温での加熱処理は支持体の劣化 を招くため好ましくない。また、コスト削減の観点から も、加熱処理はできる限り低温(例えば50℃~350℃) で行うのが好ましい。上述した粒径5 m以下の半導体微 粒子を併用したり、加熱処理を鉱酸や金属酸化物プレカ ーサーの存在下で行うことにより、加熱処理温度の低温 (比が可能となる。また紫外線、赤外線、マイクロ波等の 照射や電界又は超音波を印加することにより低温化でき る。不要な有機物等を除去する目的で、上記の照射等に 加えて加熱、減圧、酸素プラズマ処理、純水洗浄、溶剤 50

洗浄、ガス洗浄等を適宜併用するのが好ましい。

【0109】加熱処理後、半導体微粒子の表面債を増大 させるため、或いは半導体微粒子近傍の純度を高め色素 から半導体微粒子への電子注入効率を高めるために、例 えば四塩化チタン水溶液を用いた化学メッキ処理や三塩 化チタン水溶波を用いた電気化学的メッキ処理を施して もよい。また、半導体微粒子から電荷輸送層へ遊電流が 流れるのを防止するために、粒子表面に色素以外の電子 電導性の低い有機物を吸着させるのも有効である。 吸着 させる有機物は疎水性基を持つのが好ましい。

【() 1 1 ()】半導体機粒子層は多くの色素を吸着するこ とができるように大きな表面積を有するのが好ましい。 半導体微粒子を支持体上に塗布した状態での表面積は、 投影面積に対して10倍以上であるのが好ましく。100倍 以上であるのがより好ましい。上限は特に制限はない が、通常1000倍程度である。

【0111】(3)色素

感光層に使用する色素は可視域や近赤外域に吸収を有 し、半導体を増感しうるものであればよく、好ましくは 20 金属錯体色素、メチン色素、ポルフィリン系色素及び/ 又はフタロシアニン系色素であり、特に好ましくは金屑 錯体色素及び/又はポリメチン色素である。光電変換の 波長域をできるだけ広くし、且つ変換効率を上げるため に、二種類以上の色素を併用してもよい。この場合、光 源の波長域と強度分布に合わせて、併用する色素とその 混合割合を選択すればよい。

【0112】本発明で用いる色素は、好ましくは半導体 微粒子表面に対して吸着能力のある適当な結合基(inte rlocking group) を有する。好ましい結合基としては-C 00r盛、-0r盛、-50g1億、-P(0)(0t)g基及び-0P(0)(0t)g 基のような酸性基、並びにオキシム、ジオキシム、ヒド ロキシキノリン、サリチレート及びα-ケトエノレート のようなπ伝導性を有するキレート化基が挙げられる。 中でも-COOt柱、-P(O)(OH), 基及び-OP(O)(OH), 基が特に 好ましい。これらの結合基はアルカリ金属等と塩を形成 していてもよく、分子内塩を形成していてもよい。また ポリメチン色素においては、メチン鏡がスクアリリウム 環やクロコニウム環を形成する場合のように酸性益を含 有するなら、この部分を結合基としてもよい。以下、感 光層に用いる好ましい地感色素を具体的に説明する。

【() 1 1 3 】(a)金属錯体色素 本発明で使用する全居錯体色素は金属フタロシアニン色 素又は金屑ポルフィリン色素であるのが好ましい。 ま た、金属錯体色素の金屑原子はルテニウムRuが好まし い。本発明で使用できるルテニウム錯体色素としては、 例えば米国特許4927721号、同4684537号、同5084365 号,同5350644号、同5463057号、同5525440号、特閲平7 -249790号,特表平10-504512号、世界特許98/50393号、 特開2000-26487号等に記載のものが挙げられる。

【0114】本発明で用いるルテニウム錯体色素は下記

(22)

一般式(I):

(A,)。Ru(B-a)(B-b)(B-c) (I)
により表されるのが好ましい。一般式(I)中、A,は1又
は2座の配位子を表し、CI、SCN、H,O、Br、I、ON、NCO
及びSeON、並びにβ-ジケトン類、シュウ酸及びジチオ
カルバミン酸の誘導体からなる群から選ばれた配位子を来

41

*表す。pは0~3の整数である。B-a B-b及びB-cはそれ それ独立に下記式B-1~B-10により表される化合物から 退ばれた有機配位子を表す。

[0115] [批33]

HOOC COOH

BS (10)-12

· coop

86 Ro

носс _____соон

B-7 HOOC COOH

Brg HOOC COOH

m "C) COOR

B-10 R- 17 R-

【0 1 1 6】式B-1~B-10中、R、は水素原子又は置換基を表す。該置換基の例としては、ハロゲン原子、炭素原子数1~12の置換又は無置換のアルキル基、炭素原子数7~12の置換又は無置換のアラルキル基、炭素原子数6~12の置換又は無置換のアリール基。上記酸性基(塩を形成していてもよい)やキレート化基が挙げられる。ここで、アルキル基及びアラルキル基のアルキル部分は直鎖状でも分岐状でもよく、またアリール基及びアラルキ

30 ル基のアリール部分は単環でも多環(場合環、環集台)でもよい。B-a、B-b及びB-cは同一でも異なっていてもよく、いずれか1つ又は2つでもよい。
[0117]本発明で使用できる金属錯体色素の好ましい具体例を以下に示すが、本発明はこれらに限定されるものではない。

[0118] [(t34]

http://www6.ipdl.jpo.go.jp/tjcontenttrns.ipdl?N0000=21&.../;%3e;%3e%3a%3a%3e;=///// 2003/06/02

			(23)				特開2002-155142
43	MA	Rv(B-e)(B	b)(B-c)	(1)			44
	A ₁	p	B-e	B-b	В-с	R _a	_
R-1	SCN	2	B-1	B-1	_	_	-
R-2	CN	2	B-1	B-1	_	_	
R-3	Ci	2	B-1	B-1	_	_	
R-4	CH	2	9-7	8-7	_	_	
R-8	SCN	2	8-7	B-7	-		
R-6	SCN	2	B-1	B-2	_	н	
R-7	SCN	t	B-1	B-3	-	_	
R-8	G	1	B-1	B-4	_	Н	
R-9	1	2	B-1	B-5	-	н	
R-10	SCN	3	8-8	-	_	_	
R-11	ĊN	3	B-8	_	-	~-	
Fb12	SCN	1	B-2	B-6	- · ·	H	
R-13	_	0	8-1	B-1	B-1	-	

【0120】(b)メチン色素

本発明で使用するメチン色素は、好ましくはシアニン色素、メロシアニン色素、スクワリリウム色素等のポリメチン色素である。ポリメチン色素としては特別平11-358 36号。特別平11-67285号。特別平11-86916号、特別平11-97725号、特別平11-158395号。特別平11-163378号、特別平11-214730号、特別平11-214731号。特別平11-238905号、特別2000-26487号、欧州特計892411号。同911841号及び同991092号に記載のものが使用できる。好ましいメチン色素の具体例を下に示す。

45

[0121] [化%]

[0122] [(k37)

【() 123】(4)半導体微粒子への色素の吸着

半導体機粒子に色素を吸着させるためには、色素の溶液 中によく乾燥した半導体微粒子層を有する導電性支持体 を浸漬する方法・或いは色素の溶液を半導体機粒子層に 塗布する方法を用いることができる。前者の方法では、 浸漬法、ディップ法、ローラ法、エアーナイフ法等が使 用可能である。なお、浸漬法の場合、色素の吸着は窒温 で行ってもよいし、特開平7-249790号に記載されている ように加熱浸流して行ってもよい。また、後者の方法と してば、ワイヤーバー法、スライドホッパー法、エクス トルージョン法、カーテン法、スピン法、スプレー法等 の塗布方法がある。

【1)124】色素の溶液に用いる溶媒は色素の溶解性等 に応じて遺宜選択でき、例えばアルコール類(メタノー ル. エタノール、t-ブタノール、ベンジルアルコール 等)、ニトリル類 (アセトニトリル、プロピオニトリ ル、3-メトキシプロピオニトリル等)、ニトロメタン、 ハロゲン化炭化水素 (ジクロロメタン、ジクロロエタ ン、クロロホルム、クロロベンゼン等)、エーテル類 20 (ジエチルエーテル、テトラヒドロフラン等). ジメチ ルスルホキシド、アミド類(N,N-ジメチルホルムアミ F. N.H-ジメチルアセタミド等)、N-メチルピロリド ン.1,3-ジメチルイミダゾリジノン.3-メチルオキサゾ リジノン、エステル類(酢酸エチル、酢酸ブチル等)、 炭酸エステル類(炭酸ジエチル、炭酸エチレン.炭酸ブ ロビレン等)、ケトン類 (アセトン、2-ブタノン、シク ロヘキサノン等)、炭化水素(ヘキサン、石油エーテ ル、ベンゼン、トルエン等)、これらの混合溶媒等が使 用できる。

[0125] 色素の全吸着量は、導電性支持体の単位表 面積 (1㎡) 当たり0.01~100molとするのが好まし い。また、色素の半導体微粒子に対する吸着量は、十分 な増感効果を得るためには半導体微粒子 1 0当たり 0.01 ~ 1 mmolであるのが好ましい。色素の吸若量が少なすぎ ると増感効果が不十分となり、また多すぎると色素が浮 遊しやすく、増感効果を低減させる原因となる。また、 色素の吸着量を増大させるために吸着前に加熱処理を施 すのが好ましい。加熱処理の後に半導体微粒子表面に水 が吸着するのを抑制するために、常温に戻さず60~150 でで素早く色素を吸着させるのが好ましい。また. 経集 のような色素同士の相互作用を低減する目的で、無色の 化合物を半導体微粒子に共吸着させてもよい。共吸着さ せる化合物としては界面活性化合物が有効であり、カル ボキンル基を有するステロイド化合物(例えばケノデオ キシコール酸)や以下に示すスルホン酸塩類等の界面活 性化合物が使用できる。

[0126] [{k38]

50

47
(OCH,CH) SONA

C+H19-(OCH2CH);-OSO;K

【0127】未吸音の色素は吸音後速やかに洗浄により 除去するのが好ましい。洗浄は湿式洗浄槽中で、アセトニトリル等の極性溶剤やアルコール系溶剤等の有機溶媒 を用いて行うのが好ましい。余分な色素の除去を促進す 10 る目的で、色素を吸音した後にアミン類や4根アンモニウム塩を用いて半導体微粒子の表面を処理してもよい。 好ましいアミン類としてはビリジン、4-t-ブチルビリジン、ボリビニルビリジン等が挙げられる。好ましい4根アンモニウム塩としてはテトロブチルアンモニウムヨージド、テトラへキシルアンモニウムヨージド等が挙げられる。これらは、有機溶媒に溶解して用いてもよく、液体の場合はそのまま用いてもよい。

【0128】(C)電荷輸送層

高尚翰送層は色素の酸化体に電子を補充する機能を有す 20 る。電荷翰送層に上記本発明の第一の電解質組成物又は 第二の電解質組成物を用いるが、更に固体電解質や正孔 (ホール)輸送材料を併用してもよい。

【0129】電荷輸送層はキャスト法、塗布法、浸渍法、含浸法、浸透法等により電極上に反応溶液層を形成し、次いで上記重合反応を行い設置することができる。加熱して宣合させる場合、加熱温度は使用する色素の耐熱温度に応じて選択すればよいが、好ましくは10~200℃、より好ましくは30~150℃とする。加熱時間は加熱温度等にもよるが、5分~7時間程度とする。

【0130】電荷輸送層の形成方法に関して、詳しくは 2通りの方法が可能である。1つは感光層の上に先に対 極を貼り合わせておき、その間隙に上記反応溶液層を挟 み込む方法である。もう1つは感光層上に直接電荷輸送 層を形成し、その後対極を設置する方法である。前者の 方法においては、浸渍等による毛管現象を利用する常圧 プロセス、又は常圧より低い圧力にして間障の気相を液 相に置換する真空プロセスにより反応溶液層を挟み込む ことができる。後者の方法においては、混式電解買組成 物を用いる場合は未乾燥のまま対極を付与しエッジ部に が環境防止措置を施せばよい。ゲル電解質を用いる場合 は、液状の電解質組成物を塗布した後、固体化すればよ い。また、湿式有機正孔輸送材料やゲル気解質を用いる 場合は、前途の感光層の形成法と同様の方法を利用でき る。

【0131】固体電解質や固体の正孔(ホール) 輸送材料を用いる場合には、真空蒸岩法やCVD法等のドライ成膜法により電荷輸送層を形成し、その役対極を付与することができる。有機正孔輸送材料は真空蒸岩法、キャスト法、塗布法、スピンコート法、浸流法、電解重合法、

光電解宣台法等の手法により導入することができる。無 機固体化台物の場合も、キャスト法、釜布法、スピンコート法、浸漬法、電解析出法、無電解メッキ法等の手法 により導入することができる。

48

【0132】酸化還元対を生成させるために電荷輸送層にヨウ素等を導入する場合。電解質の溶液に添加する方法。電荷輸送層の形成後。これをヨウ素等と共に密閉容器内に置き電解質中に拡散させる手法等が利用できる。また。後述の対極にヨウ素等を塗布又は蒸着し、光電変換素子を組み立てたときに電荷輸送層中に導入することも可能である。

【0133】電荷輸送層中の水分は10,000ppm以下であるのが好ましく、更に好ましくは2,000ppm以下であり、特に好ましくは100ppm以下である。

【0134】(D)対極

対極は光電変換素子を光電池としたときに正径として作 用する。対極は上記導電性支持体と同様に、導電性材料 からなる対極導電層のみから構成されていてもよいし、 対極導電層と支持基板から構成されていてもよい。 対極 導電層に用いる導電性材料としては、 金属 (例えば白 金、金、銀、銅、アルミニウム、マグネシウム、インジ ウム等)、炭素及び導電性金属酸化物(インジウムース ズ捏合酸化物. 酸化スズにファ素をドープしたもの等) が挙げられる。中でも白金、金、銀、銅、アルミニウム 及びマグネシウムが好ましい。対極に用いる支持益板 は、好ましくはガラス基板又はプラスチック基板であ り、これに上記導電性材料を塗布又は蒸若して用いる。 対極導電層の厚さは特に制限されないが3 mm~10 д в で あるのが好ましい。対極の表面抵抗は低い程よく、500 /□以下であるのが好ましく、20Q/□以下であるのがよ り好ましい。

【0135】導電性支持体と対極のいずれか一方又は両方から光を照射してよいので、感光層に光が到達するためには、導電性支持体と対極のうち少なくとも一方が実質的に透明であればよい。発電効率向上の観点からは、導電性支持体を透明にし、光を導電性支持体側から入射させるのが好ましい。この場合、対極は光を反射する性質を有するのが好ましい。このような対極の材料としては、金属や導電性の酸化物を蒸若したガラス又はプラスチック、金属薄膜等が使用できる。

【0136】対極は電荷輸送層上に直接導電材を塗布、メッキ又は蒸着 (P/O. C/O) するか。導電層を有する基板の導電層側を貼り付けて設けてよい。また、導電性支持体の場合と同様に、特に対極が透明の場合には、対極の抵抗を下げる目的で金属リードを用いるのが好ましい。なお、好ましい金属リードの材質及び設置方法、金属リード設置による入射光量の低下等は導電性支持体の場合と同じである。

【0137】(E)その他の層

50 対極と導電性支持体の短格を防止するため、予め導電性

http://www6.ipdl.jpo.go.jp/tjcontenttrns.ipdl?N0000=21&.../;%3e;%3e%3a%3a%3e;=/////

支持体と感光層の間に緻密な半導体の薄膜層を下塗り層 として金設するのが好ましい。電荷輸送層に電子輸送材 料や正孔翰送付料を用いる場合は特に有効である。下塗 り層の材料は好ましくはTiQ、SnQ、FeQ。WQ、ZnO 及び/又はMoのであり、さらに好ましくはTiのであ る。下塗り層はElectrochimi. Acta、40, 643-652(199 5)に記載されているスプレーパイロリンス法や。 スパッ タ法等により塗設することができる。 下塗り層の膜厚は 5~1000mmであるのが好ましく、10~500mmであるのがよ り好ましい。

【0138】また、電極として作用する導電性支持体及 び対極の一方又は両方の外側表面、導電層と基板の間又 は益板の中間に、保護層、反射防止層等の機能性層を設 けてもよい。このような機能性層の形成には、その材質 に応じて塗布法。蒸岩法、貼り付け法等を用いることが できる。

【0139】(F)光電変換素子の内部構造の具体例 上述のように、光電変換素子の内部構造は目的に合わせ 様々な形態が可能である。大きく2つに分ければ、両面 から光の入射が可能な構造と、片面からのみ可能な構造 が可能である。 図2 ~図8 に本発明に好ましく適用でき る光電変換素子の内部構造を例示する。

【0140】図2に示す構造は、透明導電層10aと透明 対極導電層40aとの間に、感光層20と電荷輸送層30とを 介在させたものであり、両面から光が入射する常造であ る。図3に示す構造は、透明基板50a上に一部金属リー ド11を設け、その上に透明導電層10aを設け、下塗り層6 0、 感光層20、 電荷輸送層30及び対極導電層40をこの順 で設け、更に支持基板50を配置したものであり、導電層 側から光が入射する構造である。図4に示す構造は、支 30 持益板50上に更に導電層10を設置し、下塗り層60を介し て感光層20を設け、更に電荷輸送層30と透明対極導電層 40aとを設け、一部に金属リード11を設けた透明基板50a を金属リード11側を内側にして配置したものであり、対 極側から光が入射する構造である。 図5 に示す構造は、 一部金屑リード11を設けた2つの透明基板50a上に、そ れぞれ透明導電層10a. 透明対極導電層40aを設け、それ ちの間に下塗り層60、感光層20及び電荷輸送層30を介在 させたものであり、両面から光が入射する構造である。 図6に示す構造は、透明基板50a上に透明導電層10aを設 40 置し、下塗り居60を介して感光層20を設け、更に電荷輸 送層30及び対極導電層40を設け、この上に支持基板50を 配置したものであり、導電層側から光が入射する構造で ある。図7に示す構造は、支持基板50上に導電層10を設 置し、下塗り居60を介して感光層20を設け、更に電荷輸 送層30及び透明対極導電層40aを設け、この上に透明基 板50aを配置したものであり、対極側から光が入射する 構造である。図8に示す構造は、透明基板50a上に透明 導電層102を設置し、下塗り層60を介して感光層20を設 け、更に電筒輸送層30及び透明対極導電層40aを設け、

この上に透明益板50aを配置したものであり、両面から 光が入射する構造である。

【() 】 4 1 】 [3]光電池

本発明の光電池は、上記本発明の光電変換素子を外部負 苘に接続して電気的仕亭 (発電) をさせるようにしたも のである。光電池のうち、電荷輸送計料23が主としてイ オン輸送材料からなるものを光電気化学電池と呼び、ま た太陽光による発電を主目的とするものを太陽電池と呼 <u>ځ.</u>

【0142】光電池の側面は構成物の劣化や内容物の垣 散を防止するためにポリマーや接着剤等で密封するのが 好ましい。導電性支持体及び対極にリードを介して接続 される外部回路自体は公知のもので良い。

【0143】本発明の光電変換素子を太陽電池に適用す る場合、そのセル内部の常造は基本的に上述した光電変 換素子の構造と同じである。また、本発明の光電変換素 子を含む本発明の太陽電池モジュールは、従来の太陽電 池モジュールと益本的には同様の構造をとりうる。 太陽 電池モジュールは一般的には金屑、セラミック等の支持 基板の上にセルが構成され、その上を充填樹脂や保護ガ ラス等で覆い、支持基板の反対側から光を取り込む構造 をとる。支持益板に強化ガラス等の透明材料を用い、そ の上にセルを帯成してその透明の支持基板側から光を取 り込む構造とすることも可能である。具体的には、スー パーストレートタイプ、サブストレートタイプ或いはポ ッティングタイプのモジュール構造。 アモルファスシリ コン太陽電池等で用いられる基板一体型モジュール構造 等が知られている。本発明の光電変換素子を用いた色素 増感型太陽電池においても、使用目的や使用場所及び環 焼により、 遺宜モジュール常造を選択できる。 本発明に おける利用可能な太陽電池モジュールの構造、好ましい 熊振等は特願平11-8457に記載のものと同様である。

[0144]

【実施例】以下、具体例により本発明を更に詳細に説明 するが、本発明はそれらに限定されるものではない。 【0145】1. 二酸化チタン分散液の調製

内側をテフロン (登録商標) コーティングした内容精20 Omlのステンレス製容器に二酸化チタン微粒子(日本ア エロジル (株) 製、Degussa P-25) 15g、水45g. 分散剤 '(アルドリッチ社製、Triton X-100) lg. 直径0.5mmの ジルコニアピーズ (ニッカトー社製) 30gを入れ、サン ドグラインダーミル (アイメックス社製) を用いて1500 rpmで2時間分散処理した。得られた分散液からジルコ ニアピーズをろ遇により除去した。得られた分散液中の 二酸化チタン微粒子の平均粒径は2.5μ㎡あった。なお 粒径はMALVERN社製のマスターサイザーにて測定した。

【O 146】2. 色素を吸着したTiO。電極の作成 フゥ索をドープした酸化スズ層を有する導電性ガラス (旭硝子 (株) 設TCOガラス-Uを20mm×20mmの大きさに 50 切断加工したもの、表面抵抗約30Ω/□)の導電面側に

ガラス棒を用いて上記分散液を塗布した。半導体微粒子 か金布量は20g/mとした。その際、導電面側の一部(蟾から3mm)に粘着テーブを張ってスペーサーとし、粘着テーブが両端に来るようにガラスを並べて一度に8枚ずつ塗布した。塗布後、粘着テーブを剥離し、室温で1日間風乾した。次にこのガラスを電気炉(ヤマト科学(株)製マッフル炉FP-32型)に入れ、450℃にて30分間焼成し、TiQ、電極を得た。この気極を取り出し冷却した後、色素R-1のエタノール溶液(3×101mol/1)に3時間浸漬した。色素の染着したTiQ、電極を4t-ブチルピリ 10ジンに15分間浸漬した後、エタノールで洗浄し自然乾燥した。得られた感光層の厚さは6.5μmであった。

【0147】3. 光電気化学電池の作製

3-1. 溶媒を含有する電解質組成物を用いた光電気化学 電池

実施例1~7並びに比較例1及び2

0.5mol/1の電解貿塩Mtm (1-メチル-3-ヘキンルイミダ ゾリウムのヨウ素塩)及び0.05mol/1のヨウ素を含むア セトニトリル溶液を調製し、これにシロキサン化合物1-4を加えた。ここでシロキサン化合物は【溶媒+電解貿 塩+シロキサン化合物】を100質量%として10質量%用 いた。得られた溶液を、前述のように作製した色素増感 TiO,電極基板(20mx×20mm)と、これと同じ大きさの白*

* 金蒸若ガラスを重ね合わせた隙間に毛細管現象を利用し て染み込ませTrO。電極中に導入し、エポキシ系封止剤で 封止して、本発明の第一の電解質組成物を用いた実施例 1の光電気化学電池を得た。溶媒及びシロキサン化台物 を下記表1に示すように変更したこと以外は上記実施例 1と同様にして、本発明の第一の電解質組成物を用いた 実施例2~7の光電気化学電池を得た。また、シロキサ ン化合物を加えないこと以外は上記実施例1と同様にし て比較例1の光電気化学電池を作製し、更にシロキサン 化合物に換えて t-ブチルビリジンを添加したこと以外は 上記実施例1と同様にして比較例2の光電気化学電池を 作製した。上記実施例1~7並びに比較例1及び2の光 電気化学電池に用いた色素、シロキサン化合物及びその 質量比、電解質塩及びその濃度、ヨウ素の濃度、並びに 裕煤を表 1 に併せて示す。なお、表 1 中のANはアセトニ トリルを表し、NADは3-メチル-2-オキサゾリジノンを表 し、PCはプロビレンカーボネートを表し、Milloは1-メチ ルー3-ヘキシルイミダゾリウムのヨウ素塩を表す。ま た、表】中、シロキサン化合物の質量比は「溶媒+常解 20 質塩+シロキサン化合物]を100質量%とした場合の質 量比である。

[0148]

【表 1】

光電気 化字管池	色素	シロキサン化合物 (質量%)	電解製塩 (Tion)	ヨウ素 (molf)	溶族
実施例1	R-1	1-4 (10)	MH9m (0.5)	0.85	AN
實施例2	R-1	1-4 (10)	MHIm (0.5)	0.05	NMO
突進第3	R-1	1-4 (10)	MHim (0.5)	0.05	PÇ
实施别4	R-T	1-6 (10)	MHUn (0.5)	0.05	AN
宪美男5	R-1	1-11 (10)	MHen (0.5)	0.05	AN
夹盖例	R-1	1-13 (10)	MH (0.5)	0.05	AN
突延例7	R-1	1-17 (10)	MHm (0.5)	0.05	AN
比较例(R-1	なし	MHm (0.5)	0.06	AN
止較例2	R-1	トプチルビリジン {10}	MHm (0.5)	0.06	AN

【0149】実施例8~17

0.5mol/1の電解質塩MIm (1-メチル-3-ヘキシルイミダ ゾリウムのヨウ素塩)及び0.05mo1/1のヨウ素を含むア セトニトリル溶液を調製した。この溶液にシロキサン化 台物1-4を加え、更に求電子剤6-3を混合して均一な溶液 を調整した。とこで、シロキサン化合物は[溶媒+電解 質塩+シロキサン化合物]を100質量%として10質量% 用い、求電子割はシロキサン化台物の反応部位に対する 求電子剤の求電子部位のモル比が1となるように加え た。得られた溶液を、前述のように作製した色素増感形 Q.電極基板 (20mm×20mm) と、これと同じ大きさの白金 蒸着ガラスを重ね合わせた隙間に毛細管現象を利用して 集み込ませ、TrO。電極中に導入した。これを50℃で12時 間放置して宣合反応を行い、エポキシ系封止剤で封止し て、本発明の第二の電解質組成物を用いた実施例8の光 電気化学電池を得た。溶媒、シロキサン化合物、並びに 求電子剤とそのモル比を下記表2に示すように変更した こと以外は上記実施例8と同様にして、本発明の第二の 電解貿組成物を用いた実施例9~14の光電気化学電池を 50

得た。また、シロキサン化合物を表2に示すものに換 え、求電子剤の使用量をシロキサン化合物に対して5質 量%としたこと以外は上記実施例8と同様にして、本発 明の第二の電解質組成物を用いた実施例15~17の光電気 化学電池を得た。上記実施例8~17の光電気化学電池に 用いた色素、求電子削及びそのモル比。シロキサン化合 物及びその質量比、電解質塩及びその濃度、ヨウ素の濃 皮. 並びに溶媒を表2に併せて示す。なお、表2中のAN はアセトニトリルを表し、MDは3-メチル-2-オキサゾリ ジノンを表し、PCはプロビレンカーボネートを表し、MI Inは1-メチル-3-ヘキンルイミダゾリウムのヨウ素塩を 表す。また、表2中、シロキサン化合物の質量比は [答 媒+電解質塩+シロキサン化合物】を100質量%とした 場合の質量比であり、求電子剤のモル比は、シロキサン 化合物の反応部位に対する求電子剤の求電子部位のモル 比である。ただし、実施例15~17の光電気化学電池に用 いた求電子剤の使用量はモル比ではなくシロキサン化合 物に対する質量比(wt%)で示す。

[0150]

http://www6.ipdl.jpo.go.jp/tjcontenttrns.ipdl?N0000=21&.../;%3e;%3e%3a%3a%3e;=/////

【表2】

光電気	色素	家電子類 (モル比及は貧量比)	シロキサン化会物 (質量が)	雅舒麗·迪 (mol/i)	用ウ素 (Now)	熔構
化学区地	84	B-3 (1)	1-4 (10)	MH(m (0.5)	0.05	4
変異例3	R-1	5-8 (1)	1-4 (10)	MH4m (0.5)	0.05	NAMO
突旋例2	R-1		14 (10)	MHER (0.5)	0.05	PC
实施的10	R-1	E-3 (1)	1-0 (10)	MHm (0.5)	0.06	AN
安美研11	F8-1	E-8 (1)	1-4 (10)	MH2m (0.5)	0.05	AH
突旋风拉	R-1	E-12 (1)	1-0 (10)	MHm (0.5)	8.06	AM
與歐別13	R-1	E-12 (1)		M)4m (0.5)	0.05	AN
安徽祭14	R-1	E-3 (0.5), E-5 (0.1)	1-4 (10)			AN
李生815	R-1	E-3 (6 w/%)	141 (10)	MHm (0.5)	0.05	_
密性例16	R-1	E-3 (5 w/%)	1-13 (18)	MH (0.5)	0.06	AN
金色 第47		E-3 (5 W(%)	1-17 (10)	M-1m (0.5)	0.05	AN

[0151]比較例3

500mgのヘキサエチレングリコールメタクリル酸エステル(日本油脂化学社製「ブレンマー氏-350」). 1 gの. プロピレンカーボネート. 及び2 mgの重合開始剤AIBNを含有する混合液を調製し. これに500mgのヨウ化リチウムを溶解させた。次にこの混合液を10分間真空脱気し、上記のように作製した色素増感TiQ、電極基板(20mm×20mm)に塗布した。続いて混合液を塗布したTiQ、電極を減圧下に置き、TiQ、電極内の気泡を除きモノマーの浸透を促した後、60℃で1時間加熱し定合させた。 宣合後、室20温でヨウ素雰囲気下に30分間曝して. 得られた重合体中にヨウ素を拡散させた。これを白金を蒸若した対極と室わ合せて比較例3の光電気化学電池(日本化学会誌、7、484頁(1997年)記載の電解質を用いた光電気化学電池)を得た。

53

【0152】3-2. 富温溶融塩を含有する電解質組成物 を用いた光電気化学電池

実施例18~28及び比較例4~6

60質量%の溶融塩A 28質量%の溶融塩B 2質量%のヨウ素.及び10質量%のシロキサン化合物1-4を混合し均一な電解質組成物を調製した。得られた電解質組成物5 μ1を上記のように作製した色素増感TiQ 電極基板に塗 *

*布した後、この電極を減圧下に置き電解質組成物を浸透 させた。電解質組成物が十分に浸透し電極中の空気が抜 けた後、これに白金蒸着ガラスを重ね合わせて本発明の 第一の電解質組成物を用いた実施例18の光電気化学電池 を得た。溶融塩とその質量比、並びにシロキサン化合物 を下記表3に示すように変更したこと以外は上記実施例 18と同様にして、本発明の第一の電解貿組成物を用いた 実施例19~28の光電気化学電池を得た。また、シロキサ ン化合物を加えず、溶融塩とその質量比を表3に示すよ うに変更したこと以外は上記実施例18と同様にして比較 例4及び5の光電気化学電池を作製し、更にシロキサン 化合物に換えてもブチルビリジンを添加し、溶融塩とそ の貿量比を表3に示すように変更したこと以外は上記実 施例18と同様にして比較例6の光電気化学電池を作製し た。ただし、t-ブチルピリジンの量は10質量%とした。 上記実施例18~28及び比較例4~6の光電気化学電池に 用いた色素、溶融塩及びその質量比、3ウ素の質量比、 並びにシロキサン化台物及びその質量比を表3に併せて 示す。また、溶融塩A~Dの常造を以下に示す。

【0153】 【表3】

非常 氧		建物塩	ヨウ素	シロキサン化合物
化学管理	色素	(開発%)	(別量化)	(変量%)
東施製18	R-1	A (60) / B (28)	2	1-4 (10)
李旗景知	R-1	A (60) / C (28)	2	1-4 (10)
要推到20	R-1	A (90) / C (28)	2	1-4 (10)
安施例21	R-1	A (50) / B (28)	2	1-6 (10)
安徽到22	81	D (80) / C (28)	2	1-4 (10)
李监明23	RI	D (50) / C (26)	2	1-4 (10)
安建例24	Ri	D (80) / C (28)	2	1-8 (18)
安建例26	R-1	D (80) / C (28)	2	1-4 (10)
	R-1	A (80) / C (28)	2	1-11 (10)
实施例28	R-1	A (50) / C (28)	2	1-13 (10)
実施例27	R-1	A (90) / C (28)	1 2	1-17 (10)
突旋例29	R-1	A (70) / O (28)	1 2	なし
比較多		D (70) / C (28)	2	なし
比较#5	R-1	A (80) / C (28)		トプテルピリジン
建設 例	R-1	N (00) 1 0 (20)		1,

[0154] [批39]

*60貿量%の溶融塩A 28質量%の溶融塩B、2質量%のヨ ウ素 及び10貿量%のシロキサン化合物1-4を混合し

55

【0155】実施例29~39

更に求電子剤に-3を加えて均一な電解質組成物を調製し た。とこで、求電子剤は、シロキサン化合物の反応部位 に対する求電子剤の求電子部位のモル比が1となるよう に加えた。得られた電解質組成物5 m 1を上記のように 作製した色素増感TiO。電極差板に塗布した後、との電極 を減圧下に置き電解質組成物を浸透させた。電解質組成 物が十分に浸透し電極中の空気が抜けた後、これに白金 10 蒸着ガラスを重ね合わせ、50°Cで10時間放置して重合反 応を行い、本発明の第二の電解質組成物を用いた実施例 29の光電気化学電池を得た。溶融塩及びシロキサン化合 物とそれらの貿量比、並びに求電子剤とそのモル比を下 記表4に示すように変更したこと以外は上記実施例29と 同様にして、本発明の第二の電解質組成物を用いた実施 例30~39の光電気化学電池を得た。上記実施例29~39の 光電気化学電池に用いた色素、溶融塩及びその質量比、 ヨウ素の質量比、求電子剤及びそのモル比、並びにシロ キサン化合物及びその質量比を表4に併せて示す。なお 20 表4中、求電子剤のモル比は、シロキサン化合物の反応 部位に対する求電子剤の求電子部位のモル比である。

[0156] 【表4】

光理员 化学程法	8.	遊動塩 (質量性)	日ウ素 (食量14)	求権子前 (モル比)	シロキザン化合物 (質量%)
夹连件29	R-1	A (00) / B (28)	2	5-8 (1)	1-4 (10)
突盖例30		A (80) / C (28)		E-3 (1)	1-4 (10)
		A (60) / C (28)		E-12 (1)	1-4 (10)
专施 #432	R-1	A (00) / B (26)	2	E-3 (1)	1-6 (10)
海海州39	R-1	O (60) / C (28)	2	E-3 (1)	14 (10)
安室例料	R-1	D (00) / C (28)	2	E-12 (1)	1-4 (10)
海美州35	R-1	D (80) / C (28)	2	E-3 (1)	1-8 (10)
美華州28	R-1	D (60) / C (28)	2	E-3 (0.9), E-5 (0.1)	1-1 (10)
赛曲针37	R-1	A (80) / C (28)	2	E-3 (1)	1-11 (10)

【0157】比較例7

プロピレンカーボネートに換えて上記化合物Cを用いた こと以外は上記比較例3と同様にして、比較例7の光電 気化学電池を作製した。

【0158】4. 光電変換効率の測定

500Mのキセノンランプ (ウシオ電気 (株) 製) の光をAN 1.5フィルター (Orie)社製) 及びシャープカットフィル ター (Kenko L-42) を通すことにより紫外根を含まない 40 模擬太陽光を発生させた。この光の強度は86mg/cmgであ※

※った。この模擬太陽光を、SOCにて作製した実施例1~ 39及び比較例1~7の光電気化学電池に照射し、発生し た電気を電流電圧測定装置(ケースレーSML238型)にて 測定した。これにより求められた各光電気化学電池の短 格電流密度(Jsc)、開放電圧(Voc)、形状因子(F F)、変換効率(カ)及び360時間連続照射後の変換効率 の低下率を表5~8に示す。

[0159]

【表5】

光管 気 化学電池	短篇電索磁度 (Jac) mAtom ²	阿斯斯廷 (You) Y	张因子 (FF)	東後4年 (中) %	2 任下率 (280年) %
突端例1	10.1	0.72	0.62	5.24	1.9
安飾物2	9,75	0.72	0.61	4.98	76
埃施903	9.89	67.0	0.62	5.20	77
安体制4	10.2	0.72	0.61	5.21	76
安连朝5	8.62	0.73	0.60	4.90	78
3時概象	9,43	0.74	0.61	4.95	78
\$25E.697	9.87	0.79	0.60	4.92	77
11.11.91	9.92	0.65	0.65	4.57	99
ILEKSE2	9.42	0.72	0.51	4.81	99

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(30)

特開2002-155142

57

光電気 化学程度

实施例16

88 M PH 18

7.87

* *【表6】

知識を実施を (Jsc) mAform	MEXTEE (Voc)	整体组子 (FF)	(3)	で任下4 (300時間)
9.12	0.50	0.57	4.11	42
8.97	0.67	0.56	3.64	36
8.69	0.57	0.86	3.62	35
9,10	0.66	0.57	3.95	41
9.12	0.68	0.58	4,04	37
9.10	0.60	0.56	3.91	33

[0161]

[0160]

※ ※【表7】

0.56

0.57

0.57

0.65

0.64

3.A7

3.35

光電気 化学散泡	短 格電支 密度 (Jsc.) mAkm ²	MX電圧 (Voc) V	## ## (FF)	定性效率 (2) %	7年下率 (360時開始) %
突施例18	0.11	0.51	0.57	3.68	18
実施制19	80.9	0.62	0.56	3.58	18
突施例20	9.20	0.62	0.58	3.85	16
探集例21	9.11	0.80	0.56	5.69	17
尖龍到22	9.29	0.60	0.57	8.69	17
英華製23	9.14	0.60	0.58	8.70	16
突旋到34	9.13	0.61	0.57	8.00	16
突施例25	9.09	0.61	0.58	8.74	14
突旋到26	8.10	0.62	0.58	8.29	15
事類例2	8.99	0.60	0.57	8.58	16
安连到28	8.98	0.81	0.57	8.63	15
比較394	7.25	0,62	0.58	2.76	35
比較的5	7.90	0.56	0.50	2.98	30
此級例	7.20	0.62	0.56	291	45

[0162]

★ ★【表8】

	短編章技術教 開放電圧					
光键点 化学高速	(Jsc) mAlcm ²	(Voc) V	部状因子 (FF)	(p) %	(200037773)	
実施例29	8.11	0.57	0.55	2.90	18	
支統8130	8.20	0.59	0.55	3.09	18	
実施例針	8.20	0,59	0.54	3.09	15	
美能332	8.08	0.55	0.55	2.05	17	
実施例33	8.29	0.60	0.55	5,18	17	
安美河34	8.28	0.61	0.54	5.17	10	
夹施河35	8.25	0.58	0.55	3.06	10	
实施部35	8.27	0.68	0.54	3.01	14	
FXE9137	8.01	0.60	0.66	2.84	16	
会議機関	7.11	0.61	0.54	2.72	14	
起施例39	7.05	0.80	0.54	2.68	15	
比较物	1,40	0.52	0.50	0.42	14	

【0163】表5及び表7より明らかなように、比較例 1. 4及び5の光電気化学電池は開放電圧が低くこれが 低い光電変換効率の原因となっているのに対して、本発 40 明の第一の電解質組成物を用いた実施例1~7及び18~ 28の光電気化学電池は開放電圧が高くそれに伴い変換効 **率が向上している。また、電解質組成物に有機溶媒を多** く含む比較例1及び2並びに実施例1~7の光電気化学 電池では暗所保存後の劣化が着しいが、 本発明の第一の 電解質組成物を用いることにより耐久性が改善されてい ることがわかる。また表6及び表8より、従来の固体電 解貿を用いた比較例3及び7の光電気化学電池と比較し て、本発明の第二の電解質組成物を用いた実施例8~17 及び29~39の光電気化学電池は優れた変換効率及び耐久 50 性を示すことがわかる。

[0164]

【発明の効果】以上詳述したように、本発明の第一及び 第二の電解質組成物は耐久性及び電荷輸送館に優れてお り、この電解質組成物を用いた光電変換索子及び光電池 は優れた耐久性及び光電変換特性を示す。かかる光電池 は太陽電池として極めて有効である。

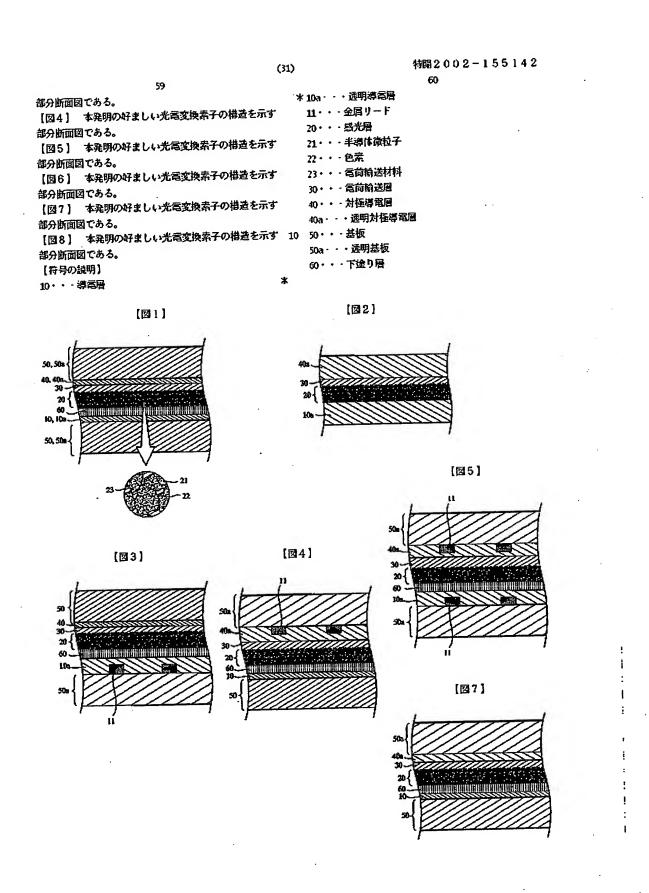
【図面の簡単な説明】

【図1】 本発明の好ましい光電変換素子の構造を示す 部分断面図である。

【図2】 本発明の好ましい光電変換素子の構造を示す 部分断面図である。

【図3】 本発明の好ましい光電変換素子の構造を示す

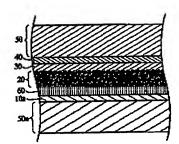
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(32)

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[図6]



【図8】

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HO1L 31/04

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Fターム(参考) 43002 CP031 CP091 CP171 [A016

DD086 EU117 FD090 FD207

HA05

43035 BA01 CA042 CA181 GA05

LB20

5F051 AA14 BA18 EA18 FA01 FA02

KA10

5G301 CA30 CD01

5H032 AA06 AS16 CC17 EE04 HH01

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CLAIMS

[Claim(s)]

[Claim 1] The following general formula (1): [Formula 1]

R₁: L₁-Q₀₁ R₂: L₂-Q₀₂

(However, R1 L1- Q01 (L1 expresses combination or a divalent connection machine)) when Q01 expresses a substituent when L1 expresses combination, and L1 expresses a divalent connection machine, Q01 expresses a hydrogen atom or a substituent Expressing, R2 is L2-Q02 (when Q02 expresses a substituent when L2 expresses combination or a divalent connection machine and L2 expresses combination, and L2 expresses a divalent connection machine, Q02 exprésses a hydrogen atom or a substituent.). it expresses The electrolyte constituent characterized by containing the siloxane compound which has at least two substituents which react with an electrophile agent and can form covalent bond including the repeat unit expressed.

[Claim 2] The electrolyte constituent characterized by the substituent which reacts with the aforementioned electrophilic agent and can form covalent bond in an electrolyte constituent according to claim 1 being a basic group.

[Claim 3] The electrolyte constituent characterized by pKa(s) of the conjugate acid of the compound which comes to add hydrogen to the aforementioned basic group being 3-15 in an electrolyte constituent according to claim 2.

[Claim 4] The electrolyte constituent characterized by the aforementioned basic group being an imidazolyl machine which is not replaced [the pyridyl machine which is not replaced / substitution or /, substitution, or] in an electrolyte constituent according to claim 2 or 3.

[Claim 5] It sets to an electrolyte constituent according to claim 1 to 4, and the aforementioned siloxane compound is following general formula (2):. [Formula 2]

(however the substituent which Q1 and Q2 react with the aforementioned electrophile agent independently, respectively, and can form covalent bond are expressed, R11-R16 express independently the aryl group which is not replaced [the alkyl group which is not replaced / substitution or /, substitution, or], respectively, L11 and L12 express a divalent connection machine independently, respectively, and n expresses the integer of 1-1000. Electrolyte constituent characterized by what is expressed by).

[Claim 6] It sets to an electrolyte constituent according to claim 5, and the aforementioned siloxane compound is following general formula (3):. [Formula 3]

$$\begin{pmatrix}
Q_{11} \\
N
\end{pmatrix} - L_{11} - Si - O \begin{pmatrix}
R_{13} \\
Si - O \\
R_{14}
\end{pmatrix} - Si - L_{12} - \begin{pmatrix}
Q_{21} \\
N
\end{pmatrix}$$
...(3)

(however Q11 and Q21 express the atomic group which forms 5 or 6 member ring with a nitrogen atom independently, respectively, R11-R16 express independently the aryl group which is not replaced [the alkyl group which is not replaced / substitution or /, substitution, or], respectively, L11 and L12 express a divalent connection machine independently, respectively, and n expresses the integer of 1-1000. Electrolyte constituent characterized by what is expressed by).

[Claim 7] The electrolyte constituent characterized by being constituted with one or more sorts of atoms chosen from the group which the above Q11 and Q21 becomes from a carbon atom, a hydrogen atom, a nitrogen atom, an oxygen atom, and a sulfur atom, respectively in an electrolyte constituent according to claim 6.

[Claim 8] The electrolyte constituent characterized by the above 5 or 6 member rings being an imidazole ring or a pyridine ring in an electrolyte constituent according to claim 6 or 7. [Claim 9]: The electrophile agent which has at least two leaving groups, and the following general formula (1) [Formula 4]

$$\begin{array}{c}
\begin{pmatrix} R_1 \\ Si - O \end{pmatrix} \\
R_2 \\
\end{array}$$

R₁: L₁-Q₀₁ R₂: L₂-Q₀₂

(However, R1 L1- Q01 (L1 expresses combination or a divalent connection machine)) when Q01 expresses a substituent when L1 expresses combination, and L1 expresses a divalent connection machine, Q01 expresses a hydrogen atom or a substituent Expressing, R2 is L2-Q02 (when Q02 expresses a substituent when L2 expresses combination or a divalent connection machine and L2 expresses combination, and L2 expresses a divalent connection machine, Q02 expresses a hydrogen atom or a substituent.). it expresses The electrolyte constituent characterized by containing the polymer which the siloxane compound which has at least two substituents which react with the aforementioned electrophile agent and can form covalent bond is made to react including the repeat unit expressed, and is obtained.

[Claim 10] It sets to an electrolyte constituent according to claim 9, and the aforementioned siloxane compound is following general formula (2):. [Formula 5]

$$Q_{1} - L_{11} - S_{12} - O \begin{pmatrix} R_{13} \\ S_{1} - O \\ R_{12} \end{pmatrix} - \begin{pmatrix} R_{13} \\ S_{1} - O \\ R_{14} \end{pmatrix}_{n} - \begin{pmatrix} R_{15} \\ S_{1} - C \\ R_{18} \end{pmatrix} - C_{2}$$
 (2)

(however the substituent which Q1 and Q2 react with the aforementioned electrophile agent independently, respectively, and can form covalent bond are expressed, R11-R16 express independently the aryl group which is not replaced [the alkyl group which is not replaced / substitution or /, substitution, or], respectively, L11 and L12 express a divalent connection machine independently, respectively, and n expresses the integer of 1-1000. Electrolyte constituent characterized by what is expressed by).

[Claim 11] It sets to an electrolyte constituent according to claim 10, and the aforementioned siloxane compound is following general formula (3):. [Formula 6]

$$\begin{pmatrix}
Q_{11} \\
N \end{pmatrix} - L_{11} - S_{12} - Q_{13} \\
R_{12} - Q_{13} \\
R_{14} - Q_{15} \\
R_{16} - Q_{21} \\
R$$

(however Q11 and Q21 express the atomic group which forms 5 or 6 member ring with a nitrogen

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atom independently, respectively, R11-R16 express independently the aryl group which is not replaced [the alkyl group which is not replaced / substitution or /, substitution, or], respectively, L1I and L12 express a divalent connection machine independently, respectively, and n expresses the integer of 1-1000. Electrolyte constituent characterized by what is expressed by).

[Claim 12] The electrolyte constituent characterized by pKa of the conjugate acid of the anion which the aforementioned leaving group ****s and produces in an electrolyte constituent according to claim 9 to 11 being ten or less.

[Claim 13] The electrolyte constituent characterized by the aforementioned leaving group being a halogen atom, an alkylsulfonyloxy machine, or an arylsulfonyloxy machine, respectively in an electrolyte constituent according to claim 9 to 12.

[Claim 14] The electrolyte constituent characterized by a solvent content being below 10 mass % of the whole electrolyte constituent in an electrolyte constituent according to claim 1 to 13.

[Claim 15] The electrolyte constituent characterized by containing an iodine salt and/or iodine in addition to the aforementioned siloxane compound and the aforementioned polymer in an electrolyte constituent according to claim 1 to 14.

[Claim 16] The electrolyte constituent characterized by being used for a photoelectric cell in an electrolyte constituent according to claim 1 to 15.

[Claim 17] The optoelectric transducer characterized by the aforementioned charge transporting bed containing an electrolyte constituent according to claim 1 to 16 in the optoelectric transducer which has a conductive layer, a photosensitive layer, a charge transporting bed, and a counter electrode. [Claim 18] The optoelectric transducer characterized by containing the semiconductor particle to which sensitization of the aforementioned photosensitive layer was carried out with coloring matter in an optoelectric transducer according to claim 17.

[Claim 19] The optoelectric transducer characterized by the aforementioned semiconductor particle containing a metal chalcogenide particle in an optoelectric transducer according to claim 18. [Claim 20] The optoelectric transducer characterized by the aforementioned metal chalcogenide particle containing a titanium oxide particle in an optoelectric transducer according to claim 19. [Claim 21] The optoelectric transducer characterized by the aforementioned coloring matter being metal complex coloring matter and/or poly methine coloring matter in an optoelectric transducer according to claim 17 to 20.

[Claim 22] The photoelectric cell using the optoelectric transducer according to claim 17 to 21.

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DETAILED DESCRIPTION

[Detailed Description of the Invention]

[0001]

[The technical field to which invention belongs] this invention relates to the optoelectric transducer and photoelectric cell in which the endurance and the photoelectric transfer characteristic which were excellent since the electrolyte constituent excellent in endurance and charge transportation ability and this electrolyte constituent were used are shown.

[0002]

[Description of the Prior Art] The liquefied electrolyte constituent (electrolytic solution) which dissolved the electrolyte salt in the solvent has been used from the former as an electrolyte of electrochemical elements, such as a cell, a capacitor, a sensor, a display device, and a record element. However, in the electrochemical element using such a liquefied electrolyte constituent, this constituent may be revealed between prolonged use or preservation, and reliability is missing. [0003] Although U.S. JP,4927721,B etc. is indicating the optoelectric transducer using the semiconductor particle which carried out sensitization with coloring matter, and the photoelectrochemical cell using this in Nature, the 353rd volume, the 737-740th page, and 1991, since the liquefied electrolyte constituent is used for the charge transporting bed also in these, this constituent reveals or is drained between prolonged use or preservation, a photoelectric conversion efficiency falls remarkably or there is a case where it stops functioning as an element. [0004] WO 93/No. 20565 proposed the optoelectric transducer which used the solid electrolyte under such a situation. Moreover, the Chemical Society of Japan, 7, 484 pages (1997) JP,7-288142,A, Solid State Ionics, 89, 263, and (1986) JP,9-27352,A proposed the optoelectric transducer containing the solid electrolyte which used the bridge formation polyethylene-oxide system high molecular compound. However, the optoelectric transducer using these solid electrolytes has the photoelectric transfer characteristic, especially inadequate short-circuit current density, and, in addition, its endurance is not enough, either.

[0005] Moreover, in order to prevent disclosure and an exhaustion of an electrolyte constituent and to raise the endurance of an optoelectric transducer, the method of using a pyridinium salt, an imidazolium salt, a thoria ZORIUMU salt, etc. is indicated (WO 95/No. 18456, JP,8-259543,A, electrochemistry, the 65th volume, No. 11, 923page (1997), etc.). These salts are in a melting state in ordinary temperature (near 25 degree C), and are called room temperature fused salt. Since solvents, such as water and an organic solvent, are unnecessary or little and can be managed with this method, the endurance of a cell improves. However, especially the optoelectric transducer using such room temperature fused salt has a low open circuit voltage, and its photoelectric conversion efficiency is not good.

[0006]

[Problem(s) to be Solved by the Invention] Therefore, the purpose of this invention is offering the optoelectric transducer and photoelectric cell in which the endurance and the photoelectric transfer characteristic which were excellent since the electrolyte constituent excellent in endurance and charge transportation ability and this electrolyte constituent were used are shown.

[0007]

[Means for Solving the Problem] The electrolyte constituent containing the polymer which this invention person makes the electrolyte constituent containing a siloxane compound including a http://www4.ipdl.jpo.go.jp/cgi-bin/tran_web_cgi_ejje 6/3/2003

specific repeat unit and this siloxane compound react with an electrophilic agent wholeheartedly in view of the above-mentioned purpose as a result of research, and is obtained discovered that the outstanding charge transportation ability and outstanding endurance were shown, and hit on an idea of it to this invention.

[0008] namely, the first electrolyte constituent of this invention -- following general formula (1): -- [Formula 7]

$$\begin{array}{c}
\begin{pmatrix}
R_1 \\
Si - O
\end{pmatrix}
\\
R_2
\end{array}$$

R₁: L₁-Q₀₁ R₂: L₂-Q₀₂

(However, R1 L1- Q01 (L1 expresses combination or a divalent connection machine)) when Q01 expresses a substituent when L1 expresses combination, and L1 expresses a divalent connection machine, Q01 expresses a hydrogen atom or a substituent Expressing, R2 is L2-Q02 (when Q02 expresses a substituent when L2 expresses combination or a divalent connection machine and L2 expresses combination, and L2 expresses a divalent connection machine, Q02 expresses a hydrogen atom or a substituent.). it expresses It is characterized by containing the siloxane compound which has at least two substituents which react with an electrophilic agent and can form covalent bond including the repeat unit expressed.

[0009] Moreover, it is characterized by the second electrolyte constituent of this invention containing the polymer which the siloxane compound which has the electrophilic agent which has at least two leaving groups, and at least two substituents which react with an electrophilic agent and can form covalent bond including the repeat unit expressed by the above-mentioned general formula (1) is made to react, and is obtained.

[0010] The first of this invention and second electrolyte constituents can be preferably used for a photoelectric cell. The optoelectric transducer of this invention has a conductive layer, a photosensitive layer, a charge transporting bed, and a counter electrode, and it is characterized by this charge transporting bed containing the electrolyte constituent of the above first, or the second electrolyte constituent. The photoelectric cell of this invention uses this optoelectric transducer. [0011] By filling the following conditions with this invention, the optoelectric transducer and photoelectric cell in which the electrolyte constituent which has further excellent endurance or charge transportation ability, the further excellent endurance, and the photoelectric transfer characteristic are shown are obtained.

[0012] (1) In the first and second electrolyte constituents, as for the substituent which reacts with an electrophilic agent and can form covalent bond, it is desirable that it is a basic group, and this basic group is an imidazolyl machine which is not replaced [the pyridyl machine which is not replaced / substitution or /, substitution, or] especially preferably. As for pKa of the conjugate acid of the compound which comes to add hydrogen to this basic group, it is desirable that it is 3-15. [0013] (2) As for the siloxane compound used for the first and second electrolyte constituents, being expressed by the following general formula (2) is desirable, and being expressed by the following general formula (3) is more desirable. [Formula 8]

$$Q_{1} - L_{11} - S_{12} - O \begin{pmatrix} R_{13} \\ SI - O \\ R_{14} \end{pmatrix} = \begin{pmatrix} R_{15} \\ Si - L_{12} - Q_{2} \\ R_{18} \end{pmatrix}$$
 (2)

The substituent which Q1 and Q2 react with the above-mentioned electrophilic agent independently, respectively, and can form covalent bond is expressed among a general formula (2), R11-R16 express independently the aryl group which is not replaced [the alkyl group which is not replaced / substitution or /, substitution, or], respectively, L11 and L12 express a divalent connection machine independently, respectively, and n expresses the integer of 1-1000.

Q11 and Q21 express the atomic group which forms 5 or 6 member ring with a nitrogen atom independently, respectively among a general formula (3), R11-R16 express independently the aryl group which is not replaced [the alkyl group which is not replaced / substitution or /, substitution, or], respectively, L11 and L12 express a divalent connection machine independently, respectively, and n expresses the integer of 1-1000.

[0014] (3) As for Q11 and Q21 in a general formula (3), in the first and second electrolyte constituents, it is desirable respectively to be constituted by one or more sorts of atoms chosen from the group which consists of a carbon atom, a hydrogen atom, a nitrogen atom, an oxygen atom, and a sulfur atom.

[0015] (4) As for 5 or 6 member ring which Q11 and Q21 in a general formula (3) form with a nitrogen atom, respectively, in the first and second electrolyte constituents, it is desirable that they are especially an imidazole ring or a pyridine ring.

[0016] (5) As for pKa of the conjugate acid of the anion which the leaving group which an electrophilic agent has ****s and produces, in the second electrolyte constituent, it is desirable that it is ten or less.

[0017] (6) As for the leaving group which an electrophilic agent has, in the second electrolyte constituent, it is desirable respectively that they are a halogen atom, an alkylsulfonyloxy machine, or an arylsulfonyloxy machine.

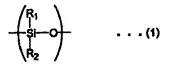
[0018] (7) As for the first and second solvent contents of an electrolyte constituent, it is desirable that it is especially below 10 mass % of the whole electrolyte constituent.

[0019] (8) As for the first and second electrolyte constituents, it is desirable to contain an iodine salt and/or iodine in addition to the above-mentioned siloxane compound and the above-mentioned polymer.

[0020] (9) As for the photosensitive layer of an optoelectric transducer, it is desirable to contain the semiconductor particle by which sensitization was carried out with coloring matter. As for this semiconductor particle, it is desirable that a metal chalcogenide particle is included, and, as for a metal chalcogenide particle, it is desirable that a titanium oxide particle is included. Moreover, as for coloring matter, it is desirable that they are metal complex coloring matter and/or poly methine coloring matter. [0021]

[Embodiments of the Invention] [1] The first electrolyte constituent of an electrolyte constituent this invention contains the specific siloxane compound mentioned later. Moreover, the second electrolyte constituent of this invention contains the polymer which this siloxane compound is made to react with the electrophile agent which has at least two leaving groups, and is obtained. The second electrolyte constituent of this invention hardly shows a fluidity, but is excellent in endurance and charge transportation ability. The first of this invention and second electrolyte constituents may contain an electrolyte salt, a solvent, etc. further. Hereafter, each the first of this invention and second components of an electrolyte constituent are explained in full detail.

[0022] (A) The siloxane compound used for the first of a siloxane compound this invention and second electrolyte constituents has at least two substituents which react with an electrophile agent and can form covalent bond, including the repeat unit expressed by the following general formula (1). In the second electrolyte constituent of this invention, this siloxane compound receives ornamentation of alkylation, class[the / 4th]-izing, etc. by the electrophile agent. [Formula 10]



R₁: L₁-Q₀₁ R₂: L₂-Q₀₂

[0023] R1 expresses L1-Q01 among a general formula (1), and R2 expresses L2-Q02. Here, when Q01 expresses a substituent when L1 expresses combination or a divalent connection machine and L1 expresses combination, and L1 expresses a divalent connection machine, Q01 expresses a hydrogen atom or a substituent. Moreover, when Q02 expresses a substituent when L2 expresses combination or a divalent connection machine and L2 expresses combination, and L2 expresses a divalent connection machine, Q02 expresses a hydrogen atom or a substituent. when they may also be included although a siloxane compound includes one repeat unit expressed by the general formula (1), and more than one are included, even if R1 and R2 in each repeat unit are the same respectively, they may differ [two or more]

[0024] When L1 or L2 expresses a divalent connection machine, as the example An alkylene machine, An alkenylene group, an arylene machine, -O-, -S-, -CO-, -NR'- (R' is a hydrogen atom or an alkyl group), - SO2- and - SiR" -- R"'- (R -- "and R"' -- Respectively -- Alkyl Group --) An aryl group, an alkoxy group or aryloxy groups, such combination, etc. are mentioned. Especially -(CH2) m1-, -O-, -(OCH2CH2) m1-, - M1-O-, -(OCH2CH2) M1-CH2-, (OCH2CH2) - M1-, - (OCH2CH2CH2) M1-O-, (OCH2CH</SUB>2CH2) - (OCH2CH2CH2) m1-CH2-, -(CH2) m1-(Si (CH3)2-O) m2-, and -O-(CH2) m1-(Si(CH3)2-O) m2- is desirable. In addition, m1 and m2 express the integer of 1-20, respectively.

[0025] the case where Q01 and Q02 express a substituent -- as the example of a desirable substituent -- an alkyl group (the shape of a straight chain --) You may be a letter of branching, or annular. For example, a methyl group, an ethyl group, n-propyl group, An isopropyl machine, t-butyl, n-octyl machine, a ray KOSHIRU machine, 2-chloro ethyl group, 2-cyano ethyl group, a 2-ethylhexyl machine, a cyclohexyl machine, a cyclopentylic group, aryl groups (for example, a phenyl group --), such as a 4-n-dodecyl cyclohexyl machine Heterocycle machines, such as p-tolyl group, a naphthyl group, and m-chlorophenyl machine (it is the univalent basis which comes preferably to remove one hydrogen atom from the aromatic heterocycle compound or un-aromatic heterocycle compound which is not replaced [the substitution of 5 or 6 members, or]) For example, 2-furil machine, 2thienyl group, 2-pyrimidinyl group, 2-pyridyl machine, halogen atoms (for example, a chlorine atom --), such as 4-pyridyl machine and 1-imidazolyl machine a cyano group, a nitro group and hydroxyl groups, such as a bromine atom and an iodine atom, and an alkoxy group (for example, a methoxy machine --) An ethoxy basis, an isopropoxy group, a t-butoxy machine, n-octyloxy machine, a 2methoxyethoxy machine, -O(CH2CH2O) mCH3 grade, and a silyloxy machine (for example, a trimethyl silyloxy machine --) t-buthyldimethyl silyloxy machine, a trimethoxy silyloxy machine, etc., an acyloxy machine (for example, a formyloxy machine, an acetyloxy machine, and a pivaloyloxy machine --) A stearoyl oxy-basis, a benzoyloxy machine, p-methoxypheny carbonyloxy group, etc., a carbamoyloxy machine (for example, N and an N-dimethylcarbamoyloxy machine --) A N,Ndiethylcarbamoyloxy machine, morpholino carbonyloxy group, An N and N-G n-octyl aminocarbonyl oxy-basis, an N-n-octyl carbamoyloxy machine, etc., alkoxy carbonyloxy group (for example, a methoxycarbonyloxy machine --) An ethoxycarbonyloxy machine, t-buthoxycarbonyloxy machine, noctyl carbonyloxy group, etc., aryloxy carbonyloxy group (for example, a phenoxy carbonyloxy machine --) p-methoxy phenoxy carbonyloxy machine, an p-n-hexadecyl oxy-phenoxy carbonyloxy machine, etc., the amino group (for example, the amino group, a methylamino machine, a dimethylamino machine, and the Ernie Reno machine --) the acylamino machines (for example, a formylamino machine --), such as N-methyl ANIRINO machine and a diphenylamino machine An acetylamino machine, the pivaloyl amino group, the lauroyl amino group, a benzoylamino machine, 3, 4, a 5-tree n-octyloxy phenyl carbonylamino machine, etc., the aminocarbonyl amino group (for example, carbamoyl amino machine, N, and N-dimethylamino carbonylamino machine --) N and N-

diethylamino carbonylamino machine, a morpholino carbonylamino machine, etc., an alkoxycarbonylamino machine (for example, a methoxycarbonylamino machine --) An ethoxycarbonylamino machine, t-butoxycarbonylamino machine, n-octadecyloxycarbonylamino machine, aryloxycarbonylamine machines (for example, a phenoxycarbonylamino machine --), such as N-methyl methoxycarbonylamino machine p-chloro phenoxycarbonylamino machine, an m-noctyloxy phenoxycarbonylamino machine, etc., a sulfamoylamino group (for example, sulfamoylamino group, N, and N-dimethylamino sulfonylamino machine --) alkyl sulfonylamino machines (for example, a methylsulfonylamino machine --), such as an N-n-octyl amino sulfonylamino machine aryl sulfonylamino machines (for example, a phenyl sulfonylamino machine --), such as a butylsulphonylamino machine 2, 3, 5-TORIKURORO phenyl sulfonylamino machine, pmethylphenyl sulfonylamino machine, etc., a sulfhydryl group and an alkyl thio machine (for example, a methylthio machine and an ethyl thio machine --) aryl thio machines (for example, a phenylthio machine --), such as an n-hexadecyl thio machine heterocycle thio machines (for example, a 2-benzothiazolethio group --), such as p-chloro phenylthio machine and m-methoxy phenylthio machine sulfamoyl groups (for example, N-ethyl sulfamoyl group --), such as a 1-phenyl tetrazole-5-IRUCHIO machine N-(3-dodecyloxy propyl) sulfamoyl group, N, and N-dimethyl sulfamoyl group, N-acetyl sulfamoyl group, N-benzoyl sulfamoyl group, alkyl sulfinyl machines (for example, a methyl sulfinyl machine --), such as N-(N'-phenylcarbamoyl) sulfamoyl group aryl sulfinyl machines (for example, a phenyl sulfinyl machine --), such as an ethyl sulfinyl machine alkyl sulfonyl machines (for example, a methyl sulfonyl machine --), such as p-methylphenyl sulfinyl machine aryl sulfonyl machines (for example, a phenyl sulfonyl machine --), such as an ethyl sulfonyl machine acyl groups (for example, an acetyl group --), such as p-methylphenyl sulfonyl machine A pivaloyl machine, 2chloro acetyl group, a stearoyl machine, a benzoyl, aryloxy carbonyl groups (for example, a phenoxy carbonyl group --), such as an p-n-octyloxy phenyl carbonyl group o-chloro phenoxy carbonyl group, m-nitroglycerine phenoxy carbonyl group, alkoxy carbonyl groups (for example, a methoxycarbonyl group --), such as a p-t-butyl phenoxy carbonyl group An ethoxycarbonyl machine, a tbutoxycarbonyl machine, n-octadecyl oxycarbonyl machine, etc., a carbamoyl group (for example, a carbamoyl group and N-methyl carbamoyl group --) An N and N-dimethyl carbamoyl-group, N, and N-G n-octyl carbamoyl group, Silyl machines, such as N-(methyl sulfonyl) carbamoyl group (it is the silyl machine which is not replaced [the substitution of carbon numbers 3-30, or] preferably) For example, a trimethylsilyl machine, t-butyldimethylsilyl machine, a phenyl dimethylsilyl machine, etc., Phosphino machines (being the phosphino machine which is not replaced [the substitution of carbon numbers 2-30 or] preferably for example, a dimethyl phosphino machine, a diphenyl phosphino machine, a methylphenoxy phosphino machine, etc.) etc. are mentioned. Especially, an alkyl group, an aryl group, a silyl machine, an alkoxy group, an aryloxy group, a silyloxy machine, a heterocycle machine, the amino group, an alkyl thio machine, and a phosphino machine are more desirable, and an alkyl group, a silyl machine, an alkoxy group, a silyloxy machine, and especially a heterocycle machine are desirable.

[0026] The above-mentioned siloxane compound has two or more substituents which react with an electrophile agent and can form covalent bond. As for the substituent which reacts with an electrophile agent and can form covalent bond, in the first and second electrolyte constituents, it is desirable that it is a basic group. pKa of the conjugate acid of the compound with which a basic group comes to add hydrogen to it points out three or more bases here. As for pKa of this conjugate acid, it is desirable that it is 3-15, and it is more desirable that it is 4-12. such a basic group — the amino group (a dimethylamino machine and a diethylamino machine —) nitrogen-containing heterocycle machines (a morpholino machine and a quinuclidinyl machine —), such as the Ernie Reno machine A piperazinyl machine, a piperidino machine, a pyrrolidino machine, an imidazolyl machine, 2-methyl imidazolyl machine, A quinolyl machine, an acridinyl machine, a pyridyl machine, 2-methyl pyridyl machine, It is desirable that they are guanidino machines (trimethyl guanidino machine etc.), such as a diazabicyclo undecenyl machine, it is more desirable that it is a nitrogen-containing heterocycle machine, and it is desirable that it is especially the imidazolyl machine which is not replaced [the pyridyl machine which is not replaced / substitution or /, substitution, or]. The above-mentioned siloxane compound may have such a basic group at the side chain and/or end in the repeat unit

expressed by the general formula (1). When it has this basic group in the side chain in the repeat unit expressed by the general formula (1), Q01 in a general formula (1) and/or Q02 are these basic groups.

[0027] As for the siloxane compound used for the first of this invention, and second electrolyte constituents, being expressed by the following general formula (2) is desirable, and being expressed by the following general formula (3) is more desirable. [Formula 11]

[0028] Q1 and Q2 express the substituent which reacts with an electrophile agent independently, respectively and can form covalent bond among a general formula (2). The electrophile agent in this substituent and the atom which reacts are a nitrogen atom, the Lynn atom, or a sulfur atom preferably, is a nitrogen atom or the Lynn atom more preferably, and is a nitrogen atom especially preferably. As a substituent which Q1 and Q2 express, the amino group, a phosphino machine, a heterocycle machine, an alkyl thio machine, etc. are mentioned.

[0029] R11-R16 express independently the aryl group which is not replaced [the alkyl group which is not replaced / substitution or /, substitution, or] among a general formula (2), respectively. R11-R16 are the alkyl groups of carbon numbers 1-10 preferably, are the alkyl group of carbon numbers 1-3 more preferably, and are a methyl group especially preferably.

[0030] The above Q1 and Q2, and R11-R16 may have the substituent, respectively. as the desirable example of this substituent -- an alkyl group (a methyl group and an ethyl group --) A propyl group, an isopropyl machine, a butyl, a pentyl machine, a hexyl machine, An octyl machine, a 2-ethylhexyl machine, t-octyl machine, a decyl group, the dodecyl, A tetradecyl machine, 2-hexyl decyl group, an octadecyl machine, a cyclohexyl machine, alkenyl machines (a vinyl group --), such as a cyclopentylic group, 2-carboxy ethyl group, and a benzyl A halogens atom, such as an allyl group (a fluorine atom, a chlorine atom, a bromine atom, iodine atom, etc.), A cyano group, an alkoxy group (a methoxy machine, an ethoxy basis, methoxyethoxy machine, etc.), aryloxy machines (phenoxy machine etc.) and an alkyl thio machine (a methylthio machine --) Acyl groups, such as an ethyl thio machine (an acetyl group, a propionyl machine, benzoyl, etc.), sulfonyl machines (a methane sulfonyl machine, benzenesulphonyl machine, etc.) and an acyloxy machine (an acetoxy machine --) sulfonyloxy machines (a methane sulfo NIRIOKISHI machine --), such as a benzoyloxy machine Phosphonyl groups, such as a toluenesulfonyloxy machine (diethyl phosphonyl group etc.), Amide groups (an acetylamino machine, benzoylamino machine, etc.), carbamoyl groups (N and N-dimethyl carbamoyl group, N-phenylcarbamoyl machine, etc.), an aryl group, heterocycle machines (a phenyl group, toluyl machine, etc.) (a pyridyl machine, an imidazolyl machine, furanyl machine, etc.), etc. are mentioned.

[0031] L11 and L12 express a divalent connection machine independently among a general formula (2), respectively. As an example of this divalent connection machine, the connection machine which comes to combine an alkylene machine, an alkenylene group, an arylene machine, -O-, -S-, -CO-, -NR'- (for R' to express a hydrogen atom or an alkyl group), -SO2-, -SiRR'- (for R and R' to express an alkyl group or an aryl group, respectively), and these [two / or more] is mentioned. [0032] When L11 and L12 are an alkylene machine, an alkenylene group, or an arylene machine, These A halogen atom (a fluorine atom, a chlorine atom, a bromine atom, iodine atom, etc.), A hydroxyl group, the amino group, a nitro group, a carboxyl group, a carbamoyl group, a sulfonic group, A sulfonamide machine, acyl groups (a HORUMIRU machine, acetyl group, etc.), an acyloxy machine, The acylamino machine, alkyl groups (an acetamino machine, bends amino group, etc.), 6/3/2003

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You may have substituents, such as alkoxy groups (a methoxy machine, an ethoxy basis, methoxyethoxy machine, etc.), an AKOKISHI carbonyl group, an alkyl sulfonyl machine, an aryl group, an aryloxy group, and aryl sulfonyl machines (phenoxy machine etc.).

[0033] n expresses the integer of 1-1000 among a general formula (2). n is the integer of 1-500 preferably, and is the integer of 1-100 especially preferably. If n is larger than 1000, a reactant fall with ionic conductivity and an electrophile agent will be caused.

[0034] Q11 and Q21 express the atomic group which forms 5 or 6 member ring with a nitrogen atom independently, respectively among a general formula (3). As for Q11 and Q21, it is desirable to be constituted by one or more sorts of atoms chosen from the group which consists of a carbon atom, a hydrogen atom, a nitrogen atom, an oxygen atom, and a sulfur atom.

[0035] As for 5 or 6 member ring formed of Q11 and Q21, it is desirable that it is an unsaturation ring. As 5 member rings, a pyrrolidine ring, an oxazole ring, a thiazole ring, an imidazole ring, a pyrazole ring, an isoxazole ring, a thiadiazole ring, an oxadiazole ring, and a triazole ring are desirable, a thiazole ring, an imidazole ring, and a triazole ring are more desirable, and especially an imidazole ring is desirable. As 6 member rings, a morpholine ring, a piperidine ring, a pyridine ring, a pyridine ring, a pyridine ring, a pyridine ring is desirable.

[0036] R11-R16, L11 and L12, and n in a general formula (3) are them in a general formula (2), and homonymy, and its same is said of a desirable mode.

[0037] Although the example 1-1 to 1-18 of the siloxane compound used for the first of this invention and second electrolyte constituents is shown below, this invention is not limited to them.

[Formula 13]

1-1
$$H_2N$$
 CH_3
 $CH_$

1-2
$$CH_3$$
 CH_3 $CH_$

[0039] [Formula 14]

[0040]

[Formula 15]

[0041] [Formula 16]

1-11

1-12

1-13

1-14

1-15

[0042] [Formula 17]

1-16

[0043] The siloxane compound used by this invention is easily compoundable with the substitution reaction by R1-H of a compound and/or R2-H which are expressed by the polymerization of the silane compound expressed by the following general formula (4), and the following general formula (5), the high DOROSHI relation reaction of the compound and olefin compound which are expressed by the following general formula (6), the condensation reaction of the compound and the alcoholic compound which are expressed by the following general formula (7), etc.

[Formula 18]

R41 and R42 express a halogen atom or an alkoxy group independently among a general formula (4), respectively.

[0045]

[Formula 19]

$$\begin{pmatrix}
R_{61} \\
Si \\
O
\\
R_{62}
\end{pmatrix}$$
(5)

R51 and R52 express an alkoxy group or an aryloxy group independently among a general formula (5), respectively.

[0046]

[Formula 20]

R11-R16 and n in a general formula (6) are them in a general formula (2), and homonymy, and its same is said of a desirable mode.

[0047]

[Formula 21]

R11-R16 and n in a general formula (7) are them in a general formula (2), and homonymy, and its same is said of a desirable mode.

[0048] (B) The electrophile agent used for the second electrolyte constituent of an electrophile agent this invention has at least two leaving groups. This electrophile agent reacts with "the substituent which reacts with an electrophile agent and can form covalent bond" which the above-mentioned siloxane compound has, and when alkylation, onium chlorination, the 4th class-ization, etc. carry out this substituent, it forms the shape of a straight line, and the polymer over which the bridge was

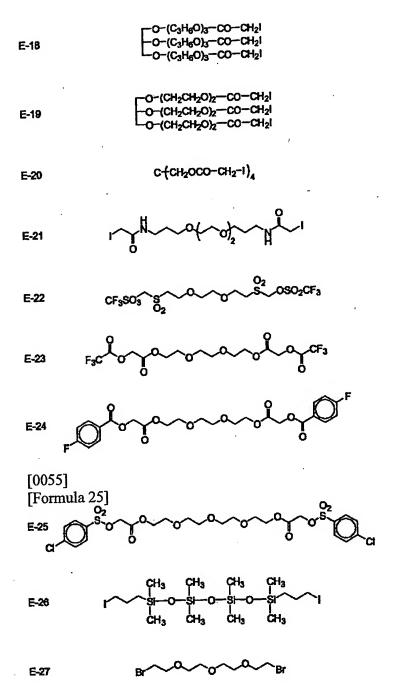
[0049] In order to make moderate the degree of cross linking of the polymer which the abovementioned siloxane compound and an electrophile agent are made to react, and is obtained, as for the number of leaving groups, it is desirable that they are 2-4 pieces, and it is desirable that they are especially two pieces. If there are many leaving groups, a degree of cross linking will become high, consequently membraneous quality becomes hard, and ionic conductivity falls. Moreover, as for pKa of the conjugate acid of the anion which a leaving group ****s and produces, it is desirable that it is ten or less, and it is more desirable that it is five or less.

[0050] Leaving groups may be a halogen atom, an alkylsulfonyloxy machine, an arylsulfonyloxy machine, an acyloxy machine, etc., respectively. A halogen atom, an alkylsulfonyloxy machine, and an arylsulfonyloxy machine are desirable especially. As a halogen atom, an iodine atom, a bromine atom, and a chlorine atom are desirable, and an iodine atom and a bromine atom are more desirable. As an alkylsulfonyloxy machine, a methyl sulfonyloxy machine, a chloro methyl sulfonyloxy machine, and perfluoroalkyl sulfonyloxy machines (trifluoromethyl sulfonyloxy machine etc.) are desirable. As an arylsulfonyloxy machine, a benzene sulfonyloxy machine, a p-toluenesulfonyloxy machine, p-chlorobenzene sulfonyloxy machine, and p-nitrobenzene sulfonyloxy machine are desirable. As an acyloxy machine, the alkylcarbonyloxy machines (trifluoromethyl carbonyloxy group etc.) and aryl-carbonyloxy groups (p-fluoro phenyl carbonyloxy group etc.) which carried out fluorine substitution of all or a part of hydrogen atoms are desirable.

[0051] The amount of the electrophile agent used can be arbitrarily defined according to the molecular weight or the degree of cross linking of a reaction rate with the above-mentioned siloxane compound, or the polymer to generate. The 0.01-2Eq of the 0.05-1.5Eq of the amount of the electrophile agent used is 0.1-1Eq especially preferably more preferably preferably to the number of mols of "the substituent which reacts with an electrophile agent and can form covalent bond" which a siloxane compound has. When the number of mols of the substituent which reacts with the electrophile agent which a siloxane compound has, and can form covalent bond is not clear, the mass ratio of the electrophile agent to the mass of a siloxane compound is one to 100 mass % preferably, and is three to 70 mass % more preferably. Even if it uses an electrophile agent independently, it may use two or more sorts together. Although this invention shows the example E-1 to E-27 of an usable electrophile agent hereafter, this invention is not limited to them.

[0052]

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[0056] (C) The polymer used for the second electrolyte constituent of a polymerization-reaction this invention can be obtained by the polymerization reaction of the above-mentioned electrophile agent and a siloxane compound. The polymerization of them is carried out by the alkylation reaction which occurs in detail between the electrophilic part in an electrophile agent, and the substituent which reacts with this electrophile agent in a siloxane compound, and can form covalent bond, the reaction (for example, the 4th class-ized reaction of nitrogen) which forms an onium salt. As for the mass average molecular weight of the polymer obtained, it is desirable that it is 1000-1 million, and it is more desirable that it is 2000-500,000.

[0057] As for polymerization reaction, it is desirable to carry out besides an electrophilic agent and a siloxane compound under the conditions with which the electrolyte salt mentioned later coexists. Although an electrolyte salt may be added after a reaction, it is difficult to distribute an electrolyte salt uniformly in a polymer in this case, and it is not desirable.

[0058] When preparing the reaction solution containing a siloxane compound, an electrophilic agent, and an electrolyte salt and performing polymerization reaction, when a [siloxane compound + electrolyte salt + solvent] is made into 100 mass %, as for the mass ratio of a siloxane compound, it is desirable to consider as 1 - 50 mass %, and it is more desirable to consider as 3 - 30 mass %. Since

carrier mobility will fall if a fluidity becomes that a siloxane compound is under 1 mass % inadequate and 60 mass % is exceeded, it is not desirable. In addition, even if it uses a siloxane compound independently, it may use two or more sorts together.

[0059] (D) As an electrolyte salt electrolyte salt, they are (a) I2 and an iodide (it LiI(s)), for example. NaI, KI, CsI, the metal iodide of CaI2 grade, tetrapod alkylammonium iodide, Combination with the 4th class ammonium iodine salts, such as pyridinium iodide and imidazolium iodide, etc., (b) -- Br2 and a bromide (LiBr, NaBr, KBr, CsBr, and the metal bromide of CaBr2 grade --) Combination with the 4th class ammonium bromine salts, such as a tetrapod alkylammonium star's picture and a pyridinium star's picture, etc., (c) Metal complexes (a ferrocyanic-acid salt-ferricyanic-acid salt, ferrocene-ferricinium ion, etc.), (d) sulfur compounds (the poly sodium sulfide, alkyl thiol-alkyl disulfide, etc.), (e) viologen coloring matter, a hydroquinone-quinone, etc. can be used. Especially, the combination of I2 and the 4th class ammonium iodine salt is desirable. You may mix and use an

[0060] Moreover, EP718288, WO 95/18456, J.Electrochem.Soc., Vol.143, No.10, and 3099 (1996), as an electrolyte salt Inorg. Chem., 35, and 1168-1178 (1996), JP,8-259543, A, electrochemistry, the 65th volume, No. 11, and 923 pages (1997) etc. -- fused salt, such as a pyridinium salt indicated, an imidazolium salt, and a thoria ZORIUMU salt, can also be used The quality of molten salt electrolysis is desirable especially from a viewpoint of coexistence of endurance and charge transportation ability. In addition, fused salt here is liquefied in a room temperature, or it is the salt of the low melting point and it is [as for the melting point, it is desirable that it is 100 degrees C or less, and] desirable [the melting point] that it is especially near a room temperature.

[0061] as the fused salt which can be preferably used by this invention -- the following general formula (Y-a) -- what is expressed by either is mentioned for and (Y-b) (Y-c) [0062]

[Formula 26]

[0063] Qy1 expresses the atomic group which forms the aromatic cation of 5 or 6 member ring with a nitrogen atom among a general formula (Y-a). As for Qy1, it is desirable to be constituted by one or more sorts of atoms chosen from the group which consists of a carbon atom, a hydrogen atom, a nitrogen atom, an oxygen atom, and a sulfur atom.

[0064] It is desirable that they are an oxazole ring, a thiazole ring, an imidazole ring, a pyrazole ring, an isoxazole ring, a thiadiazole ring, an oxadiazole ring, a triazole ring, the Indore ring, or a pyrrole ring, as for 5 member rings formed of Qy1, it is more desirable that they are an oxazole ring, a thiazole ring, or an imidazole ring, and it is desirable that they are especially an oxazole ring or an imidazole ring. As for 6 member rings formed of Qy1, it is desirable that they are a pyridine ring, a pyrimidine ring, a pyridazine ring, a pyrazine ring, or a triazine ring, and it is more desirable that it is

[0065] Ay1 expresses a nitrogen atom or the Lynn atom among a general formula (Y-b).

[0066] A general formula (Y-a), and (Y-b) (Y-c) inner Ry1-inner Ry6 are an alkyl group (even if it has the shape of the carbon atomic numbers 1-24 and a straight chain preferably and is a letter of branching) which is not replaced [substitution or] independently, respectively. You may be a ring type. Moreover, for example, a methyl group, an ethyl group, a propyl group, An isopropyl machine, a pentyl machine, a hexyl machine, an octyl machine, a 2-ethylhexyl machine, t-octyl machine, a decyl group, a dodecyl machine, a tetradecyl machine, 2-hexyl decyl group, ARUKENIRU machines which are not replaced [substitution or], such as an octadecyl machine, a cyclohexyl machine, and a cyclopentylic group (even if it has the shape of the carbon atomic numbers 2-24 and a straight chain preferably, you may be a letter of branching) For example, a vinyl group, an allyl group, etc. are expressed, and it is the alkyl group of the carbon atomic numbers 2-18, or the ARUKENIRU machine of the carbon atomic numbers 2-18 more preferably, and is the alkyl group of the carbon atomic numbers 2-6 especially preferably.

[0067] Moreover, among Ry1-Ry4 in a general formula (Y-b), the un-aromatic ring in which two or more connect with mutually and they contain Ay1 may be formed, two or more may connect mutually and they may form a ring structure among Ry1-Ry6 in a general formula (Y-c).

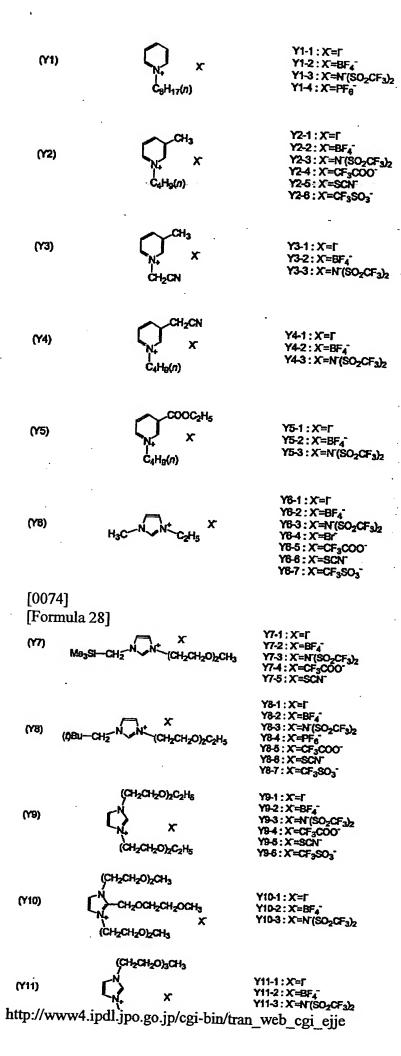
[0068] A general formula (Y-a), inner Qy1, and Ry1-Ry6 may have the substituent. as the desirable example of this substituent -- a halogen atom (it Cl(s) and Br(s) F --) cyano groups, such as I, and an alkoxy group (a methoxy machine, an ethoxy basis, and a methoxyethoxy machine --) Aryloxy machines (phenoxy machine etc.), such as a methoxyethoxy ethoxy basis, Alkyl thio machines (a methylthio machine, ethyl thio machine, etc.), an alkoxy carbonyl group (ethoxycarbonyl machine etc.), carbonate machines (ethoxycarbonyloxy machine etc.) and an acyl group (an acetyl group --) sulfonyl machines (a methane sulfonyl machine --), such as a propionyl machine and a benzoyl Acyloxy machines (an acetoxy machine, benzoyloxy machine, etc.), such as a benzenesulphonyl machine, A sulfonyloxy machine (a methane sulfonyloxy machine, toluenesulfonyloxy machine, etc.), phosphonyl groups (diethyl phosphonyl group etc.) and an amide group (an acetylamino machine --) Carbamoyl groups, such as a benzoylamino machine (N and N-dimethyl carbamoyl group etc.), an alkyl group (a methyl group, an ethyl group, a propyl group, an isopropyl machine, and a cyclo propyl group --) Aryl groups, such as a butyl, 2-carboxy ethyl group, and a benzyl, heterocycle machines (a phenyl group, toluyl machine, etc.) (a pyridyl machine, an imidazolyl machine, furanyl machine, etc.), ARUKENIRU machines (a vinyl group, 1-propenyl machine, etc.), a silyl machine, a silyloxy machine, etc. are mentioned.

[0069] The fused salt expressed by the above-mentioned general formula (Y-a) - (Y-c) either may form a polymer through either Qy1, and Ry1-Ry6.

[0070] You may use the fused salt expressed by the above-mentioned general formula (Y-a) - (Y-c) either, mixing with the salt which could use it, having mixed two or more sorts even if it used it independently, and replaced iodide ion I- by other anions. As an anion which replaces I-, halogenide ion, SCN- (Cl-, Br-, etc.), BF4-, PF6-, ClO4-, 2 (CF3SO2)N-, 2 (CF3CF2SO2)N-, CF3SO3-, CH3SO3-, CF3COO-, Ph4B-, 3(CF3SO2) C-, etc. are desirable. They are SCN-, BF4-, CF3SO3-, CF3COO-, or (CF3SO2) 2N- more preferably.

[0071] Moreover, alkali-metal salts, such as other iodine salts and CF3COOLi like LiI, CF3COONa, LiSCN, and NaSCN, can also be added. As for the addition of an alkali-metal salt, it is desirable to consider as a 0.02 - 2 mass % grade, and it is still more desirable to consider as 0.1 to 1 mass %. [0072] Although - (Y29) is listed to the example (Y1) of the electrolyte salt preferably used by this invention, and the following, they do not limit this invention. [0073]

[Formula 27]



[0075]

[Formula 29]

Y12-1:X≒Г Y12-2: X=BF4 Y12-3: X=N(\$O₂CF₃)₂

(Y13)

Y13-1 : X=F Y13-2:X=BF4 Y13-3: X=N(SO2CF3)2

(Y14)

Y14-1:X=[Y14-2:X=BF4 Y14-3: X=N(SO2CF3)2

(Y15)

Y15-1:X=F Y15-2: X=BF4 Y15-3: X=N(SO2CF3)2

Y16-1: X=F Y18-2: X=BF4 Y16-3: X=N(SO2CF3)2

[0076]

[Formula 30]

(Y17)

Y17-1:X=F Y17-2: X=BF₄⁻ Y17-3: X=N(\$O₂CF₈)₂ Y17-4: X=PF₆⁻

-(CH2CH2O)2CH3 X (Y18)

Y18-1 : X=Γ Y18-2: X=BF4 Y18-3: X=N(802CF3)2

(CH2CH2O)2CH3 (CH2CH2O)2CH3 (Y19) H3C(OH2CH2C)2

Y19-1: X=F Y19-2: X=BF4 Y19-3: X=N(SO2CF3)2 Y19-4: X=CF3COO' Y19-5: X=SCN Y19-8: X=CF3SO3

(Y20)

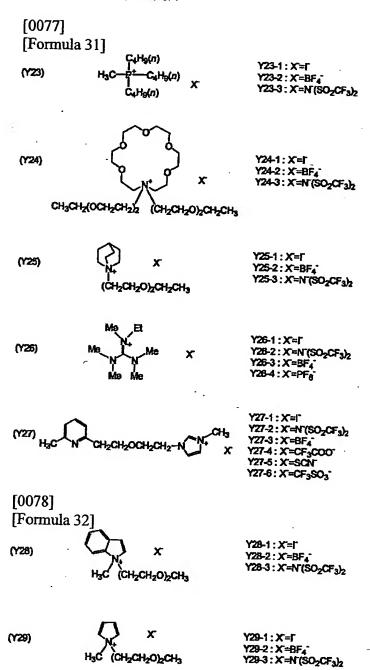
Y20-1:X=F Y20-2: X=BF₄ Y20-3: X=N(SO₂CF₃)₂

(Y21)

Y21-1: X'=Γ Y21-2: X=BF4 Y21-3: X=N(SO2CF3)2

http://www4.ipdl.jpo.go.jp/cgi-bin/tran_web_cgi_ejje

Y22-1:X=F Y22-2: X=BF4 Y22-3: X=N(SO2CF3)2



[0079] It is desirable not to use a solvent in this invention using what is in a melting state in ordinary temperature as an electrolyte salt. Although the solvent mentioned later may be added, as for the content of an electrolyte salt, it is desirable that it is more than 50 mass % to the whole electrolyte constituent, and it is desirable that it is especially more than 90 mass %. Moreover, as for the first of this invention, and second electrolyte constituents, it is desirable to contain the above-mentioned siloxane compound and iodine salts other than the above-mentioned polymer, and it is desirable that more than 50 mass % is an iodine salt among the salts to be used. Moreover, when using a solvent, it is desirable to make concentration of an electrolyte salt into 0.05 - 2 mol/l, and considering as 0.1 -

[0080] (E) As for the first of an iodine this invention, and second electrolyte constituents, it is desirable to contain iodine. As for an iodine content, it is desirable that it is 0.1 to 20 mass % to the whole electrolyte constituent, and it is more desirable that it is 0.5 to 5 mass %. Moreover, iodine and a bromine can be added in the reaction solution containing the siloxane compound, electrophilic agent, and electrolyte salt which were mentioned above, and it can also be made to generate a redox couple beforehand. As for the concentration of the iodine in this reaction solution, or a bromine,

considering as 0.01 - 0.3 mol/l is desirable.

[0081] (F) The first of a solvent this invention and second electrolyte constituents may contain the solvent. It is desirable that it is below the whole 50 mass %, as for the solvent content of an electrolyte constituent, it is more desirable that it is below 30 mass %, and it is desirable that it is especially below 10 mass %.

[0082] As a solvent, ionic mobility is high at hypoviscosity, or what can discover the ion conductivity which raised effective carrier concentration with the high dielectric constant, or was excellent since it was the both is desirable. as such a solvent -- a carbonate compound (ethylene carbonate --) Heterocyclic compounds, such as propylene carbonate (3-methyl-2-oxazolidinone etc.), ether compounds (a dioxane, diethylether, etc.) and chain-like ether (ethylene glycol dialkyl ether --) The propylene-glycol dialkyl ether, the polyethylene-glycol dialkyl ether, alcohols (a methanol --), such as the polypropylene-glycol dialkyl ether Ethanol, ethylene glycol monoalkyl ether, propylene-glycol monoalkyl ether, polypropylene-glycol monoalkyl ether, etc., polyhydric alcohol (ethylene glycol, a propylene glycol, and a polyethylene glycol --) nitryl compounds (an acetonitrile --), such as a polypropylene glycol and a glycerol Guru taro dinitrile, a methoxy acetonitrile, a propionitrile, Ester (a carboxylate, phosphoric ester, phosphonate, etc.), such as a benzonitrile and screw cyano ethyl ether, non-proton nature polar solvents (dimethyl sulfoxide (DMSO), sulfolane, etc.), water, etc. are mentioned. Especially, a carbonate compound, a nitryl compound, and a heterocyclic compound are desirable. These solvents may mix and use two or more sorts if needed.

[0083] (G) In addition, to the first of this invention, and second electrolyte constituents, it is desirable to add basic compounds, such as t-butyl pyridine [of a publication (1997)], 2-picoline, 2, and 6-lutidine, to J.Am.Ceram.Soc., 80 (12), 3157-3171, etc. The desirable density ranges in the case of adding a basic compound are 0.05-2M.

[0084] In order to gel the first and second electrolyte constituents, technique, such as a polymerization of the monomers containing polymer addition, oil gelling agent addition, and polyfunctional monomer and crosslinking reaction of polymer, can be used together. When making it gel by polymer addition, the compound of a publication etc. is usable to "Polymer Electrolyte Reviews -1 and 2" (coeditorship of J.R.MacCallum and C.A.Vincent, ELSEVIER APPLIED SCIENCE), and it is desirable to use a polyacrylonitrile or a polyvinylidene fluoride. When making it gel by oil gelling agent addition, J.Chem.Soc.Japan, Ind.Chem.Sec., 46, and 779 (1943), J.Am.Chem.Soc., 111, and 5542 (1989), J.Chem.Soc., Chem.Commun., 1993, 390, Angew.Chem.Int.Ed.Engl., 35, and 1949 (1996), It is desirable to use the compound which can use the compound indicated by Chem.Lett., 1996, 885, J.Chem.Soc., Chem.Commun., 1997, and 545 grades, and has amide structure. Moreover, the method of gelling the electrolytic solution given in JP,11-185863,A and the method of gelling the quality of molten salt electrolysis given in JP,2000-58140,A are also applicable to this invention. moreover, the case where an electrolyte constituent is made to gel by the crosslinking reaction of polymer -- JP,2000-17076,A -- said -- the cross linking technique indicated by 2000-86724 is also applicable

[0085] [2] The optoelectric transducer of an optoelectric-transducer this invention has a conductive layer, a photosensitive layer, a charge transporting bed, and a counter electrode. As preferably shown in drawing 1, a laminating is carried out to the order of a conductive layer 10, an under coat 60, a photosensitive layer 20, the charge transporting bed 30, and the counter electrode conductive layer 40, and a photosensitive layer 20 consists of charge transportation material 23 which permeated the opening between the semiconductor particle 21 by which sensitization was carried out with coloring matter 22, and the semiconductor particle 21 concerned. The charge transportation material 23 consists of the same component as the material used for the charge transporting bed 30. Moreover, in order to give intensity to an optoelectric transducer, you may form a substrate 50 as a ground of a conductive layer 10 and/or the counter electrode conductive layer 40. In this invention, it is arbitrary and the layer which consists the layer which consists of a conductive layer 10 and a substrate 50 to prepare of "a conductive base material", a counter electrode conductive layer 40, and a substrate 50 that it is arbitrary and is prepared is called "counter electrode." In addition, the conductive layer 10 in drawing 1, the counter electrode conductive layer 40, and a substrate 50 may be transparent

conductive-layer 10a, transparent counter electrode conductive-layer 40a, and transparent substrate 50a, respectively. That to which this optoelectric transducer is connected to an external load, and electric work (power generation) is done is a photoelectric cell, and it is the photosensor which was made for the purpose of sensing of optical information.

[0086] In the optoelectric transducer of this invention shown in drawing 1, when a semiconductor particle is n type, the light which carried out incidence to the photosensitive layer 20 containing the semiconductor particle 21 by which sensitization was carried out with coloring matter 22 excites coloring matter 22, and the electron of the high energy in the excited coloring matter 22 is passed to the conduction band of the semiconductor particle 21, and it reaches a conductive layer 10 by diffusion further. At this time, coloring matter 22 serves as an oxidant. In a photoelectric cell, while the electron in a conductive layer 10 works in an external circuit, it returns to the oxidant of coloring matter 22 through the counter electrode conductive layer 40 and the charge transporting bed 30, and coloring matter 22 is reproduced. A photosensitive layer 20 works as a negative electrode (optical anode), and a counter electrode 40 commits it as a positive electrode. On the boundaries (for example, the boundary of a conductive layer 10 and a photosensitive layer 20, the boundary of a photosensitive layer 20 and the charge transporting bed 30, the boundary of the charge transporting bed 30 and the counter electrode conductive layer 40, etc.) of each layer, the constituents of each class may be carrying out diffusive mixing mutually. Hereafter, each class is explained in detail. [0087] (A) A conductive base material conductivity base material consists of the monolayer of (1) conductive layer or (2) conductive layers, and two-layer [of a substrate]. In the case of (1), that at which intensity and sealing performance are fully maintained as a material of a conductive layer can be used, for example, it can use metallic materials (platinum, gold, silver, copper, zinc, titanium, aluminum, these alloys, etc.). In the case of (2), the substrate which has a conductive layer containing an electric conduction agent can be used for a photosensitive-layer side. As a desirable electric conduction agent, metals (for example, platinum, gold, silver, copper, zinc, titanium, aluminum, an indium, the alloy containing these, etc.), carbon, and conductive metallic oxides (what doped a fluorine or antimony to an indium-tin multiple oxide and the tin oxide) are mentioned. The thickness of a conductive layer has desirable about 0.02-10 micrometers.

[0088] A conductive base material has surface electrical resistance as good as a low. Surface electrical resistance is below 500hms / ** preferably, and is below 200hms / ** more preferably. [0089] When irradiating light from a conductive base material side, as for a conductive base material, it is desirable that it is substantially transparent. It means substantially that a light transmittance is it 10% or more that it is transparent in some or the whole region of a visible - near infrared region (400-1200nm). As for this light transmittance, it is desirable that it is 50% or more, and it is more desirable that it is 80% or more. It is desirable that the light transmittance of the wavelength region where a photosensitive layer has sensitivity especially is high.

[0090] What formed the transparent conductive layer which consists of a conductive metallic oxide in the front face of transparent substrates, such as glass and plastics, by an application or vacuum evaporationo as a transparent conductivity base material is desirable. As for a transparent conductive layer, it is desirable to consist of diacid-ized tin which doped a fluorine or antimony, or an indiumstannic-acid ghost (ITO). In addition to glass substrates, such as an advantageous soda glass and an alkali free glass without the influence of alkali elution, as a transparent substrate, a transparent polymer film is usable in respect of cost and intensity. As a material of a transparent polymer film, a triacetyl-cellulose (TAC), polyethylene-terephthalate (PET), polyethylenenaphthalate (PEN), syndiotactic polystyrene (SPS), polyphenylene-sulfide (PPS), polycarbonate (PC), polyarylate (PAr), polysulfone (PSF), polyester sulfone (PES), polyimide (PI), polyether imide (PEI), annular polyolefine, and bromine-ized phenoxy etc. is usable. In order to secure sufficient transparency, as for the coverage of a conductive metallic oxide, it is desirable to consider as per [0.01-100g] two 1m of base materials of glass or plastics.

[0091] It is desirable to use a metal lead in order to lower resistance of a transparent conductivity base material. The quality of the material of a metal lead has desirable metals, such as platinum, gold, nickel, titanium, aluminum, copper, and silver. As for a metal lead, it is desirable to install in a transparent substrate by vacuum evaporationo, sputtering, etc., and to prepare on it the transparent

conductive layer which consists of conductive tin oxide or ITO. The fall of the amount of incident lights by metal lead installation is more preferably suppressed to 1 - 5% less than 10%. [0092] (B) As for a photosensitive-layer (1) semiconductor photosensitive layer, it is desirable to contain the semiconductor particle by which sensitization was carried out with coloring matter. In a photosensitive layer, a semiconductor acts as a photo conductor, absorbs light, performs charge separation, and produces an electron and an electron hole. With the semiconductor by which coloring matter sensitization was carried out, generating of an optical absorption, the electron by this, and an electron hole takes place mainly in coloring matter, and a semiconductor bears the role which receives and transmits this electron (or electron hole). As for the semiconductor used by this invention, it is desirable that it is the n-type semiconductor which a conductor electron serves as a carrier under optical pumping, and gives an anode current.

[0093] The compounds (a strontium titanate, titanic-acid calcium, titanic-acid sodium, a barium titanate, niobic-acid potassium, etc.) which have an element semiconductor like silicon or germanium, a III-V system compound semiconductor, metaled chalcogenide (an oxide, a sulfide, selenides, those composites, etc.), and a perovskite structure as an example of the semiconductor used by this invention are mentioned. Metal chalcogenide is desirable especially.

[0094] As desirable metal chalcogenide, the oxide of titanium, tin, zinc, iron, a tungsten, a zirconium, a hafnium, strontium, an indium, a cerium, an yttrium, a lanthanum, vanadium, niobium, or a tantalum, cadmium, zinc, lead, silver, antimony or the sulfide of a bismuth, cadmium or a leaden selenide, the telluride of cadmium, etc. are mentioned. As other compound semiconductors, the selenide of phosphides, such as zinc, a gallium, an indium, and cadmium, a gallium arsenide, or a copper-indium, the sulfide of a copper-indium, etc. are mentioned. Furthermore, a composite like MxOySz or M1xM2yOz (an oxygen atom, x, and y and z express the number [atom / metal] with which M, M1, and M2 become, and, as for O, a valence becomes neutral, respectively) can also be used preferably.

[0095] Preferably the semiconductor used by this invention Si, TiO2, SnO2, Fe 2O3, WO3, ZnO, Nb 2O5, CdS, ZnS and PbS, Bi2S3, CdSe, CdTe, It is SrTiO3, GaP, InP, GaAs, CuInS2, or CuInSe2. More preferably TiO2, SnO2, Fe 2O3, WO3, ZnO, It is Nb 2O5, CdS and PbS, CdSe, SrTiO3 and InP, GaAs, CuInS2, or CuInSe2, is TiO2 or Nb 2O5 especially preferably, and is TiO2 most preferably. As for TiO2, it is desirable to include an anatase type crystal 70% or more, and it is more desirable that it is 100% anatase type crystal.

[0096] It is desirable to dope a metal in order to raise the electronic conductivity in a semiconductor. As a metal to dope, a divalent or trivalent metal is desirable. In order to prevent that a reverse current flows from a semiconductor to a charge transporting bed, it is also effective in a semiconductor to dope a univalent metal.

[0097] Although a single crystal or a polycrystal is sufficient as the semiconductor used for this invention, the polycrystal from a viewpoint of a manufacturing cost, raw-material reservation, and an energy pay back time is desirable. The amorphous portion may be included in part. As for a semiconductor, it is desirable to use as a porous membrane which consists of a semiconductor particle.

[0098] Generally the particle size of a semiconductor particle is the order of nm-mu m. As for the primary-particle mean particle diameter which asked for the projected area of a particle from the diameter when converting into a circle, it is desirable that it is 5-200nm, and it is more desirable that it is 8-100nm. Moreover, as for the mean particle diameter of the semiconductor particle in the dispersion liquid produced in order to apply on a conductive base material (aggregated particle), it is desirable that it is 0.01-30 micrometers. Two or more kinds of particles from which a particle size distribution differs may be mixed, it is desirable that the average size of a small particle is 25nm or less in this case, and it is more desirable that it is 10nm or less. Particle size is big, for example, it is also desirable to mix a semiconductor particle (100nm or more and about 300nm) in order to scatter an incident light and to raise the rate of optical capture.

[0099] You may mix and use two or more sorts of semiconductor particles from which a kind also differs. In such a case, as for one sort, it is desirable that they are TiO2, ZnO, Nb 2O5, or SrTiO3. As for another side, it is desirable that they are SnO2, Fe 2O3, or WO3. Especially, ZnO, SnO2, ZnO and

WO3, ZnO, or the combination of SnO2 and WO3 is more desirable. When mixing and using two or more sorts of semiconductor particles, each particle size may differ. Especially the particle size of the above Nb [TiO2, ZnO, and] 2O5 or SrTiO3 is large, and its small one is [the particle size of SnO2, Fe 2O3, or WO3] desirable. The large particle and large particle size of 100nm or more have [particle size] a desirable combination of a small particle 15nm or less.

[0100] a sol-gel method given [as a method of producing a semiconductor particle] in "the thin-layer-coating technology by the sol-gel method" (1995) etc. of the company (1998) of the "science of sol-gel method" AGUNE ** style of *********, and a technical-information association, and "composition of the monodisperse particle by the new synthesis method gel-sol method and size form control" of Tadao Sugimoto -- wait -- the gel-sol method given in ****, the 35th volume, No. 9, 1012-1018 etc. pages (1996), Moreover, the method of producing an oxide for the chloride which Degussa developed by elevated-temperature hydrolysis in an acid hydrogen salt is also preferably applicable.

[0101] When a semiconductor particle is titanium oxide, each of above-mentioned sol-gel methods, gel-sol methods, and elevated-temperature adding-water part solution methods in the inside of the acid hydrogen salt of a chloride can be used preferably, and may use the sulfuric-acid method and chlorine method of a publication for "titanium oxide physical-properties and applied-technology" Gihodo Shuppan Co., Ltd. (1997) of the Seino study further. In addition, a sol-gel method given in Barbe's and others journal OBU American ceramic society, the 80th volume, No. 12, 3157-3171 pages (1997), Burnside's and others chemical MATERIARUZU, the 10th volume, No. 9, 2419-2425 etc. pages, etc. is also desirable.

[0102] (2) In case a semiconductor particle layer semiconductor particle is applied on a conductive base material, in addition to the method of applying the dispersion liquid or the colloidal solution of a semiconductor particle on a conductive base material, the above-mentioned sol-gel method etc. can be used. When mass-production-izing of an optoelectric transducer, the physical properties of semiconductor particle dispersion liquid, the versatility of a conductive base material, etc. are taken into consideration, the wet film production method is comparatively desirable. As the wet film production method, the applying method, print processes, an electrolytic-deposition method, and an electrodeposition process are typical. Moreover, you may use the SPD method which sprays the metallic-oxide precursor pyrolyzed on the method of carrying out vacuum evaporation by the method (the LPD method) of depositing by the liquid phase by the ligand exchange etc., the spatter, etc., CVD, or the warmed substrate from the method of oxidizing a metal, and a metal solution, and forms a metallic oxide.

[0103] In case the method and semiconductor which are distributed while grinding as a method of producing the dispersion liquid of a semiconductor particle using the above-mentioned sol-gel method, the method of mashing with a mortar, and a mill are compounded, the method of depositing as a particle and using it as it is in a solvent, etc. is mentioned.

[0104] As a dispersion medium, water or various kinds of organic solvents (for example, a methanol, ethanol, isopropyl alcohol, a citronellol, terpineol, a dichloromethane, an acetone, an acetonitrile, ethyl acetate, etc.) are usable. In case it distributes, you may use polymer, such as a polyethylene glycol, a hydroxyethyl cellulose, and a carboxymethyl cellulose, a surfactant, an acid, a chelating agent, etc. as a distributed assistant if needed. Especially, it is desirable to add a polyethylene glycol. By changing the molecular weight of the polyethylene glycol to add, the viscosity of dispersion liquid can be adjusted, the semiconductor layer which cannot separate easily can be formed or the voidage of a semiconductor layer can be controlled.

[0105] As the desirable method of application, the method by which application and metering, such as the slide hopper method given in metering systems, such as application systems, such as a roller and the dipping method, the air knife method, and the blade method, the wire bar method given in JP,58-4589,B, U.S. JP,2681294,B, said 2761419 numbers, said 2761791 numbers, etc., the extrusion method, and the curtain method, are made into the same portion is mentioned. Moreover, the spin method and a spray method are also desirable as a general aviation. As the wet printing method, intaglio printing, the rubber version, the screen-stencil including letterpress, offset, and the three major print processes of gravure, etc. can use preferably. What is necessary is just to choose the

desirable film production method according to liquid viscosity or wet thickness from the above methods.

[0106] A semiconductor particle layer can carry out the multilayer application of the semiconductor particle dispersion liquid from which not only a monolayer but particle size differs, or can also carry out the multilayer application of the layer containing the semiconductor particles (or a different binder, a different additive, etc.) of a different kind. The multilayer application is effective when thickness runs short by application once.

[0107] Although the rate of capture of light generally becomes high since the amount of coloring matter support per unit projected area increases so that semiconductor particle layer thickness (it is the same as the thickness of a photosensitive layer) becomes thick, since the generated diffusion length of electron increases, the loss by charge reunion also becomes large. Therefore, the thickness with a desirable semiconductor particle layer is 0.1-100 micrometers. When using for a photoelectric cell, as for semiconductor particle layer thickness, it is desirable that it is 1-30 micrometers, and it is more desirable that it is 2-25 micrometers. As for the semiconductor particle coverage per two, it is desirable to be referred to as 0.5-100g, and it is [1m of base materials] more desirable to be referred to as 3-50g.

[0108] Heat-treating is desirable in order to raise paint film intensity and adhesion with a base material while contacting semiconductor particles electronically, after applying a semiconductor particle to a conductive base material. As for heating temperature, it is desirable to consider as 40 degrees C or more less than 700 degrees C, and it is more desirable to consider as 100 degrees C or more 600 degrees C or less. Moreover, what is necessary is just to make heating time into 10 minutes - about 10 hours. When using a base material with low melting point and softening temperature like a polymer film, the heat-treatment in an elevated temperature is not desirable in order to cause degradation of a base material. Moreover, it is desirable to perform heat-treatment as much as possible also from a viewpoint of cost reduction at low temperature (for example, 50 degrees C - 350 degrees C). Low temperature-ization of heat-treatment temperature is attained by using together a semiconductor particle with a particle size of 5nm or less mentioned above, or heat-treating under existence of a mineral-acid metallurgy group oxide precursor. Moreover,-izing can be carried out [low temperature] by impressing irradiation, the electric field, or the ultrasonic wave of ultraviolet rays, infrared radiation, microwave, etc. It is desirable to use together suitably heating, reduced pressure, oxygen plasma treatment, pure water washing, solvent cleaning, gas scrubbing, etc. for the purpose which removes the unnecessary organic substance etc. in addition to the above-mentioned irradiation etc.

[0109] After heat-treatment, in order to increase the surface area of a semiconductor particle, or in order to raise the purity near the semiconductor particle and to raise the electron-injection efficiency from coloring matter to a semiconductor particle, you may perform chemical-plating processing using titanium-tetrachloride solution, and electrochemical plating processing using titanium-trichloride solution. Moreover, in order to prevent that a reverse current flows from a semiconductor particle to a charge transporting bed, it is effective in a particle front face to also make the low organic substance of electronic conductivity other than coloring matter adsorb. As for the organic substance made to adsorb, it is desirable to have a hydrophobic radical.

[0110] As for a semiconductor particle layer, it is desirable to have a big surface area so that much coloring matter can be adsorbed. As for the surface area in the state where the semiconductor particle was applied on the base material, it is desirable that they are 10 or more times to projected area, and it is more desirable that they are 100 or more times. Although especially a limit is infinite, they are usually about 1000 times.

[0111] (3) That what is necessary is just what has absorption in a visible region or a near-infrared region, and can carry out sensitization of the semiconductor, the coloring matter used for a coloring matter photosensitive layer is metal complex coloring matter, methine coloring matter, porphyrin system coloring matter, and/or phthalocyanine system coloring matter preferably, and is metal complex coloring matter and/or poly methine coloring matter especially preferably. In order to make the wavelength region of photo electric translation large as much as possible and to gather a conversion efficiency, you may use together two or more kinds of coloring matter. In this case, what

is necessary is just to choose the coloring matter used together and its mixed rate according to the wavelength region and intensity distribution of the light source.

[0112] The coloring matter used by this invention has the suitable joint machine (interlocking group) which has the adsorption capacity force to a semiconductor particle front face preferably. The chelation machine which has pi conductivity like -COOH basis, -OH basis, -SO3H set, -P(O) (OH)2 set, an acidic group like -OP(O) (OH)2 set and an oxime, dioxime, a hydroxyquinoline, salicylate, and alpha-KETOENO rate as a desirable joint machine is mentioned. -COOH basis, -P(O) (OH)2 set, and especially -OP(O) (OH)2 set are desirable especially. These joint machines may form alkali metal etc. and the salt, and may form the inner salt. Moreover, in poly methine coloring matter, it is good also considering the oak which contains an acidic group like [in case a methine chain forms a squarylium ring and a crocodile NIUMU ring], and this portion as a joint machine. Hereafter, the desirable sensitizing dye used for a photosensitive layer is explained concretely.

[0113] (a) As for the metal complex coloring matter used by the metal complex coloring matter this invention, it is desirable that they are metal phthalocyanine dye or metalloporphyrin coloring matter. Moreover, the metal atom of metal complex coloring matter has desirable Ruthenium Ru. as the ruthenium complex coloring matter which can be used by this invention — for example, U.S. JP,4927721,B — said — No. 4684537 — said — No. 5084365 — said — No. 5350644 — said — No. 5463057 — said — the thing of a publication is mentioned to No. 5525440, JP,7-249790,A, *******
No. 504512 [ten to], the world patent 98/No. 50393, JP,2000-26487,A, etc.

[0114] The ruthenium complex coloring matter used by this invention is following (general formula I):(A1) pRu (B-a) (B-b) (B-c). ... Being expressed by (I) is desirable. Among a general formula (I), A1 expresses the ligand of 1 or 2 seats, and expresses the ligand chosen from the group which consists of a derivative of Cl, SCN, H2O, Br, I, CN and NCO, SeCN and beta-diketones, oxalic acid, and a dithiocarbamic acid. p is the integer of 0-3. B-a, B-b, and B-c express the organic ligand chosen from the compound independently expressed by the following formula B-1 to B-10, respectively.

[0116] Ra expresses a hydrogen atom or a substituent among a formula B-1 to B-10. As an example

of this substituent, the aryl group which is not replaced [the substitution of the aralkyl machine which is not replaced / the substitution of a halogen atom and the carbon atomic numbers 1-12 or / and the carbon atomic numbers 7-12 or / and the carbon atomic numbers 6-12 or], the above-mentioned acidic group (you may form the salt), and a chelation machine are mentioned. Here, the shape of a straight chain and the letter of branching are sufficient as the alkyl portions of an alkyl group and an aralkyl machine, and a monocycle or a polycyclic (the condensed ring, ring set) is sufficient as the aryl portions of an aryl group and an aralkyl machine. Even if B-a, B-b, and B-c are the same, they may differ from each other, and any one or two are sufficient as them.

[0117] Although the desirable example of the metal complex coloring matter which can be used by this invention is shown below, this invention is not limited to these.
[0118]

[Formula 34]
(A₁)₆Ru(B-a)(B-b)(B-c) . .

	A ₁	р	B-a	B-b	В-с	Re
R-1	SCN	2	B-1	B-1	_	_
R-2	CN	2	B-1	B-1		
R-3	CI	2	B-1	B-1	_	_
. R-4	CN	2	B-7	B-7	_	_
R-5	SCN	2	B-7	B-7	_	-
R-6	SCN	2	B-1	B-2	_	н
R-7	SCN	1	B-1	B-3		_
R-8	cı	1	B-1	B-4	_	н
R-9	1	2	B-1	B-5		н
R-10	SCN	3	B-8	_	_	_
R-11	CN	3	B-8		_	
R-12	SCN	1	B-2	B-8	_	н
R-13	_	0	B-1	B-1	B-1	_

6/3/2003

[0120] (b) The methine coloring matter used by the methine coloring matter this invention is poly methine coloring matter, such as a cyanine dye, merocyanine coloring matter, and SUKUWARIRIUMU coloring matter, preferably. As poly methine coloring matter, the thing of a publication can be used for JP,11-35836,A, JP,11-67285,A, JP,11-86916,A, JP,11-97725,A, JP,11-158395,A, JP,11-163378,A, JP,11-214730,A, JP,11-214731,A, JP,11-238905,A, JP,2000-26487,A, the Europe patent No. 892411, said 911841 numbers, and said 991092 numbers. The example of desirable methine coloring matter is shown below.

[Formula 36]

M-1

[0122] [Formula 37]

[0123] (4) In order to make coloring matter stick to the adsorption semiconductor particle of the coloring matter to a semiconductor particle, the method immersed into the solution of coloring matter in the conductive base material which has the often dried semiconductor particle layer, or the method of applying the solution of coloring matter to a semiconductor particle layer can be used. By the former method, dip coating, the dipping method, a roller, the air knife method, etc. are usable. In addition, in the case of dip coating, adsorption of coloring matter may be performed at a room temperature, and you may perform it by carrying out heating reflux as indicated by JP,7-249790,A. Moreover, as the latter method, there are the methods of application, such as the wire bar method, the slide hopper method, the extrusion method, the curtain method, the spin method, and a spray method.

[0124] the solvent used for the solution of coloring matter -- the solubility of coloring matter etc. -- responding -- suitably -- it can choose -- for example, alcohols (a methanol --) nitril (an acetonitrile --), such as ethanol, t-butanol, and benzyl alcohol Nitromethanes, such as a propionitrile and 3-methoxy propionitrile, a halogenated hydrocarbon (a dichloromethane, a dichloroethane, and chloroform --) Ether, such as a chlorobenzene (diethylether, tetrahydrofuran, etc.), dimethyl sulfoxide and amides (N.N-dimethylformamide --) N-methyl pyrrolidones, such as N and N-dimethyl acetamido, 1, 3-dimethyl imidazolidinone, 3-methyl oxazolidinone and ester (ethyl acetate, butyl acetate, etc.) Carbonates (diethyl carbonate, an ethylene carbonate, propylene carbonate, etc.), ketones, hydrocarbons (an acetone, 2-butanone, cyclohexanone, etc.) (Korean geisha, the petroleum ether, benzene, toluene, etc.), these mixed solvents, etc. can be used.

[0125] As for all the amounts of adsorption of coloring matter, it is desirable to be referred to as per [a unit surface area (1m2) / 0.01] - 100mmol of a conductive base material. Moreover, in order to

[a unit surface area (1m2) / 0.01] - 100mmol of a conductive base material. Moreover, in order to acquire sufficient sensitization effect, as for the amount of adsorption to the semiconductor particle of coloring matter, it is desirable that they are per [0.01] 1g of semiconductor particles - 1mmol. The sensitization effect becomes inadequate, and if there is too little amount of adsorption of coloring matter, if many [too], coloring matter will tend to float, and it becomes the cause of reducing the sensitization effect. Moreover, it is desirable to heat-treat, before adsorbing in order to increase the amount of adsorption of coloring matter. In order to suppress that water sticks to a semiconductor particle front face after heat-treatment, it is desirable not to return to ordinary temperature but to make coloring matter adsorb quickly at 60-150 degrees C. Moreover, you may carry out the coadsorption of the colorless compound to a semiconductor particle for the purpose which reduces the interaction of the coloring matter like condensation. As a compound which carries out a coadsorption, a surface activity compound is effective, and surface activity compounds, such as sulfonates shown in the steroid compound (for example, chenodeoxycholic acid) which has a carboxyl group, or the following, can be used.

[0126]

[Formula 38]

C₉H₁₉--(OCH₂CH₂)₃-OSO₃K

[0127] As for non-adsorbed coloring matter, it is desirable that washing removes promptly after adsorption. It is desirable to perform washing in a wet washing tub using organic solvents, such as polar solvents, such as an acetonitrile, and an alcohols solvent. After adsorbing coloring matter, amines and quarternary ammonium salt may be used and the front face of a semiconductor particle may be processed, in order to promote removal of excessive coloring matter. As desirable amines, a pyridine, a 4-t-butyl pyridine, a polyvinyl pyridine, etc. are mentioned. As desirable quarternary ammonium salt, TETORO butyl ammonium iodide, tetrapod hexyl ammonium iodide, etc. are mentioned. These may be dissolved and used for an organic solvent and, in the case of a liquid, you may use as it is.

[0128] (C) A charge transporting-bed charge transporting bed has the function to supplement the oxidant of coloring matter with an electron. Although the first electrolyte constituent of the above-mentioned this invention or the second electrolyte constituent is used for a charge transporting bed, you may use together a solid electrolyte and electron hole (hole) transportation material further. [0129] A charge transporting bed can form a reaction solution layer on an electrode by the cast method, the applying method, dip coating, the sinking-in method, the penetration method, etc., and, subsequently can be installed by performing the above-mentioned polymerization reaction. Although what is necessary is just to choose heating temperature according to the heat-resistant temperature of the coloring matter to be used when heating and carrying out a polymerization, 10-200 degrees C is more preferably made into 30-150 degrees C. Although heating time is based on heating temperature etc., you may be 5 minutes - about 72 hours.

[0130] Two kinds of methods are possible in detail about the formation method of a charge transporting bed. One is the method of sticking a counter electrode previously on a photosensitive layer, and putting the above-mentioned reaction solution layer between the gap. Another is the method of forming a direct charge transporting bed on a photosensitive layer, and installing a counter electrode after that. In the former method, a reaction solution layer can be put according to the ordinary-pressure process using the capillarity by being immersed etc., or the vacuum process which makes it a low pressure and replaces the gaseous phase of a gap by the liquid phase from an ordinary pressure. What is necessary is to give a counter electrode with not drying and just to take a liquid disclosure prevention measure against the edge section in the latter method, when using a wet electrolyte constituent. What is necessary is just to solidify, after applying a liquefied electrolyte constituent, when using a gel electrolyte. Moreover, when using wet organic electron hole transportation material and a gel electrolyte, the method of forming the above-mentioned photosensitive layer and the same method can be used.

[0131] When using the electron hole (hole) transportation material of a solid electrolyte or a solid-state, a charge transporting bed can be formed by the dry forming-membranes methods, such as a vacuum deposition method and CVD, and a counter electrode can be given after that. An organic electron hole transportation material can be introduced by technique, such as a vacuum deposition method, the cast method, the applying method, the spin coat method, dip coating, an electrolytic polymerization method, and the photoelectrical depolymerizing method. Also in an inorganic solid-state compound, it can introduce by technique, such as the cast method, the applying method, the spin coat method, dip coating, an electrolytic-deposition method, and an electroless deposition method. [0132] In order to make a redox couple generate, when introducing iodine etc. into a charge transporting bed, the technique of placing [technique] this into an airtight container and diffusing it in an electrolyte with iodine etc., etc. can be used after formation of the method of adding in an electrolytic solution, and a charge transporting bed. Moreover, it is also possible to introduce iodine etc. into the below-mentioned counter electrode into a charge transporting bed, an application or when it carries out vacuum evaporationo and an optoelectric transducer is assembled.

[0133] It is 2,000 ppm or less that it is 10,000 ppm or less desirable still more preferably, and the moisture in a charge transporting bed is 100 ppm or less especially preferably.

[0134] (D) A counter electrode counter electrode acts as a positive electrode, when an optoelectric transducer is used as a photoelectric cell. The counter electrode may consist of only counter electrode conductive layers which consist of a conductive material like the above-mentioned conductive base material, and may consist of a counter electrode conductive layer and a support substrate. As a conductive material used for a counter electrode conductive layer, a metal, carbon (for example, platinum, gold, silver, copper, aluminum, magnesium, an indium, etc.), and conductive metallic oxides (what doped the fluorine to an indium-tin multiple oxide and the tin oxide) are mentioned. Platinum, gold, silver, copper, aluminum, and magnesium are desirable especially. The support substrate used for a counter electrode is a glass substrate or a plastic plate preferably, and the vacuum evaporationo of it is applied or carried out, and it uses the above-mentioned conductive material for this. Although especially the thickness of a counter electrode conductive layer is not restricted, it is desirable that it is 3nm - 10 micrometers. The surface electrical resistance of a counter electrode is as good as a low, it is desirable that they are below 50ohms / **, and it is more desirable that they are below 20ohms / **.

[0135] Since light may be irradiated from both a conductive base material, and both [either or], in order for light to reach a photosensitive layer, it is good if at least one side is substantially transparent among a conductive base material and a counter electrode. It is desirable to make a conductive base material transparent from a viewpoint of the improvement in a generating efficiency, and to carry out incidence of the light from a conductive base material side. In this case, as for a counter electrode, it is desirable to have the property to reflect light. As a material of such a counter electrode, the glass which deposited the metal and the conductive oxide or plastics, a metal thin film, etc. can be used. [0136] On a charge transporting bed, a counter electrode may stick the application, plating, or conductive-layer side of the substrate which carries out vacuum evaporationo (PVD, CVD), or has a conductive layer, and may prepare direct electric conduction material. Moreover, as well as the case of a conductive base material when especially a counter electrode is transparent, it is desirable to use a metal lead in order to lower resistance of a counter electrode. In addition, the fall of the desirable quality of the material of a metal lead and the desirable installation method, and the amount of incident lights by metal lead installation etc. is the same as the case of a conductive base material. [0137] (E) In order to prevent other layer counter electrodes and the short circuit of a conductive base material, it is desirable to paint the thin film layer of a conductive base material and a semiconductor precise between photosensitive layers as an under coat beforehand. It is effective especially when using electronic transportation material and electron hole transportation material for a charge transporting bed. The material of an under coat is TiO2, SnO2, Fe 2O3, WO3 and ZnO, and/or Nb 205 preferably, and is TiO2 still more preferably. An under coat can be painted by Electrochimi. Acta, 40, the spray pyrolysis method indicated by 643-652 (1995), the spatter, etc. As for the thickness of an under coat, it is desirable that it is 5-1000nm, and it is more desirable that it is 10-500nm.

[0138] Moreover, you may prepare functional layers, such as a protective layer and an acid-resisting layer, between either the conductive base material which acts as an electrode or a counter electrode both outside front faces, a conductive layer, and substrates, or in the middle of a substrate. According to the quality of the material, the applying method, a vacuum deposition, the sticking method, etc. can be used for formation of such a functional layer.

[0139] (F) the example of the internal structure of an optoelectric transducer — as mentioned above, double the internal structure of an optoelectric transducer with the purpose, and various gestalten are possible for it If it roughly divides into two, the structure in which the incidence of both sides to light is possible, and structure possible only from one side are possible. The internal structure of an optoelectric transducer preferably applicable to <u>drawing 2</u> - <u>drawing 8</u> at this invention is illustrated. [0140] The structure shown in <u>drawing 2</u> is structure in which a photosensitive layer 20 and the charge transporting bed 30 are made to intervene between transparent conductive-layer 10a and transparent counter electrode conductive-layer 40a, and light carries out incidence from both sides. The structure shown in <u>drawing 3</u> is structure in which establishes the metal lead 11 in part on

transparent substrate 50a, prepares transparent conductive-layer 10a on it, forms an under coat 60, a photosensitive layer 20, the charge transporting bed 30, and the counter electrode conductive layer 40 in this order, and arranges the support substrate 50 further, and light carries out incidence from a conductive-layer side. The structure shown in drawing 4 is structure in which carries out the metal lead 11 side inside, and arranges transparent substrate 50a which installed the conductive layer 10 further on the support substrate 50, formed the photosensitive layer 20 through the under coat 60, prepared the charge transporting bed 30 and transparent counter electrode conductive-layer 40a further, and established the metal lead 11 in part, and light carries out incidence from a counter electrode side. A part of structure shown in drawing 5 is structure in which prepare transparent conductive-layer 10a and transparent counter electrode conductive-layer 40a on two transparent substrates 50a which established the metal lead 11, respectively, an under coat 60, a photosensitive layer 20, and the charge transporting bed 30 are made to intervene among them, and light carries out incidence from both sides. The structure shown in drawing 6 is structure in which installs transparent conductive-layer 10a on transparent substrate 50a, forms a photosensitive layer 20 through an under coat 60, forms the charge transporting bed 30 and the counter electrode conductive layer 40 further, and arranges the support substrate 50 on this, and light carries out incidence from a conductive-layer side. The structure shown in drawing 7 is structure in which installs a conductive layer 10 on the support substrate 50, forms a photosensitive layer 20 through an under coat 60, prepares the charge transporting bed 30 and transparent counter electrode conductive-layer 40a further, and arranges transparent substrate 50a on this, and light carries out incidence from a counter electrode side. The structure shown in drawing 8 is structure in which installs transparent conductive-layer 10a on transparent substrate 50a, forms a photosensitive layer 20 through an under coat 60, prepares the charge transporting bed 30 and transparent counter electrode conductive-layer 40a further, and arranges transparent substrate 50a on this, and light carries out incidence from both sides. [0141] [3] The photoelectric cell of photoelectrical Ikemoto invention connects the optoelectric transducer of the above-mentioned this invention to an external load, and is made to do electric work (power generation). What calls photoelectrochemical cell what the charge transportation material 23 becomes mainly from ion-transport material among photoelectric cells, and makes power generation by sunlight a key objective is called solar battery.

[0142] In order to prevent degradation of a structure and vaporization of contents, as for the side of a photoelectric cell, sealing with polymer, adhesives, etc. is desirable. The external circuit itself connected to a conductive base material and a counter electrode through a lead is easy to be well-

[0143] When applying the optoelectric transducer of this invention to a solar battery, the structure inside the cell is the same as the structure of an optoelectric transducer fundamentally mentioned above. Moreover, the solar cell module of this invention containing the optoelectric transducer of this invention can take the same structure as fundamentally as the conventional solar cell module. Generally, a cell is constituted on support substrates, such as a metal and a ceramic, and a solar cell module covers a it top with a restoration resin, cover glass, etc., and takes the structure of incorporating light from the opposite side of a support substrate. It is also possible to consider as the structure of using transparent materials, such as tempered glass, for a support substrate, constituting a cell on it, and incorporating light from the transparent support substrate side. Specifically, the substrate one apparatus module structure used with module structure a super straight type, a substrate type, or potting type, an amorphous-silicon solar cell, etc. is known. Also in the coloring matter sensitization type solar battery using the optoelectric transducer of this invention, module structure can be suitably chosen according to the purpose of use, a service space, and environment. The structure of the solar cell module in this invention which can be used, the desirable mode, etc. are the same as that of a thing given in Japanese Patent Application No. 11-8457. [0144]

[Example] Hereafter, although an example explains this invention still in detail, this invention is not limited to them.

[0145] 1. With 15g [of titanium-dioxide particles] (product [made from Japanese Aerosil], Degussa P-25), 45g, 1g (Aldrich make, Triton X-100), and a diameter of 0.5mm zirconia-beads (Nikkato Corp. make) 30g was put into the container made from stainless steel of 200ml of content volume which carried out Teflon (registered trademark) coating of the manufacture inside of titanium-dioxide dispersion liquid, and distributed processing was carried out by 1500rpm for 2 hours using the Sand-grinder mill (product made from eye MEKKUSU). Filtration removed zirconia beads from the obtained dispersion liquid. The mean particle diameter of the titanium-dioxide particle in the obtained dispersion liquid was 2.5 micrometers. In addition, particle size was measured in the master sizer made from MALVERN.

[0146] 2. The glass rod was used and the above-mentioned dispersion liquid were applied to the electric conduction side side of the electrically conductive glass (thing and surface-electrical-resistance about 30ohm/** which carried out cutting processing of the TCO glass [by Asahi Glass Co., Ltd.]-U at the 20mmx20mm size) which has the tin-oxide layer which doped the creation fluorine of TiO2 electrode which adsorbed coloring matter. The coverage of a semiconductor particle was taken as 20 g/m2. At that time, the adhesive tape was stretched to the part by the side of an electric conduction side (from an edge to 3mm), and it considered as the spacer, and glass was put in order and it applied eight sheets at a time at once so that an adhesive tape might come to ends. After the application, it exfoliated and the adhesive tape was air-dried for one day at the room temperature. Next, this glass was put into the electric furnace (muffle furnace FP-32 type made from Yamato Science), it calcinated for 30 minutes at 450 degrees C, and TiO2 electrode was obtained. It flooded with the ethanol solution (3x10-4 mol/l) of coloring matter R-1 for 3 hours, after taking out this electrode and cooling. TiO2 electrode which coloring matter dyed was washed and air-dried by ethanol, after being immersed in the 4-t-butyl pyridine for 15 minutes. The thickness of the obtained photosensitive layer was 6.5 micrometers.

[0147] 3. The acetonitrile solution containing the electrolyte salt MHIm of the photoelectrochemicalcell examples 1-7, the example 1 of comparison, and 20.5 mol/l using the electrolyte constituent containing the production 3-1. solvent of a photoelectrochemical cell (iodine salt of 1-methyl-3-hexyl imidazolium) and 0.05 mol [/l.] iodine was prepared, and the siloxane compound 1-4 was added to this. 10 mass % The siloxane compound made the [solvent + electrolyte salt + siloxane compound] 100 mass %, and used it here. It was made to sink into the crevice which piled up the platinum vacuum evaporationo glass of the coloring matter sensitization TiO2 electrode substrate (20mmx20mm) which produced the obtained solution as mentioned above, and the same size as this using capillarity, introduced into the TiO2 electrode, it closed by the epoxy system encapsulant, and the photoelectrochemical cell of an example 1 using the first electrolyte constituent of this invention. was obtained. The photoelectrochemical cell of examples 2-7 using the first electrolyte constituent of this invention was obtained like the above-mentioned example 1 except having changed the solvent and the siloxane compound, as shown in the following table 1. Moreover, except not adding a siloxane compound, the photoelectrochemical cell of the example 1 of comparison was produced like the above-mentioned example 1, and the photoelectrochemical cell of the example 2 of comparison was produced like the above-mentioned example 1 except having changed to the siloxane compound further and having added t-butyl pyridine. The coloring matter used for the photoelectrochemical cell of the above-mentioned examples 1-7 and the examples 1 and 2 of comparison, a siloxane compound and its mass ratio, an electrolyte salt and its concentration, the concentration of iodine, and a solvent are collectively shown in Table 1. In addition, AN in Table 1 expresses an acetonitrile, NMO expresses 3-methyl-2-oxazolidinone, PC expresses propylene carbonate, and MHIm expresses the iodine salt of 1-methyl-3-hexyl imidazolium. Moreover, the mass ratio of a siloxane compound is a mass ratio at the time of making a [solvent + electrolyte salt + siloxane compound] into 100 mass % among Table 1.

[0148]

[Table 1]

光電気 化学電池	色素	シロキサン化合物 (質量%)	電解質塩 (mol/l)	ョウ素 (mol/i)	溶媒
実造例1	R-1	1-4 (10)	MHIm (0.5)	0.05	AN
実施例2	R-1	1-4 (10)	MHIm (0.5)	0.05	NMO
実施943	R-1	1-4 (10)	MHIm (0.5)	0.05	
实监例4	R-1	1-6 (10)	MHIm (0.5)	0.05	PC
実施例5	R-1	1-11 (10)	MHIm (0.5)	0.05	AN
実施例8	R-1	1-13 (10)	MHim (0.5)	0.05	
実施例7	R-1	1-17 (10)	MHim (0.5)	0.05	AN
比較例1	R-1	☆ L	MHim (0.5)	0.05	
比較例2	R-1	トプチルピリジン (10)	MHIm (0.5)	0.05	AN

[0149] The acetonitrile solution containing the electrolyte salt MHIm of an example 8 - 170.5 mol/l (iodine salt of 1-methyl-3-hexyl imidazolium) and the iodine of 0.05 mol/l was prepared. The siloxane compound 1-4 was added to this solution, the electrophilic agent E-3 was mixed further, and the uniform solution was adjusted. Here, the siloxane compound made the [solvent + electrolyte salt + siloxane compound] 100 mass %, 10 mass % Used it, and it added the electrophilic agent so that the mole ratio of the electrophilic part of the electrophilic agent to the reactive site of a siloxane compound might be set to 1. It was made to sink into the crevice which piled up the platinum vacuum evaporationo glass of the coloring matter sensitization TiO2 electrode substrate (20mmx20mm) which produced the obtained solution as mentioned above, and the same size as this using capillarity, and introduced into the TiO2 electrode. This was left at 50 degrees C for 12 hours, polymerization reaction was performed, it closed by the epoxy system encapsulant, and the photoelectrochemical cell of an example 8 using the second electrolyte constituent of this invention was obtained. The photoelectrochemical cell of examples 9-14 using the second electrolyte constituent of this invention was obtained like the above-mentioned example 8 except having changed a solvent, a siloxane compound, and an electrophilic agent and its mole ratio, as shown in the following table 2. Moreover, it changed to what shows a siloxane compound in Table 2, and the photoelectrochemical cell of examples 15-17 using the second electrolyte constituent of this invention was obtained like the above-mentioned example 8 except having made the amount of the electrophilic agent used into 5 mass % to the siloxane compound. The coloring matter used for the photoelectrochemical cell of the above-mentioned examples 8-17, an electrophilic agent and its mole ratio, a siloxane compound and its mass ratio, an electrolyte salt and its concentration, the concentration of iodine, and a solvent are collectively shown in Table 2. In addition, AN in Table 2 expresses an acetonitrile, NMO expresses 3-methyl-2-oxazolidinone, PC expresses propylene carbonate, and MHIm expresses the iodine salt of 1-methyl-3-hexyl imidazolium. Moreover, among Table 2, the mass ratio of a siloxane compound is a mass ratio at the time of making a [solvent + electrolyte salt + siloxane compound] into 100 mass %, and the mole ratio of an electrophilic agent is a mole ratio of the electrophilic part of the electrophilic agent to the reactive site of a siloxane compound. However, not a mole ratio but the mass ratio (wt%) to a siloxane compound shows the amount of the electrophilic agent used used for the photoelectrochemical cell of examples 15-17. [0150]

[Table 2]

光電気 化学電池	白素	求電子剤 (モル比又は質量比)	シロキサン化合物 (質量%)	電解質塩 (mo/l)	ョウ素 (mol/l)	溶媒
実施例8	R-1	E-3 (1)	1-4 (10)	MHim (0.5)	0.05	AN
実施例9	R-1	E-3 (1)	1-4 (10)	MHIm (0.5)	0.05	NMO
夹施例10	R-1	E-3 (1)	1-4 (10)	MHm (0.5)	0.05	PC
実施例11	R-1	E-3 (1)	1-8 (10)	MHIm (0.5)	0.05	AN
実施例12	R-1	E-12 (1)	1-4 (10)	MHIm (0.5)	0.05	AN
実施例13	R-1	E-12 (1)	1-6 (10)	MHIm (0.5)	0.05	AN
実施例14	R-1	E-3 (0.9), E-5 (0.1)	1-4 (10)	MHIm (0.5)	0.05	AN
実施例15	R-1	E-3 (5 wt%)	1-11 (10)	MHIm (0.5)	0.05	AN
実施例18	R-1	E-3 (5 wt%)	1-13 (10)	MHIm (0.5)	0.05	AN
夹连例17	R-1	E-3 (5 wt%)	1-17 (10)	MHIm (0.5)	0.05	AN

[0151] The hexa ethylene glycol methacrylic ester ("BUREMMA PE-350" by the Nippon Oil & Fats chemistry company) of 3500mg of examples of comparison, 1g propylene carbonate, and the mixed liquor containing the 2mg polymerization initiator azobisuisobutironitoriru were prepared, and the 500mg iodation lithium was dissolved in this. Next, the vacuum deairing of this mixed liquor was http://www4.ipdl.jpo.go.jp/cgi-bin/tran_web_cgi_ejje

carried out for 10 minutes, and it applied to the coloring matter sensitization TiO2 electrode substrate (20mmx20mm) produced as mentioned above. Then, after putting under reduced pressure of TiO2 electrode which applied mixed liquor and urging osmosis of a monomer except for the foam in TiO2 electrode, at 60 degrees C, it heated for 1 hour and the polymerization was carried out. It **(ed) for 30 minutes under iodine atmosphere at the room temperature after the polymerization, and iodine was diffused in the obtained polymer. This was piled up with the counter electrode which deposited platinum, and the photoelectrochemical cell (photoelectrochemical cell using the electrolyte the Chemical Society of Japan, 7, and given in 484 page (1997)) of the example 3 of comparison was obtained.

[0152] 3-2. The fused salt A of the photoelectrochemical-cell examples 18-28 and the example 4 of comparison - 660 mass % using the electrolyte constituent containing room temperature fused salt, the fused salt B of 28 mass %, the iodine of 2 mass %, and the siloxane compound 1-4 of 10 mass % were mixed, and the uniform electrolyte constituent was prepared. After applying 5micro of obtained electrolyte constituents I to the coloring matter sensitization TiO2 electrode substrate produced as mentioned above, it put under reduced pressure of this electrode, and the electrolyte constituent was made to permeate. After the electrolyte constituent fully permeated and the air in an electrode fell out, platinum vacuum evaporationo glass was laid on top of this, and the photoelectrochemical cell of an example 18 using the first electrolyte constituent of this invention was obtained. The photoelectrochemical cell of examples 19-28 using the first electrolyte constituent of this invention was obtained like the above-mentioned example 18 except having changed fused salt, its mass ratio, and the siloxane compound, as shown in the following table 3. Moreover, a siloxane compound was not added, but the photoelectrochemical cell of the examples 4 and 5 of comparison was produced like the above-mentioned example 18 except having changed fused salt and its mass ratio, as shown in Table 3, it changed to the siloxane compound further, t-butyl pyridine was added, and the photoelectrochemical cell of the example 6 of comparison was produced like the above-mentioned example 18 except having changed fused salt and its mass ratio, as shown in Table 3. However, the amount of t-butyl pyridine was made into 10 mass %. The coloring matter used for the photoelectrochemical cell of the above-mentioned examples 18-28 and the examples 4-6 of comparison, fused salt and its mass ratio, the mass ratio of iodine, a siloxane compound, and its mass ratio are collectively shown in Table 3. Moreover, the structure of fused salt A-D is shown below. [0153]

[Table 3]

[I auto 3	J			
光電気	da wie	溶融塩	ヨウ素	シロキサン化合物
化学電池	色素	(質量%)	(貴量%)	(資量%)
実施例18	R-1	A (60) / B (28)	2	1-4 (10)
実施例19	R-1	A (60) / C (28)	2	1-4 (10)
夹连例20	R-1	A (60) / C (28)	2	1-4 (10)
実施例21	R-1	A (60) / B (28)	2	1-6 (10)
実施例22	R-1	D (60) / C (28)	2	1-4 (10)
実施例23	R-1	D (60) / C (28)	2	1-4 (10)
実施例24	R-1	D (60) / C (28)	2	1-6 (10)
実施例25	R-1	D (60) / C (28)	2	1-4 (10)
実施例28	R-1	A (60) / C (28)	2	1-11 (10)
実施例27	R-1	A (60) / C (28)	2	1-13 (10)
実施例28	R-1	A (60) / C (28)	2	1-17 (10)
比較例4	R-1	A (70) / C (28)	2	なし
比較例5	R-1	D (70) / C (28)	2	なし
比較例8	R-1	A (60) / C (28)	2	トブチルピリジン
The state of the s		1 (4.5)		

[0154] [Formula 39]

A
$$C_4H_9(n)$$
 $C_4H_9(n)$ $C_4H_9(n)$ $C_4H_9(n)$ C_2H_5 C_2H_5

[0155] The fused salt A of an example 29 - 3960 mass %, the fused salt B of 28 mass %, the iodine of 2 mass %, and the siloxane compound 1-4 of 10 mass % were mixed, the electrophile agent E-3 was added further, and the uniform electrolyte constituent was prepared. Here, the electrophile agent was added so that the mole ratio of the electrophilic part of the electrophile agent to the reactive site of a siloxane compound might be set to 1. After applying 5micro of obtained electrolyte constituents 1 to the coloring matter sensitization TiO2 electrode substrate produced as mentioned above, it put under reduced pressure of this electrode, and the electrolyte constituent was made to permeate. After the electrolyte constituent fully permeated and the air in an electrode fell out, platinum vacuum evaporationo glass was laid on top of this, it was left at 50 degrees C for 10 hours, polymerization reaction was performed, and the photoelectrochemical cell of an example 29 using the second electrolyte constituent of this invention was obtained. The photoelectrochemical cell of examples 30-39 using the second electrolyte constituent of this invention was obtained like the above-mentioned example 29 except having changed fused salt, siloxane compounds and those mass ratios, and an electrophile agent and its mole ratio, as shown in the following table 4. The coloring matter used for the photoelectrochemical cell of the above-mentioned examples 29-39, fused salt and its mass ratio, the mass ratio of iodine, an electrophile agent, its mole ratio, a siloxane compound, and its mass ratio are collectively shown in Table 4. In addition, the mole ratio of an electrophile agent is a mole ratio of the electrophilic part of the electrophile agent to the reactive site of a siloxane compound among Table 4. [0156]

[Table 4]

D

先置気 化学電池	色素	溶融塩 (質量%)	ヨウ素 (質量%)	求電子対 (モル比)	シロキサン化合物 (質量%)
実施例29	R-1	A (60) / B (28)	2	E-3 (1)	1-4 (10)
実施例30	R-1	A (60) / C (28)	2	E-3 (1)	1-4 (10)
実施例31	R-1	A (60) / C (28)	2	E-12 (1)	1-4 (10)
実施例32	R-1	A (60) / B (28)	2	E-3 (1)	1-6 (10)
実施例33	R-1	D (60) / C (28)	2	E-3 (1)	1-4 (10)
实施例34	R-1	D (60) / C (28)	2	E-12 (1)	1-4 (10)
支施例35	R-1	D (80) / C (28)	2	E-3 (1)	1-6 (10)
支性例38	R-1	D (60) / C (28)	2	E-3 (0.9), E-5 (0.1)	1-4 (10)
夹连例37	R-1	A (60) / C (28)	2	E-3 (1)	1-11 (10)
夹连例38	R-1	A (60) / C (28)	2	E-3 (1)	1-13 (10)
空域 (1929) D://WW	R-1	A 48m / c 129)	cgi-hin	, F3 (1)	.1-17 (10)

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[0157] The photoelectrochemical cell of the example 7 of comparison was produced like the above-mentioned example 3 of comparison except having changed to example of comparison 7 propylene carbonate, and having used the above-mentioned compound C.

[0158] 4. The simulation sunlight which does not include ultraviolet rays was generated by letting AM1.5 filter (product made from Oriel), and a sharp cut filter (Kenko L-42) pass for the light of the xenon lamp of measurement 500W of a photoelectric conversion efficiency (product made from USHIO Electrical and electric equipment). This luminous intensity was 86 mW/cm2. The electrical and electric equipment which irradiated the photoelectrochemical cell of the examples 1-39 produced at 50 degrees C and the examples 1-7 of comparison, and generated this simulation sunlight was measured in the current-potential measuring device (case rhe SMU238 type). The decreasing rate of the short-circuit current density (Jsc) of each photoelectrochemical cell called for by this, an open circuit voltage (Voc), a form factor (FF), a conversion efficiency (eta), and the conversion efficiency after 360-hour continuous irradiation is shown in Tables 5-8.

[Table 5]

光電気 化学電池	短絡電流密度 (Jsc) mA/cm²	開放電圧 (Voc) V	形状因子 (FF)	変換効率 (η) 96	7低下率 (360時間後) %
実施例1	10.1	0.72	0.82	5.24	78
实施例2	9,75	0.72	0.61	4.98	78
実施例3	9.89	0.73	0.62	5.20	77
実施例	10.2	0.72	0.61	5.21	76
実施例5	9,62	0.73	0.60	4.90	78
実施例8	9,43	0.74	0.61	4.95	78
実施例7	9.67	0.73	0.60	4.92	77
比較例1	9,92	0.65	0.65	4.87	99
比較例2	9.42	0.72	0.61	4.81	99

[0160] [Table 6]

光電気 化学電池	短絡電流密度 (Jsc) mA/cm ²	開放電圧 (Voc) V	形状因子 (FF)	変換効率 (カ) %	7任下率 (380時間後) %
実施例8	9.12	0.68	0.57	4.11	42
実施例9	8.97	0.67	0,58	3.86	36
実施例10	8.89	0.67	0.56	3.82	35
実施例11	9.10	0.66	0.57	3,98	41
実施例12	9,12	0.68	0.58	4.04	37
実施例13	9,10	0,66	0.56	3.91	33
実施例14	9.11	0.67	0.58	3.97	29
実施例15	7.67	0.68	0.56	3.40	33
実施例18	7.58	0.69	0.57	. 3,47	35
実施例17	7.90	0.68	0.57	3.56	37
比较例3	2.22	0.64	0.65	1.07	62

[0161] [Table 7]

光電気 化学電池	短格電流密度 (Jsc)	開放電圧 (Voc)	形状因子	変換効率 (n)	7 低下率 (380時間後)
化子是沿	mA/cm²	٧	(FF)	96	96
実施例18	9.11	0.61	0.57	3.68	18
実施例19	9.08	0.62	0.58	3.80	18
実施例20	9.20	0.82	0.58	3.85	16
実施例21	9.11	0.60	0.58	3.69	17
実施例22	9.28	0.60	0.57	3.69	17
実施例23	9.14	0.50	0.58	3.70	16
实施例24	9.13	0.61	0.57	3.69	16
実施例25	9.09	0.61	0.58	3.74	14
実施例26	8.10	0.82	0.58	3.39	15
实施例27	8.99	0.60	0.57	3.58	16
実施例28	8.98	0.61	0.57	3.63	15
比較例4	7.85	0.52	0.58	2.75	35
比較例5	7.90	0.55	0.59	2.98	30
比較例8	7.20	0.62	0.56	2.91	45

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[0162] [Table 8]

光電気 化学電池	短絡電波密度 (Jsc) mA/cm²	院放電圧 (Voc) V	部状因子 (FF)	変換効率 (カ) 96	7年下率 (380時間後) %
実造例29	8.11	0.57	0.55	2.96	18
安监例30	8.20	0.59	0.55	3.09	18
実施例31	8.20	0.59	0.54	3.03	16
実施例32	8.09	0.55	0.55	2.85	17
実施例33	8.28	0.60	0.55	3.18	17
実施例34	8-28	0.61	0.54	3.17	18
実施例35	8.25	0.58	0.55	3.08	18
実施例38	8.27	0.58	0.54	3.01	14
実施例37	8.01	0.60	0.55	2.84	15
実施例38	7.11	0.61	0.54	2.72	14
実施例39	7.05	0.60	0.54	2.68	15
比較例7	1.40	0.52	0.50	0.42	14

[0163] To this causing [the open circuit voltage] a low photoelectric conversion efficiency low, as for the photoelectrochemical cell of the examples 1, 4, and 5 of comparison, an open circuit voltage is high and the conversion efficiency of the photoelectrochemical cell [the examples 1-7 and the photoelectrochemical cell of 18-28] using the first electrolyte constituent of this invention is improving in connection with it so that more clearly than Table 5 and 7. Moreover, although degradation after dark place preservation is remarkable in the photoelectrochemical cell of the examples 1 and 2 of comparison which contain many organic solvents in an electrolyte constituent, and examples 1-7, by using the first electrolyte constituent of this invention shows that endurance is improved. Moreover, Table 6 and 8 shows that the examples 8-17 and the photoelectrochemical cell of 29-39 using the second electrolyte constituent of this invention show the outstanding conversion efficiency and outstanding endurance as compared with the photoelectrochemical cell of the examples 3 and 7 of comparison using the conventional solid electrolyte.

[Effect of the Invention] As explained in full detail above, the first of this invention and second electrolyte constituents are excellent in endurance and charge transportation ability, and the optoelectric transducer and photoelectric cell using this electrolyte constituent show the outstanding endurance and the outstanding photoelectric transfer characteristic. This photoelectric cell is very effective as a solar battery.

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TECHNICAL FIELD

[The technical field to which invention belongs] this invention relates to the optoelectric transducer and photoelectric cell in which the endurance and the photoelectric transfer characteristic which were excellent since the electrolyte constituent excellent in endurance and charge transportation ability and this electrolyte constituent were used are shown.

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PRIOR ART

[Description of the Prior Art] The liquefied electrolyte constituent (electrolytic solution) which dissolved the electrolyte salt in the solvent has been used from the former as an electrolyte of electrochemical elements, such as a cell, a capacitor, a sensor, a display device, and a record element. However, in the electrochemical element using such a liquefied electrolyte constituent, this constituent may be revealed between prolonged use or preservation, and reliability is missing. [0003] Although U.S. JP,4927721,B etc. is indicating the optoelectric transducer using the semiconductor particle which carried out sensitization with coloring matter, and the photoelectrochemical cell using this in Nature, the 353rd volume, the 737-740th page, and 1991 Since the liquefied electrolyte constituent is used for the charge transporting bed also in these, this constituent reveals or is drained between prolonged use or preservation, a photoelectric conversion efficiency falls remarkably or there is a case where it stops functioning as an element. [0004] WO 93/No. 20565 proposed the optoelectric transducer which used the solid electrolyte under such a situation. Moreover, the Chemical Society of Japan, 7, 484 pages (1997) JP,7-288142,A, Solid State Ionics, 89, 263, and (1986) JP,9-27352,A proposed the optoelectric transducer containing the solid electrolyte which used the bridge formation polyethylene-oxide system high molecular compound. However, the optoelectric transducer using these solid electrolytes has the photoelectric transfer characteristic, especially inadequate short-circuit current density, and, in addition, its endurance is not enough, either.

[0005] Moreover, in order to prevent disclosure and an exhaustion of an electrolyte constituent and to raise the endurance of an optoelectric transducer, the method of using a pyridinium salt, an imidazolium salt, a thoria ZORIUMU salt, etc. is indicated (WO 95/No. 18456, JP,8-259543,A, electrochemistry, the 65th volume, No. 11, 923page (1997), etc.). These salts are in a melting state in ordinary temperature (near 25 degree C), and are called room temperature fused salt. Since solvents, such as water and an organic solvent, are unnecessary or little and can be managed with this method, the endurance of a cell improves. However, especially the optoelectric transducer using such room temperature fused salt has a low open circuit voltage, and its photoelectric conversion efficiency is not good.

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EFFECT OF THE INVENTION

[Effect of the Invention] As explained in full detail above, the first of this invention and second electrolyte constituents are excellent in endurance and charge transportation ability, and the optoelectric transducer and photoelectric cell using this electrolyte constituent show the outstanding endurance and the outstanding photoelectric transfer characteristic. This photoelectric cell is very effective as a solar battery.

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TECHNICAL PROBLEM

[Problem(s) to be Solved by the Invention] Therefore, the purpose of this invention is offering the optoelectric transducer and photoelectric cell in which the endurance and the photoelectric transfer characteristic which were excellent since the electrolyte constituent excellent in endurance and charge transportation ability and this electrolyte constituent were used are shown.

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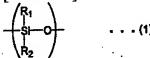
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MEANS.

[Means for Solving the Problem] The electrolyte constituent containing the polymer which this invention person makes the electrolyte constituent containing a siloxane compound including a specific repeat unit and this siloxane compound react with an electrophile agent wholeheartedly in view of the above-mentioned purpose as a result of research, and is obtained discovered that the outstanding charge transportation ability and outstanding endurance were shown, and hit on an idea of it to this invention.

[0008] namely, the first electrolyte constituent of this invention -- following general formula (1): -- [Formula 7]



R₁: L₁-Q₀₁ R₂: L₂-Q₀₂

(However, R1 L1- Q01 (L1 expresses combination or a divalent connection machine)) when Q01 expresses a substituent when L1 expresses combination, and L1 expresses a divalent connection machine, Q01 expresses a hydrogen atom or a substituent Expressing, R2 is L2-Q02 (when Q02 expresses a substituent when L2 expresses combination or a divalent connection machine and L2 expresses combination, and L2 expresses a divalent connection machine, Q02 expresses a hydrogen atom or a substituent.). it expresses It is characterized by containing the siloxane compound which has at least two substituents which react with an electrophile agent and can form covalent bond including the repeat unit expressed.

[0009] Moreover, it is characterized by the second electrolyte constituent of this invention containing the polymer which the electrophile agent which has at least two leaving groups, and the siloxane compound which has at least two substituents which react with an electrophile agent and can form covalent bond including the repeat unit expressed by the above-mentioned general formula (1) are made to react, and is obtained.

[0010] The first of this invention and second electrolyte constituents can be preferably used for a photoelectric cell. The optoelectric transducer of this invention has a conductive layer, a photosensitive layer, a charge transporting bed, and a counter electrode, and it is characterized by this charge transporting bed containing the electrolyte constituent of the above first, or the second electrolyte constituent. The photoelectric cell of this invention uses this optoelectric transducer. [0011] By filling the following conditions with this invention, the optoelectric transducer and photoelectric cell in which the electrolyte constituent which has further excellent endurance or charge transportation ability, the further excellent endurance, and the photoelectric transfer characteristic are shown are obtained.

[0012] (1) In the first and second electrolyte constituents, as for the substituent which reacts with an electrophile agent and can form covalent bond, it is desirable that it is a basic group, and this basic group is an imidazolyl machine which is not replaced [the pyridyl machine which is not replaced / substitution or /, substitution, or] especially preferably. As for pKa of the conjugate acid of the compound which comes to add hydrogen to this basic group, it is desirable that it is 3-15.

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[0013] (2) As for the siloxane compound used for the first and second electrolyte constituents, being expressed by the following general formula (2) is desirable, and being expressed by the following general formula (3) is more desirable. [Formula 8]

$$Q_{1} - L_{1} - S_{12} - O \begin{pmatrix} R_{13} \\ S_{1} - O \\ R_{12} \end{pmatrix} - \begin{pmatrix} R_{13} \\ S_{1} - O \\ R_{14} \end{pmatrix} - \begin{pmatrix} R_{15} \\ S_{1} - C \\ R_{16} \end{pmatrix} - \begin{pmatrix} R_{15} \\ S_{1} - C \\ R_{16} \end{pmatrix} - \begin{pmatrix} R_{15} \\ S_{1} - C \\ R_{16} \end{pmatrix} - \begin{pmatrix} R_{15} \\ S_{1} - C \\ R_{16} \end{pmatrix}$$

The substituent which Q1 and Q2 react with the above-mentioned electrophile agent independently, respectively, and can form covalent bond is expressed among a general formula (2), R11-R16 express independently the aryl group which is not replaced [the alkyl group which is not replaced / substitution or /, substitution, or], respectively, L11 and L12 express a divalent connection machine independently, respectively, and n expresses the integer of 1-1000. [Formula 9]

$$\begin{pmatrix}
Q_{11} \\
N
\end{pmatrix} = L_{11} - SH - O \begin{pmatrix}
R_{13} \\
SH - O
\end{pmatrix} - SH - L_{12} - \begin{pmatrix}
Q_{21} \\
N
\end{pmatrix}$$
...(3)

Q11 and Q21 express the atomic group which forms 5 or 6 member ring with a nitrogen atom independently, respectively among a general formula (3), R11-R16 express independently the aryl group which is not replaced [the alkyl group which is not replaced / substitution or /, substitution, or], respectively, L11 and L12 express a divalent connection machine independently, respectively, and n expresses the integer of 1-1000.

[0014] (3) As for Q11 and Q21 in a general formula (3), in the first and second electrolyte constituents, it is desirable respectively to be constituted by one or more sorts of atoms chosen from the group which consists of a carbon atom, a hydrogen atom, a nitrogen atom, an oxygen atom, and a sulfur atom.

[0015] (4) As for 5 or 6 member ring which Q11 and Q21 in a general formula (3) form with a nitrogen atom, respectively, in the first and second electrolyte constituents, it is desirable that they are especially an imidazole ring or a pyridine ring.

[0016] (5) As for pKa of the conjugate acid of the anion which the leaving group which an electrophile agent has ****s and produces, in the second electrolyte constituent, it is desirable that it is ten or less.

[0017] (6) As for the leaving group which an electrophile agent has, in the second electrolyte constituent, it is desirable respectively that they are a halogen atom, an alkylsulfonyloxy machine, or an arylsulfonyloxy machine.

[0018] (7) As for the first and second solvent contents of an electrolyte constituent, it is desirable that it is especially below 10 mass % of the whole electrolyte constituent.

[0019] (8) As for the first and second electrolyte constituents, it is desirable to contain an iodine salt and/or iodine in addition to the above-mentioned siloxane compound and the above-mentioned polymer.

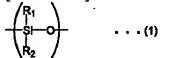
[0020] (9) As for the photosensitive layer of an optoelectric transducer, it is desirable to contain the semiconductor particle by which sensitization was carried out with coloring matter. As for this semiconductor particle, it is desirable that a metal chalcogenide particle is included, and, as for a metal chalcogenide particle, it is desirable that a titanium oxide particle is included. Moreover, as for coloring matter, it is desirable that they are metal complex coloring matter and/or poly methine coloring matter.

[0021]

[Embodiments of the Invention] [1] The first electrolyte constituent of an electrolyte constituent this invention contains the specific siloxane compound mentioned later. Moreover, the second electrolyte constituent of this invention contains the polymer which this siloxane compound is made to react with the electrophile agent which has at least two leaving groups, and is obtained. The second electrolyte constituent of this invention hardly shows a fluidity, but is excellent in endurance and http://www4.ipdl.jpo.go.jp/cgi-bin/tran_web_cgi_ejje 6/3/2003 charge transportation ability. The first of this invention and second electrolyte constituents may contain an electrolyte salt, a solvent, etc. further. Hereafter, each the first of this invention and second components of an electrolyte constituent are explained in full detail.

[0022] (A) The siloxane compound used for the first of a siloxane compound this invention and second electrolyte constituents has at least two substituents which react with an electrophile agent and can form covalent bond, including the repeat unit expressed by the following general formula (1). In the second electrolyte constituent of this invention, this siloxane compound receives ornamentation of alkylation, class[the / 4th]-izing, etc. by the electrophile agent.

[Formula 10]



R₁: L₁-Q₀₁ R₂: L₂-Q₀₂

[0023] R1 expresses L1-Q01 among a general formula (1), and R2 expresses L2-Q02. Here, when Q01 expresses a substituent when L1 expresses combination or a divalent connection machine and L1 expresses combination, and L1 expresses a divalent connection machine, Q01 expresses a hydrogen atom or a substituent. Moreover, when Q02 expresses a substituent when L2 expresses combination or a divalent connection machine and L2 expresses combination, and L2 expresses a divalent connection machine, Q02 expresses a hydrogen atom or a substituent, when they may also be included although a siloxane compound includes one repeat unit expressed by the general formula (1), and more than one are included, even if R1 and R2 in each repeat unit are the same respectively, they may differ [two or more]

[0024] When L1 or L2 expresses a divalent connection machine, as the example An alkylene machine, An alkenylene group, an arylene machine, -O-, -S-, -CO-, -NR'- (R' is a hydrogen atom or an alkyl group), - SO2- and - SiR" -- R"'- (R -- "and R"' -- Respectively -- Alkyl Group --) An aryl group, an alkoxy group or aryloxy groups, such combination, etc. are mentioned. Especially -(CH2) m1-, -O-, -(OCH2CH2) m1-, - M1-O-, -(OCH2CH2) M1-CH2-, (OCH2CH2) - (OCH2CH2CH2) m1-, -(OCH2CH2CH2) m1-O-, -(OCH2CH2CH2) m1-CH2-, -(CH2) m1-(Si(CH3)2-O) m2-, and -O-(CH2) m1-(Si(CH3)2-O) m2- is desirable. In addition, m1 and m2 express the integer of 1-20, respectively.

[0025] the case where Q01 and Q02 express a substituent -- as the example of a desirable substituent -- an alkyl group (the shape of a straight chain --) You may be a letter of branching, or annular. For example, a methyl group, an ethyl group, n-propyl group, An isopropyl machine, t-butyl, n-octyl machine, a ray KOSHIRU machine, 2-chloro ethyl group, 2-cyano ethyl group, a 2-ethylhexyl machine, a cyclohexyl machine, a cyclopentylic group, aryl groups (for example, a phenyl group --), such as a 4-n-dodecyl cyclohexyl machine Heterocycle machines, such as p-tolyl group, a naphthyl group, and m-chlorophenyl machine (it is the univalent basis which comes preferably to remove one hydrogen atom from the aromatic heterocycle compound or un-aromatic heterocycle compound which is not replaced [the substitution of 5 or 6 members, or]) For example, 2-furil machine, 2thienyl group, 2-pyrimidinyl group, 2-pyridyl machine, halogen atoms (for example, a chlorine atom --), such as 4-pyridyl machine and 1-imidazolyl machine a cyano group, a nitro group and hydroxyl groups, such as a bromine atom and an iodine atom, and an alkoxy group (for example, a methoxy machine --) An ethoxy basis, an isopropoxy group, a t-butoxy machine, n-octyloxy machine, a 2methoxyethoxy machine, -O(CH2CH2O) mCH3 grade, and a silyloxy machine (for example, a trimethyl silyloxy machine --) t-buthyldimethyl silyloxy machine, a trimethoxy silyloxy machine, etc., an acyloxy machine (for example, a formyloxy machine, an acetyloxy machine, and a pivaloyloxy machine --) A stearoyl oxy-basis, a benzoyloxy machine, p-methoxypheny carbonyloxy group, etc., a carbamoyloxy machine (for example, N and an N-dimethylcarbamoyloxy machine --) A N.Ndiethylcarbamoyloxy machine, morpholino carbonyloxy group, An N and N-G n-octyl aminocarbonyl oxy-basis, an N-n-octyl carbamoyloxy machine, etc., alkoxy carbonyloxy group (for example, a

methoxycarbonyloxy machine --) An ethoxycarbonyloxy machine, t-buthoxycarbonyloxy machine, noctyl carbonyloxy group, etc., aryloxy carbonyloxy group (for example, a phenoxy carbonyloxy machine --) p-methoxy phenoxy carbonyloxy machine, an p-n-hexadecyl oxy-phenoxy carbonyloxy machine, etc., the amino group (for example, the amino group, a methylamino machine, a dimethylamino machine, and the Ernie Reno machine --) the acylamino machines (for example, a formylamino machine --), such as N-methyl ANIRINO machine and a diphenylamino machine An acetylamino machine, the pivaloyl amino group, the lauroyl amino group, a benzoylamino machine, 3, 4, a 5-tree n-octyloxy phenyl carbonylamino machine, etc., the aminocarbonyl amino group (for example, carbamoyl amino machine, N, and N-dimethylamino carbonylamino machine --) N and Ndiethylamino carbonylamino machine, a morpholino carbonylamino machine, etc., an alkoxycarbonylamino machine (for example, a methoxycarbonylamino machine --) An ethoxycarbonylamino machine, t-butoxycarbonylamino machine, n-octadecyloxycarbonylamino machine, aryloxycarbonylamine machines (for example, a phenoxycarbonylamino machine --), such as N-methyl methoxycarbonylamino machine p-chloro phenoxycarbonylamino machine, an m-noctyloxy phenoxycarbonylamino machine, etc., a sulfamoylamino group (for example, sulfamoylamino group, N, and N-dimethylamino sulfonylamino machine --) alkyl sulfonylamino machines (for example, a methylsulfonylamino machine --), such as an N-n-octyl amino sulfonylamino machine aryl sulfonylamino machines (for example, a phenyl sulfonylamino machine --), such as a butylsulphonylamino machine 2, 3, 5-TORIKURORO phenyl sulfonylamino machine, pmethylphenyl sulfonylamino machine, etc., a sulfhydryl group and an alkyl thio machine (for example, a methylthio machine and an ethyl thio machine --) aryl thio machines (for example, a phenylthio machine --), such as an n-hexadecyl thio machine heterocycle thio machines (for example, a 2-benzothiazolethio group --), such as p-chloro phenylthio machine and m-methoxy phenylthio machine sulfamoyl groups (for example, N-ethyl sulfamoyl group --), such as a 1-phenyl tetrazole-5-IRUCHIO machine N-(3-dodecyloxy propyl) sulfamoyl group, N, and N-dimethyl sulfamoyl group, N-acetyl sulfamoyl group, N-benzoyl sulfamoyl group, alkyl sulfinyl machines (for example, a methyl sulfinyl machine --), such as N-(N'-phenylcarbamoyl) sulfamoyl group aryl sulfinyl machines (for example, a phenyl sulfinyl machine --), such as an ethyl sulfinyl machine alkyl sulfonyl machines (for example, a methyl sulfonyl machine --), such as p-methylphenyl sulfinyl machine aryl sulfonyl machines (for example, a phenyl sulfonyl machine --), such as an ethyl sulfonyl machine acyl groups (for example, an acetyl group --), such as p-methylphenyl sulfonyl machine A pivaloyl machine, 2chloro acetyl group, a stearoyl machine, a benzoyl, aryloxy carbonyl groups (for example, a phenoxy carbonyl group --), such as an p-n-octyloxy phenyl carbonyl group o-chloro phenoxy carbonyl group, m-nitroglycerine phenoxy carbonyl group, alkoxy carbonyl groups (for example, a methoxycarbonyl group --), such as a p-t-butyl phenoxy carbonyl group An ethoxycarbonyl machine, a tbutoxycarbonyl machine, n-octadecyl oxycarbonyl machine, etc., a carbamoyl group (for example, a carbamoyl group and N-methyl carbamoyl group --) An N and N-dimethyl carbamoyl-group, N, and N-G n-octyl carbamoyl group, Silyl machines, such as N-(methyl sulfonyl) carbamoyl group (it is the silyl machine which is not replaced [the substitution of carbon numbers 3-30, or] preferably) For example, a trimethylsilyl machine, t-butyldimethylsilyl machine, a phenyl dimethylsilyl machine, etc., Phosphino machines (being the phosphino machine which is not replaced [the substitution of carbon numbers 2-30 or] preferably for example, a dimethyl phosphino machine, a diphenyl phosphino machine, a methylphenoxy phosphino machine, etc.) etc. are mentioned. Especially, an alkyl group, an aryl group, a silyl machine, an alkoxy group, an aryloxy group, a silyloxy machine, a heterocycle machine, the amino group, an alkyl thio machine, and a phosphino machine are more desirable, and an alkyl group, a silyl machine, an alkoxy group, a silyloxy machine, and especially a heterocycle machine are desirable.

[0026] The above-mentioned siloxane compound has two or more substituents which react with an electrophilic agent and can form covalent bond. As for the substituent which reacts with an electrophilic agent and can form covalent bond, in the first and second electrolyte constituents, it is desirable that it is a basic group. pKa of the conjugate acid of the compound with which a basic group comes to add hydrogen to it points out three or more bases here. As for pKa of this conjugate acid, it is desirable that it is 3-15, and it is more desirable that it is 4-12. such a basic group -- the amino

group (a dimethylamino machine and a diethylamino machine --) nitrogen-containing heterocycle machines (a morpholino machine and a quinuclidinyl machine --), such as the Ernie Reno machine A piperazinyl machine, a piperidino machine, a pyrrolidino machine, an imidazolyl machine, 2-methyl imidazolyl machine, A quinolyl machine, an acridinyl machine, a pyridyl machine, 2-methyl pyridyl machine, It is desirable that they are guanidino machines (trimethyl guanidino machine etc.), such as a diazabicyclo undecenyl machine, it is more desirable that it is a nitrogen-containing heterocycle machine, and it is desirable that it is especially the imidazolyl machine which is not replaced [the pyridyl machine which is not replaced / substitution or /, substitution, or]. The above-mentioned siloxane compound may have such a basic group at the side chain and/or end in the repeat unit expressed by the general formula (1). When it has this basic group in the side chain in the repeat unit expressed by the general formula (1), Q01 in a general formula (1) and/or Q02 are these basic groups.

[0027] As for the siloxane compound used for the first of this invention, and second electrolyte constituents, being expressed by the following general formula (2) is desirable, and being expressed by the following general formula (3) is more desirable.

[Formula 11]

$$Q_{1} - L_{11} - S_{1} - O - S_{1} - C_{12} - C_{2}$$

$$R_{12} - R_{14} - R_{16}$$

$$R_{16} - R_{16}$$

$$R_{17} - R_{18} - R_{18}$$

$$R_{18} - R_{18} - R_{18}$$

[Formula 12]
$$\begin{array}{c}
Q_{11} \\
N
\end{array}$$

$$\begin{array}{c}
R_{11} \\
R_{12}
\end{array}$$

$$\begin{array}{c}
R_{13} \\
S_{1} \\
R_{16}
\end{array}$$

$$\begin{array}{c}
R_{15} \\
R_{16}
\end{array}$$

$$\begin{array}{c}
Q_{21} \\
N
\end{array}$$

$$\begin{array}{c}
\vdots \\
N
\end{array}$$

[0028] Q1 and Q2 express the substituent which reacts with an electrophile agent independently, respectively and can form covalent bond among a general formula (2). The electrophile agent in this substituent and the atom which reacts are a nitrogen atom, the Lynn atom, or a sulfur atom preferably, is a nitrogen atom or the Lynn atom more preferably, and is a nitrogen atom especially preferably. As a substituent which Q1 and Q2 express, the amino group, a phosphino machine, a heterocycle machine, an alkyl thio machine, etc. are mentioned.

[0029] R11-R16 express independently the aryl group which is not replaced [the alkyl group which is not replaced / substitution or /, substitution, or] among a general formula (2), respectively. R11-R16 are the alkyl groups of carbon numbers 1-10 preferably, are the alkyl group of carbon numbers 1-3 more preferably, and are a methyl group especially preferably.

[0030] The above Q1 and Q2, and R11-R16 may have the substituent, respectively, as the desirable example of this substituent -- an alkyl group (a methyl group and an ethyl group --) A propyl group, an isopropyl machine, a butyl, a pentyl machine, a hexyl machine, An octyl machine, a 2-ethylhexyl machine, t-octyl machine, a decyl group, the dodecyl, A tetradecyl machine, 2-hexyl decyl group, an octadecyl machine, a cyclohexyl machine, alkenyl machines (a vinyl group --), such as a cyclopentylic group, 2-carboxy ethyl group, and a benzyl A halogens atom, such as an allyl group (a fluorine atom, a chlorine atom, a bromine atom, iodine atom, etc.), A cyano group, an alkoxy group (a methoxy machine, an ethoxy basis, methoxyethoxy machine, etc.), aryloxy machines (phenoxy machine etc.) and an alkyl thio machine (a methylthio machine --) Acyl groups, such as an ethyl thio machine (an acetyl group, a propionyl machine, benzoyl, etc.), sulfonyl machines (a methane sulfonyl machine, benzenesulphonyl machine, etc.) and an acyloxy machine (an acetoxy machine --) sulfonyloxy machines (a methane sulfo NIRIOKISHI machine --), such as a benzoyloxy machine Phosphonyl groups, such as a toluenesulfonyloxy machine (diethyl phosphonyl group etc.), Amide groups (an acetylamino machine, benzoylamino machine, etc.), carbamoyl groups (N and N-dimethyl carbamoyl group, N-phenylcarbamoyl machine, etc.), an aryl group, heterocycle machines (a phenyl group, toluyl machine, etc.) (a pyridyl machine, an imidazolyl machine, furanyl machine, etc.), etc. are mentioned.

[0031] L11 and L12 express a divalent connection machine independently among a general formula http://www4.ipdl.jpo.go.jp/cgi-bin/tran_web_cgi_ejje 6/3/2003

(2), respectively. As an example of this divalent connection machine, the connection machine which comes to combine an alkylene machine, an alkenylene group, an arylene machine, -O-, -S-, -CO-, -NR'- (for R' to express a hydrogen atom or an alkyl group), -SO2-, -SiRR'- (for R and R' to express an alkyl group or an aryl group, respectively), and these [two / or more] is mentioned. [0032] When L11 and L12 are an alkylene machine, an alkenylene group, or an arylene machine, These A halogen atom (a fluorine atom, a chlorine atom, a bromine atom, iodine atom, etc.), A hydroxyl group, the amino group, a nitro group, a carboxyl group, a carbamoyl group, a sulfonic group, A sulfonamide machine, acyl groups (a formyl machine, acetyl group, etc.), an acyloxy machine, The acylamino machine, alkyl groups (an acetamino machine, bends amino group, etc.), You may have substituents, such as alkoxy groups (a methoxy machine, an ethoxy basis, methoxyethoxy machine, etc.), an AKOKISHI carbonyl group, an alkyl sulfonyl machine, an aryl group, an aryloxy group, and aryl sulfonyl machines (phenoxy machine etc.).

[0033] n expresses the integer of 1-1000 among a general formula (2). n is the integer of 1-500 preferably, and is the integer of 1-100 especially preferably. If n is larger than 1000, a reactant fall with ionic conductivity and an electrophile agent will be caused.

[0034] Q11 and Q21 express the atomic group which forms 5 or 6 member ring with a nitrogen atom independently, respectively among a general formula (3). As for Q11 and Q21, it is desirable to be constituted by one or more sorts of atoms chosen from the group which consists of a carbon atom, a hydrogen atom, a nitrogen atom, an oxygen atom, and a sulfur atom.

[0035] As for 5 or 6 member ring formed of Q11 and Q21, it is desirable that it is an unsaturation ring. As 5 member rings, a pyrrolidine ring, an oxazole ring, a thiazole ring, an imidazole ring, a pyrazole ring, an isoxazole ring, a thiadiazole ring, an oxadiazole ring, and a triazole ring are desirable, a thiazole ring, an imidazole ring, and a triazole ring are more desirable, and especially an imidazole ring is desirable. As 6 member rings, a morpholine ring, a piperidine ring, a pyridine ring, a pyrimidine ring, a pyridazine ring, a pyrazine ring, and a triazine ring are desirable, and especially a pyridine ring is desirable.

[0036] R11-R16, L11 and L12, and n in a general formula (3) are them in a general formula (2), and homonymy, and its same is said of a desirable mode.

[0037] Although the example 1-1 to 1-18 of the siloxane compound used for the first of this invention and second electrolyte constituents is shown below, this invention is not limited to them. [0038]

[Formula 13]

1-1
$$H_2N$$
 CH_3
 $CH_$

[0039]

[Formula 14]

[0040]

[0041]

[Formula 16]

1-11

1-12

1-13

1-15

[0042]

[Formula 17]

1-16

1-17

1-18

[0043] The siloxane compound used by this invention is easily compoundable with the substitution reaction by R1-H of a compound and/or R2-H which are expressed by the polymerization of the silane compound expressed by the following general formula (4), and the following general formula (5), the high DOROSHI relation reaction of the compound and olefin compound which are expressed by the following general formula (6), the condensation reaction of the compound and the alcoholic compound which are expressed by the following general formula (7), etc. [0044]

[Formula 18]

R41 and R42 express a halogen atom or an alkoxy group independently among a general formula (4),

[0045]

[Formula 19]

$$\begin{array}{c}
\begin{pmatrix}
R_{61} \\
Si - O
\end{pmatrix} \\
R_{62}
\end{pmatrix}$$
...(5)

R51 and R52 express an alkoxy group or an aryloxy group independently among a general formula (5), respectively. [0046]

[Formula 20].

$$R_{11}$$
 R_{13}
 R_{15}
 R_{16}
 R_{12}
 R_{14}
 R_{15}
 R_{15}
 R_{15}
 R_{15}
 R_{16}

R11-R16 and n in a general formula (6) are them in a general formula (2), and homonymy, and its same is said of a desirable mode.

[0047].

R11-R16 and n in a general formula (7) are them in a general formula (2), and homonymy, and its same is said of a desirable mode.

[0048] (B) The electrophilic agent used for the second electrolyte constituent of an electrophilic agent this invention has at least two leaving groups. This electrophilic agent reacts with "the substituent which reacts with an electrophilic agent and can form covalent bond" which the above-mentioned which reacts with an electrophilic agent and can form covalent bond" which the above-mentioned siloxane compound has, and when alkylation, onium chlorination, the 4th class-ization, etc. carry out this substituent, it forms the shape of a straight line, and the polymer over which the bridge was constructed.

[0049] In order to make moderate the degree of cross linking of the polymer which the above-mentioned siloxane compound and an electrophilic agent are made to react, and is obtained, as for the number of leaving groups, it is desirable that they are 2-4 pieces, and it is desirable that they are especially two pieces. If there are many leaving groups, a degree of cross linking will become high, consequently membraneous quality becomes hard, and ionic conductivity falls. Moreover, as for pKa of the conjugate acid of the anion which a leaving group ****s and produces, it is desirable that it is ten or less, and it is more desirable that it is five or less.

[0050] Leaving groups may be a halogen atom, an alkylsulfonyloxy machine, an arylsulfonyloxy machine, an acyloxy machine, etc., respectively. A halogen atom, an alkylsulfonyloxy machine, and an arylsulfonyloxy machine are desirable especially. As a halogen atom, an iodine atom, a bromine atom, and a chlorine atom are desirable, and an iodine atom and a bromine atom are more desirable. As an alkylsulfonyloxy machine, a methyl sulfonyloxy machine, a chloro methyl sulfonyloxy machine, and perfluoroalkyl sulfonyloxy machines (trifluoromethyl sulfonyloxy machine etc.) are desirable. As an arylsulfonyloxy machine, a benzene sulfonyloxy machine, a p-toluenesulfonyloxy machine, p-chlorobenzene sulfonyloxy machine, and p-nitrobenzene sulfonyloxy machine are desirable. As an acyloxy machine, the alkylcarbonyloxy machines (trifluoromethyl carbonyloxy group etc.) and aryl-carbonyloxy groups (p-fluoro phenyl carbonyloxy group etc.) which carried out fluorine substitution of all or a part of hydrogen atoms are desirable.

[0051] The amount of the electrophilic agent used can be arbitrarily defined according to the molecular weight or the degree of cross linking of a reaction rate with the above-mentioned siloxane compound, or the polymer to generate. The 0.01-2Eq of the 0.05-1.5Eq of the amount of the electrophilic agent used is 0.1-1Eq especially preferably more preferably preferably to the number of mols of "the substituent which reacts with an electrophilic agent and can form covalent bond" which a siloxane compound has. When the number of mols of the substituent which reacts with the electrophilic agent which a siloxane compound has, and can form covalent bond is not clear, the mass ratio of the electrophilic agent to the mass of a siloxane compound is one to 100 mass % preferably, and is three to 70 mass % more preferably. Even if it uses an electrophilic agent independently, it may use two or more sorts together. Although this invention shows the example E-1 to E-27 of an usable electrophilic agent hereafter, this invention is not limited to them.

[0052] [Formula 22] E-2

E-3

E-4

E-5

E-6

E-0

E-10

[0053]

[Formula 23] E-11

E-12

E-13

E-14

E-15

E-16

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[0056] (C) The polymer used for the second electrolyte constituent of a polymerization-reaction this invention can be obtained by the polymerization reaction of the above-mentioned electrophilic agent and a siloxane compound. The polymerization of them is carried out by the alkylation reaction which occurs in detail between the electrophilic part in an electrophilic agent, and the substituent which reacts with this electrophilic agent in a siloxane compound, and can form covalent bond, the reaction (for example, the 4th class-ized reaction of nitrogen) which forms an onium salt. As for the mass average molecular weight of the polymer obtained, it is desirable that it is 1000-1 million, and it is more desirable that it is 2000-500,000.

[0057] As for polymerization reaction, it is desirable to carry out besides an electrophilic agent and a siloxane compound under the conditions with which the electrolyte salt mentioned later coexists. http://www4.ipdl.jpo.go.jp/cgi-bin/tran_web_cgi_ejje 6/3/2003

Although an electrolyte salt may be added after a reaction, it is difficult to distribute an electrolyte salt uniformly in a polymer in this case, and it is not desirable.

[0058] When preparing the reaction solution containing a siloxane compound, an electrophilic agent, and an electrolyte salt and performing polymerization reaction, when a [siloxane compound + electrolyte salt + solvent] is made into 100 mass %, as for the mass ratio of a siloxane compound, it is desirable to consider as 1 - 50 mass %, and it is more desirable to consider as 3 - 30 mass %. Since carrier mobility will fall if a fluidity becomes that a siloxane compound is under 1 mass % inadequate and 60 mass % is exceeded, it is not desirable. In addition, even if it uses a siloxane compound independently, it may use two or more sorts together.

[0059] (D) As an electrolyte salt electrolyte salt, they are (a) I2 and an iodide (it LiI(s)), for example. NaI, KI, CsI, the metal iodide of CaI2 grade, tetrapod alkylammonium iodide, Combination with the 4th class ammonium iodine salts, such as pyridinium iodide and imidazolium iodide, etc., (b) -- Br2 and a bromide (LiBr, NaBr, KBr, CsBr, and the metal bromide of CaBr2 grade --) Combination with the 4th class ammonium bromine salts, such as a tetrapod alkylammonium star's picture and a pyridinium star's picture, etc., (c) Metal complexes (a ferrocyanic-acid salt-ferricyanic-acid salt, ferrocene-ferricinium ion, etc.), (d) sulfur compounds (the poly sodium sulfide, alkyl thiol-alkyl disulfide, etc.), (e) viologen coloring matter, a hydroquinone-quinone, etc. can be used. Especially, the combination of I2 and the 4th class ammonium iodine salt is desirable. You may mix and use an electrolyte salt.

[0060] Moreover, EP718288, WO 95/18456, J.Electrochem.Soc., Vol.143, No.10, and 3099 (1996), as an electrolyte salt Inorg. Chem., 35, and 1168-1178 (1996), JP,8-259543, A, electrochemistry, the 65th volume, No. 11, and 923 pages (1997) etc. — fused salt, such as a pyridinium salt indicated, an imidazolium salt, and a thoria ZORIUMU salt, can also be used The quality of molten salt electrolysis is desirable especially from a viewpoint of coexistence of endurance and charge transportation ability. In addition, fused salt here is liquefied in a room temperature, or it is the salt of the low melting point and it is [as for the melting point, it is desirable that it is 100 degrees C or less, and] desirable [the melting point] that it is especially near a room temperature.

[0061] as the fused salt which can be preferably used by this invention -- the following general formula (Y-a) -- what is expressed by either is mentioned for and (Y-b) (Y-c) [0062]

[Formula 26]

$$R_{y1}$$
 R_{y4}
 R_{y3}
 R_{y3}
 R_{y3}

[0063] Qy1 expresses the atomic group which forms the aromatic cation of 5 or 6 member ring with a nitrogen atom among a general formula (Y-a). As for Qy1, it is desirable to be constituted by one or more sorts of atoms chosen from the group which consists of a carbon atom, a hydrogen atom, a nitrogen atom, an oxygen atom, and a sulfur atom.

[0064] It is desirable that they are an oxazole ring, a thiazole ring, an imidazole ring, a pyrazole ring,

an isoxazole ring, a thiadiazole ring, an oxadiazole ring, a triazole ring, the Indore ring, or a pyrrole ring, as for 5 member rings formed of Qy1, it is more desirable that they are an oxazole ring, a thiazole ring, or an imidazole ring, and it is desirable that they are especially an oxazole ring or an imidazole ring. As for 6 member rings formed of Qy1, it is desirable that they are a pyridine ring, a pyrimidine ring, a pyridize ring, or a triazine ring, and it is more desirable that it is a pyridine ring.

[0065] Ayl expresses a nitrogen atom or the Lynn atom among a general formula (Y-b). [0066] A general formula (Y-a), and (Y-b) (Y-c) inner Ryl-inner Ry6 are an alkyl group (even if it has the shape of the carbon atomic numbers 1-24 and a straight chain preferably and is a letter of branching) which is not replaced [substitution or] independently, respectively. You may be a ring type. Moreover, for example, a methyl group, an ethyl group, a propyl group, An isopropyl machine, a pentyl machine, a hexyl machine, an octyl machine, a 2-ethylhexyl machine, t-octyl machine, a decyl group, a dodecyl machine, a tetradecyl machine, 2-hexyl decyl group, ARUKENIRU machines which are not replaced [substitution or], such as an octadecyl machine, a cyclohexyl machine, and a cyclopentylic group (even if it has the shape of the carbon atomic numbers 2-24 and a straight chain preferably, you may be a letter of branching) For example, a vinyl group, an allyl group, etc. are expressed, and it is the alkyl group of the carbon atomic numbers 2-18, or the ARUKENIRU machine of the carbon atomic numbers 2-18 more preferably, and is the alkyl group of the carbon atomic numbers 2-6 especially preferably.

[0067] Moreover, among Ry1-Ry4 in a general formula (Y-b), the un-aromatic ring in which two or more connect with mutually and they contain Ay1 may be formed, two or more may connect mutually and they may form a ring structure among Ry1-Ry6 in a general formula (Y-c).

[0068] A general formula (Y-a), inner Qy1, and Ry1-Ry6 may have the substituent, as the desirable example of this substituent -- a halogen atom (it Cl(s) and Br(s) F --) cyano groups, such as I, and an alkoxy group (a methoxy machine, an ethoxy basis, and a methoxyethoxy machine --) Aryloxy machines (phenoxy machine etc.), such as a methoxyethoxy ethoxy basis, Alkyl thio machines (a methylthio machine, ethyl thio machine, etc.), an alkoxy carbonyl group (ethoxycarbonyl machine etc.), carbonate machines (ethoxycarbonyloxy machine etc.) and an acyl group (an acetyl group --) sulfonyl machines (a methane sulfonyl machine --), such as a propionyl machine and a benzoyl Acyloxy machines (an acetoxy machine, benzoyloxy machine, etc.), such as a benzenesulphonyl machine, A sulfonyloxy machine (a methane sulfonyloxy machine, toluenesulfonyloxy machine, etc.), phosphonyl groups (diethyl phosphonyl group etc.) and an amide group (an acetylamino machine --) Carbamoyl groups, such as a benzoylamino machine (N and N-dimethyl carbamoyl group etc.), an alkyl group (a methyl group, an ethyl group, a propyl group, an isopropyl machine, and a cyclo propyl group --) Aryl groups, such as a butyl, 2-carboxy ethyl group, and a benzyl, heterocycle machines (a phenyl group, toluyl machine, etc.) (a pyridyl machine, an imidazolyl machine, furanyl machine, etc.), ARUKENIRU machines (a vinyl group, 1-propenyl machine, etc.), a silyl machine, a silyloxy machine, etc. are mentioned.

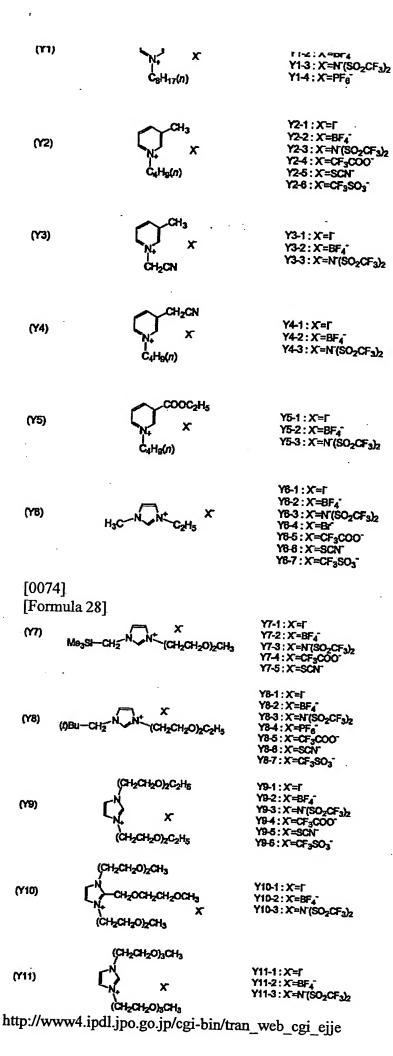
[0069] The fused salt expressed by the above-mentioned general formula (Y-a) - (Y-c) either may form a polymer through either Qy1, and Ry1-Ry6.

[0070] You may use the fused salt expressed by the above-mentioned general formula (Y-a) - (Y-c) either, mixing with the salt which could use it, having mixed two or more sorts even if it used it independently, and replaced iodide ion I- by other anions. As an anion which replaces I-, halogenide ion, SCN- (Cl-, Br-, etc.), BF4-, PF6-, ClO4-, 2 (CF3SO2)N-, 2 (CF3CF2SO2)N-, CF3SO3-, CH3SO3-, CF3COO-, Ph4B-, 3(CF3SO2) C-, etc. are desirable. They are SCN-, BF4-, CF3SO3-, CF3COO-, or (CF3SO2) 2N- more preferably.

[0071] Moreover, alkali-metal salts, such as other iodine salts and CF3COOLi like LiI, CF3COONa, LiSCN, and NaSCN, can also be added. As for the addition of an alkali-metal salt, it is desirable to consider as a 0.02 - 2 mass % grade, and it is still more desirable to consider as 0.1 to 1 mass %. [0072] Although - (Y29) is listed to the example (Y1) of the electrolyte salt preferably used by this invention, and the following, they do not limit this invention. [0073]

[Formula 27]

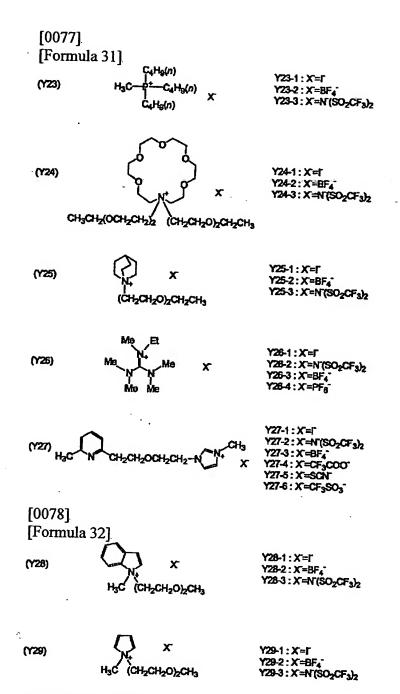
Y1-1:X=F



[0075] [Form] ula 29] x x x (ch ₂) ₆ N N C ₄ H ₆ (n)	Y12-1 : X=T Y12-2 : X=BF4* Y12-3 : X=N(SO ₂ CF ₃) ₂
(Y13)	H ₂ C-N-N ⁺ -C ₄ H _B (n)	Y13-1 : X'= Y13-2 : X'= 8F4 [*] Y13-3 : X'= Y(SO ₂ CF ₃) ₂
(Y14) _.	X C ₀ H ₁₃ (n)	Y14-1 : X=F Y14-2 : X=BF4* Y14-3 : X=H*(SO ₂ CF ₃) ₂
(Y15)	H ₃ C-\(\sum_{1}^{2}\)-CH ₃	Y15-1 : X=F Y15-2 : X=BF ₄ - Y15-3 : X=N (SO ₂ CF ₃) ₂
(Y16)	H ₃ C-N (CH ₂) ₆ -CH ₃	Y16-1 : X=I Y16-2 : X=BF4* Y16-3 : X=N(SO ₂ CF ₃) ₂
[0076 [Form	nula 30] ch _z ch _s	Y17-1: X=F Y17-2: X=BF ₄ Y17-3: X=N(SO ₂ CF ₃) ₂ Y17-4: X=PF ₆
(Y18)	CH2CH3 CH2CH3 CH2CH3 CH2CH3	Y18-1 : X=F Y18-2 : X=BF4 ⁻ Y18-3 : X=N(SO _Z CF ₃) ₂
(Y19)	(CH2CH2O)2CH3 H3C(OH2CH2C)2—N*—(CH2CH2O)2CH3 X CH3	Y19-1: X=F Y19-2: X=BF4 [*] Y19-3: X=N(SO _Z CF ₃) ₂ Y19-4: X=CF ₃ COO' Y19-5: X=SCN [*] Y19-8: X=CF ₃ SO ₃ *
(Y20)	CH2CH3 CH2CH3 CH2CH3	Y20-1 : X=F Y20-2 : X=BF4 ⁻ Y20-3 : X=N(SO ₂ CF ₃) ₂
(Y21)	H ² C C ⁴ H ⁶ (u)	Y21-1 : X=F Y21-2 : X=BF4 [*] Y21-3 : X=N(SO ₂ CF ₃) ₂
	Ĉ x	Y22-1 : X=F Y22-1 : X=F

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(Y22)



[0079] It is desirable not to use a solvent in this invention using what is in a melting state in ordinary temperature as an electrolyte salt. Although the solvent mentioned later may be added, as for the content of an electrolyte salt, it is desirable that it is more than 50 mass % to the whole electrolyte constituent, and it is desirable that it is especially more than 90 mass %. Moreover, as for the first of this invention, and second electrolyte constituents, it is desirable to contain the above-mentioned siloxane compound and iodine salts other than the above-mentioned polymer, and it is desirable that more than 50 mass % is an iodine salt among the salts to be used. Moreover, when using a solvent, it is desirable to make concentration of an electrolyte salt into 0.05 - 2 mol/l, and considering as 0.1 - 1.5 mol/l is more desirable.

[0080] (E) As for the first of an iodine this invention, and second electrolyte constituents, it is desirable to contain iodine. As for an iodine content, it is desirable that it is 0.1 to 20 mass % to the whole electrolyte constituent, and it is more desirable that it is 0.5 to 5 mass %. Moreover, iodine and a bromine can be added in the reaction solution containing the siloxane compound, electrophilic agent, and electrolyte salt which were mentioned above, and it can also be made to generate a redox couple beforehand. As for the concentration of the iodine in this reaction solution, or a bromine, considering as 0.01 - 0.3 mol/l is desirable.

[0081] (F) The first of a solvent this invention and second electrolyte constituents may contain the solvent. It is desirable that it is below the whole 50 mass %, as for the solvent content of an electrolyte constituent, it is more desirable that it is below 30 mass %, and it is desirable that it is especially below 10 mass %.

[0082] As a solvent, ionic mobility is high at hypoviscosity, or what can discover the ion conductivity which raised effective carrier concentration with the high dielectric constant, or was excellent since it was the both is desirable. as such a solvent -- a carbonate compound (ethylene carbonate --) Heterocyclic compounds, such as propylene carbonate (3-methyl-2-oxazolidinone etc.), ether. Heterocyclic compounds (a dioxane, diethylether, etc.) and chain-like ether (ethylene glycol dialkyl ether --) The propylene-glycol dialkyl ether, the polyethylene-glycol dialkyl ether, alcohols (a methanol --), such as the polypropylene-glycol dialkyl ether Ethanol, ethylene glycol monoalkyl ether, propylene-glycol monoalkyl ether, Polyethylene-glycol monoalkyl ether, polypropylene-glycol monoalkyl ether, etc., polyhydric alcohol (ethylene glycol, a propylene glycol, and a polyethylene glycol --) nitryl compounds (an acetonitrile --), such as a polypropylene glycol and a glycerol Guru taro dinitrile, a methoxy acetonitrile, a propionitrile, Ester (a carboxylate, phosphoric ester, phosphonate, etc.), such as a benzonitrile and screw cyano ethyl ether, non-proton nature polar solvents (dimethyl sulfoxide (DMSO), sulfolane, etc.), water, etc. are mentioned. Especially, a carbonate compound, a nitryl compound, and a heterocyclic compound are desirable. These solvents may mix and use two or more sorts if needed.

[0083] (G) In addition, to the first of this invention, and second electrolyte constituents, it is desirable to add basic compounds, such as t-butyl pyridine [of a publication (1997)], 2-picoline, 2, and 6-lutidine, to J.Am.Ceram.Soc., 80 (12), 3157-3171, etc. The desirable density ranges in the case of adding a basic compound are 0.05-2M.

[0084] In order to gel the first and second electrolyte constituents, technique, such as a polymerization of the monomers containing polymer addition, oil gelling agent addition, and polyfunctional monomer and crosslinking reaction of polymer, can be used together. When making it gel by polymer addition, the compound of a publication etc. is usable to "Polymer Electrolyte Reviews -1 and 2" (coeditorship of J.R.MacCallum and C.A.Vincent, ELSEVIER APPLIED SCIENCE), and it is desirable to use a polyacrylonitrile or a polyvinylidene fluoride. When making it gel by oil gelling agent addition, J.Chem.Soc.Japan, Ind.Chem.Sec., 46, and 779 (1943), J.Am.Chem.Soc., 111, and 5542 (1989), J.Chem.Soc., Chem.Commun., 1993, 390, Angew.Chem.Int.Ed.Engl., 35, and 1949 (1996), It is desirable to use the compound which can use the compound indicated by Chem.Lett., 1996, 885, J.Chem.Soc., Chem.Commun., 1997, and 545 grades, and has amide structure. Moreover, the method of gelling the electrolytic solution given in JP,11-185863,A and the method of gelling the quality of molten salt electrolytic constituent is made to gel by the crosslinking reaction of polymer -- JP,2000-17076,A -- said -- the cross linking technique indicated by 2000-86724 is also applicable

[0085] [2] The optoelectric transducer of an optoelectric-transducer this invention has a conductive layer, a photosensitive layer, a charge transporting bed, and a counter electrode. As preferably shown in drawing 1, a laminating is carried out to the order of a conductive layer 10, an under coat 60, a photosensitive layer 20, the charge transporting bed 30, and the counter electrode conductive layer 40, and a photosensitive layer 20 consists of charge transportation material 23 which permeated the opening between the semiconductor particle 21 by which sensitization was carried out with coloring matter 22, and the semiconductor particle 21 concerned. The charge transportation material 23 consists of the same component as the material used for the charge transporting bed 30. Moreover, in order to give intensity to an optoelectric transducer, you may form a substrate 50 as a ground of a conductive layer 10 and/or the counter electrode conductive layer 40. In this invention, it is arbitrary and the layer which consists the layer which consists of a conductive layer 10 and a substrate 50 to prepare of "a conductive base material", a counter electrode conductive layer 40, and a substrate 50 that it is arbitrary and is prepared is called "counter electrode." In addition, the conductive layer 10 in drawing 1, the counter electrode conductive layer 40, and a substrate 50 may be transparent conductive-layer 10a, transparent counter electrode conductive-layer 40a, and transparent substrate 50a, respectively. That to which this optoelectric transducer is connected to an external load, and 6/3/2003 http://www4.ipdl.jpo.go.jp/cgi-bin/tran_web_cgi_ejje

electric work (power generation) is done is a photoelectric cell, and it is the photosensor which was made for the purpose of sensing of optical information.

[0086] In the optoelectric transducer of this invention shown in drawing 1, when a semiconductor particle is n type, the light which carried out incidence to the photosensitive layer 20 containing the semiconductor particle 21 by which sensitization was carried out with coloring matter 22 excites coloring matter 22, and the electron of the high energy in the excited coloring matter 22 is passed to the conduction band of the semiconductor particle 21, and it reaches a conductive layer 10 by diffusion further. At this time, coloring matter 22 serves as an oxidant. In a photoelectric cell, while the electron in a conductive layer 10 works in an external circuit, it returns to the oxidant of coloring matter 22 through the counter electrode conductive layer 40 and the charge transporting bed 30, and coloring matter 22 is reproduced. A photosensitive layer 20 works as a negative electrode (optical anode), and a counter electrode 40 commits it as a positive electrode. On the boundaries (for example, the boundary of a conductive layer 10 and a photosensitive layer 20, the boundary of a photosensitive layer 20 and the charge transporting bed 30, the boundary of the charge transporting bed 30 and the counter electrode conductive layer 40, etc.) of each layer, the constituents of each class may be carrying out diffusive mixing mutually. Hereafter, each class is explained in detail. [0087] (A) A conductive base material conductivity base material consists of the monolayer of (1) conductive layer or (2) conductive layers, and two-layer [of a substrate]. In the case of (1), that at which intensity and sealing performance are fully maintained as a material of a conductive layer can be used, for example, it can use metallic materials (platinum, gold, silver, copper, zinc, titanium, aluminum, these alloys, etc.). In the case of (2), the substrate which has a conductive layer containing an electric conduction agent can be used for a photosensitive-layer side. As a desirable electric conduction agent, metals (for example, platinum, gold, silver, copper, zinc, titanium, aluminum, an indium, the alloy containing these, etc.), carbon, and conductive metallic oxides (what doped a fluorine or antimony to an indium-tin multiple oxide and the tin oxide) are mentioned. The thickness of a conductive layer has desirable about 0.02-10 micrometers.

[0088] A conductive base material has surface electrical resistance as good as a low. Surface electrical resistance is below 50ohms / ** preferably, and is below 20ohms / ** more preferably. [0089] When irradiating light from a conductive base material side, as for a conductive base material, it is desirable that it is substantially transparent. It means substantially that a light transmittance is it 10% or more that it is transparent in some or the whole region of a visible - near infrared region (400-1200nm). As for this light transmittance, it is desirable that it is 50% or more, and it is more desirable that it is 80% or more. It is desirable that the light transmittance of the wavelength region where a photosensitive layer has sensitivity especially is high.

[0090] What formed the transparent conductive layer which consists of a conductive metallic oxide in the front face of transparent substrates, such as glass and plastics, by an application or vacuum evaporationo as a transparent conductivity base material is desirable. As for a transparent conductive layer, it is desirable to consist of diacid-ized tin which doped a fluorine or antimony, or an indiumstannic-acid ghost (ITO). In addition to glass substrates, such as an advantageous soda glass and an alkali free glass without the influence of alkali elution, as a transparent substrate, a transparent polymer film is usable in respect of cost and intensity. As a material of a transparent polymer film, a triacetyl-cellulose (TAC), polyethylene-terephthalate (PET), polyethylenenaphthalate (PEN), syndiotactic polystyrene (SPS), polyphenylene-sulfide (PPS), polycarbonate (PC), polyarylate (PAr), polysulfone (PSF), polyester sulfone (PES), polyimide (PI), polyether imide (PEI), annular polyolefine, and bromine-ized phenoxy etc. is usable. In order to secure sufficient transparency, as for the coverage of a conductive metallic oxide, it is desirable to consider as per [0.01-100g] two 1m of

[0091] It is desirable to use a metal lead in order to lower resistance of a transparent conductivity base material. The quality of the material of a metal lead has desirable metals, such as platinum, gold, nickel, titanium, aluminum, copper, and silver. As for a metal lead, it is desirable to install in a transparent substrate by vacuum evaporationo, sputtering, etc., and to prepare on it the transparent conductive layer which consists of conductive tin oxide or ITO. The fall of the amount of incident lights by metal lead installation is more preferably suppressed to 1 - 5% less than 10%.

[0092] (B) As for a photosensitive-layer (1) semiconductor photosensitive layer, it is desirable to contain the semiconductor particle by which sensitization was carried out with coloring matter. In a photosensitive layer, a semiconductor acts as a photo conductor, absorbs light, performs charge separation, and produces an electron and an electron hole. With the semiconductor by which coloring matter sensitization was carried out, generating of an optical absorption, the electron by this, and an electron hole takes place mainly in coloring matter, and a semiconductor bears the role which receives and transmits this electron (or electron hole). As for the semiconductor used by this invention, it is desirable that it is the n-type semiconductor which a conductor electron serves as a carrier under optical pumping, and gives an anode current.

[0093] The compounds (a strontium titanate, titanic-acid calcium, titanic-acid sodium, a barium titanate, niobic-acid potassium, etc.) which have an element semiconductor like silicon or germanium, a III-V system compound semiconductor, metaled chalcogenide (an oxide, a sulfide, selenides, those composites, etc.), and a perovskite structure as an example of the semiconductor used by this invention are mentioned. Metal chalcogenide is desirable especially.

[0094] As desirable metal chalcogenide, the oxide of titanium, tin, zinc, iron, a tungsten, a zirconium, a hafnium, strontium, an indium, a cerium, an yttrium, a lanthanum, vanadium, niobium, or a tantalum, cadmium, zinc, lead, silver, antimony or the sulfide of a bismuth, cadmium or a leaden selenide, the telluride of cadmium, etc. are mentioned. As other compound semiconductors, the selenide of phosphides, such as zinc, a gallium, an indium, and cadmium, a gallium arsenide, or a copper-indium, the sulfide of a copper-indium, etc. are mentioned. Furthermore, a composite like MxOySz or M1xM2yOz (an oxygen atom, x, and y and z express the number [atom / metal] with which M, M1, and M2 become, and, as for O, a valence becomes neutral, respectively) can also be used preferably.

[0095] Preferably the semiconductor used by this invention Si, TiO2, SnO2, Fe 2O3, WO3, ZnO, Nb 2O5, CdS, ZnS and PbS, Bi2S3, CdSe, CdTe, It is SrTiO3, GaP, InP, GaAs, CuInS2, or CuInSe2. More preferably TiO2, SnO2, Fe 2O3, WO3, ZnO, It is Nb 2O5, CdS and PbS, CdSe, SrTiO3 and InP, GaAs, CuInS2, or CuInSe2, is TiO2 or Nb 2O5 especially preferably, and is TiO2 most preferably. As for TiO2, it is desirable to include an anatase type crystal 70% or more, and it is more desirable that it is 100% anatase type crystal.

[0096] It is desirable to dope a metal in order to raise the electronic conductivity in a semiconductor. As a metal to dope, a divalent or trivalent metal is desirable. In order to prevent that a reverse current flows from a semiconductor to a charge transporting bed, it is also effective in a semiconductor to dope a univalent metal.

[0097] Although a single crystal or a polycrystal is sufficient as the semiconductor used for this invention, the polycrystal from a viewpoint of a manufacturing cost, raw-material reservation, and an energy pay back time is desirable. The amorphous portion may be included in part. As for a semiconductor, it is desirable to use as a porous membrane which consists of a semiconductor particle.

[0098] Generally the particle size of a semiconductor particle is the order of nm-mu m. As for the primary-particle mean particle diameter which asked for the projected area of a particle from the diameter when converting into a circle, it is desirable that it is 5-200nm, and it is more desirable that it is 8-100nm. Moreover, as for the mean particle diameter of the semiconductor particle in the dispersion liquid produced in order to apply on a conductive base material (aggregated particle), it is desirable that it is 0.01-30 micrometers. Two or more kinds of particles from which a particle size distribution differs may be mixed, it is desirable that the average size of a small particle is 25nm or less in this case, and it is more desirable that it is 10nm or less. Particle size is big, for example, it is also desirable to mix a semiconductor particle (100nm or more and about 300nm) in order to scatter an incident light and to raise the rate of optical capture.

[0099] You may mix and use two or more sorts of semiconductor particles from which a kind also differs. In such a case, as for one sort, it is desirable that they are TiO2, ZnO, Nb 2O5, or SrTiO3. As for another side, it is desirable that they are SnO2, Fe 2O3, or WO3. Especially, ZnO, SnO2, ZnO and WO3, ZnO, or the combination of SnO2 and WO3 is more desirable. When mixing and using two or more sorts of semiconductor particles, each particle size may differ. Especially the particle size of the

above Nb [TiO2, ZnO, and] 2O5 or SrTiO3 is large, and its small one is [the particle size of SnO2, Fe 2O3, or WO3] desirable. The large particle and large particle size of 100nm or more have [particle size] a desirable combination of a small particle 15nm or less.

[0100] a sol-gel method given [as a method of producing a semiconductor particle] in "the thinlayer-coating technology by the sol-gel method" (1995) etc. of the company (1998) of the "science of sol-gel method" AGUNE ** style of ********, and a technical-information association, and "composition of the monodisperse particle by the new synthesis method gel-sol method and size gestalt control" of Tadao Sugimoto -- wait -- the gel-sol method given in ****, the 35th volume, No. 9, 1012-1018 etc. pages (1996), Moreover, the method of producing an oxide for the chloride which Degussa developed by elevated-temperature hydrolysis in an acid hydrogen salt is also preferably

[0101] When a semiconductor particle is titanium oxide, each of above-mentioned sol-gel methods, gel-sol methods, and elevated-temperature adding-water part solution methods in the inside of the acid hydrogen salt of a chloride can be used preferably, and it is the Seino study further.

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EXAMPLE

[Example] Hereafter, although an example explains this invention still in detail, this invention is not limited to them.

[0145] 1. The manufacture inside of titanium-dioxide dispersion liquid. With 15g [of titanium-dioxide particles] (product [made from Japanese Aerosil], Degussa P-25), 45g [of water], 1g [of dispersants] (Aldrich make, Triton X-100), and a diameter of 0.5mm zirconia-beads (Nikkato Corp. make) 30g was put into the container made from stainless steel of 200ml of content volume which carried out Teflon (registered trademark) coating, and distributed processing was carried out by 1500rpm for 2 hours using the Sand-grinder mill (product made from eye MEKKUSU). Filtration removed zirconia beads from the obtained dispersion liquid. The mean particle diameter of the titanium-dioxide particle in the obtained dispersion liquid was 2.5 micrometers. In addition, particle size was measured in the master sizer made from MALVERN.

[0146] 2. The glass rod was used and the above-mentioned dispersion liquid were applied to the electric conduction side side of the electrically conductive glass (thing and surface-electrical-resistance about 30ohm/** which carried out cutting processing of the TCO glass [by Asahi Glass Co., Ltd.]-U at the 20mmx20mm size) which has the tin-oxide layer which doped the creation fluorine of TiO2 electrode which adsorbed coloring matter. The coverage of a semiconductor particle was taken as 20 g/m2. At that time, the adhesive tape was stretched to the part by the side of an electric conduction side (from an edge to 3mm), and it considered as the spacer, and glass was put in order and it applied eight sheets at a time at once so that an adhesive tape might come to ends. After the application, it exfoliated and the adhesive tape was air-dried for one day at the room temperature. Next, this glass was put into the electric furnace (muffle furnace FP-32 type made from Yamato Science), it calcinated for 30 minutes at 450 degrees C, and TiO2 electrode was obtained. It flooded with the ethanol solution (3x10-4 mol/l) of coloring matter R-1 for 3 hours, after taking out this electrode and cooling. TiO2 electrode which coloring matter dyed was washed and air-dried by ethanol, after being immersed in the 4-t-butyl pyridine for 15 minutes. The thickness of the obtained photosensitive layer was 6.5 micrometers.

[0147] 3. The acetonitrile solution containing the electrolyte salt MHIm of the photoelectrochemicalcell examples 1-7, the example 1 of comparison, and 20.5 mol/l using the electrolyte constituent containing the production 3-1. solvent of a photoelectrochemical cell (iodine salt of 1-methyl-3-hexyl imidazolium) and 0.05 mol [/l.] iodine was prepared, and the siloxane compound 1-4 was added to this. 10 mass % The siloxane compound made the [solvent + electrolyte salt + siloxane compound] 100 mass %, and used it here. It was made to sink into the crevice which piled up the platinum vacuum evaporationo glass of the coloring matter sensitization TiO2 electrode substrate (20mmx20mm) which produced the obtained solution as mentioned above, and the same size as this using capillarity, introduced into the TiO2 electrode, it closed by the epoxy system encapsulant, and the photoelectrochemical cell of an example 1 using the first electrolyte constituent of this invention was obtained. The photoelectrochemical cell of examples 2-7 using the first electrolyte constituent of this invention was obtained like the above-mentioned example 1 except having changed the solvent and the siloxane compound, as shown in the following table 1. Moreover, except not adding a siloxane compound, the photoelectrochemical cell of the example 1 of comparison was produced like the above-mentioned example 1, and the photoelectrochemical cell of the example 2 of comparison was produced like the above-mentioned example 1 except having changed to the siloxane compound 6/3/2003 http://www4.ipdl.jpo.go.jp/cgi-bin/tran_web_cgi_ejje

further and having added t-butyl pyridine. The coloring matter used for the photoelectrochemical cell of the above-mentioned examples 1-7 and the examples 1 and 2 of comparison, a siloxane compound and its mass ratio, an electrolyte salt and its concentration, the concentration of iodine, and a solvent are collectively shown in Table 1. In addition, AN in Table 1 expresses an acetonitrile, NMO expresses 3-methyl-2-oxazolidinone, PC expresses propylene carbonate, and MHIm expresses the iodine salt of 1-methyl-3-hexyl imidazolium. Moreover, the mass ratio of a siloxane compound is a mass ratio at the time of making a [solvent + electrolyte salt + siloxane compound] into 100 mass % [0148]

[Table 1]

l able l	<u> </u>	-	•	-	
光電気 化学電池	色素	シロキサン化合物 (質量%)	電解資塩 (mol/l)	ヨウ素 (mol/i)	溶媒
実施例1	R-1	1-4 (10)	MHIm (0.5)	0.05	AN
実施例2	R-1	1-4 (10)	MHIm (0.5)	0.05	NMO
実施例3	R-1	1-4 (10)	MHIm (0.5)	0.05	PC
実施例4	R-1	1-6 (10)	MHlm (0.5)	0.05	AN
突旋倒6	R-1 R-1	1-11 (10)	MHIm (0.5)	0.05	AN
実施例7	R-1	1-13 (10)	MHIm (0.5)	0.05	AN
比较例1	R-1	1-17 (10) なし	MHIm (0.5)	0.05	AN
比較例2	R-1	£ブチルピリジン (10)	MiHim (0.5) MiHim (0.5)	0.05	AN
		7,72,727 (10)	marians (u.b)	0.05	AN

[0149] The acetonitrile solution containing the electrolyte salt MHIm of an example 8 - 170.5 mol/l (iodine salt of 1-methyl-3-hexyl imidazolium) and the iodine of 0.05 mol/l was prepared. The siloxane compound 1-4 was added to this solution, the electrophilic agent E-3 was mixed further, and the uniform solution was adjusted. Here, the siloxane compound made the [solvent + electrolyte salt + siloxane compound] 100 mass %, 10 mass % Used it, and it added the electrophilic agent so that the mole ratio of the electrophilic part of the electrophilic agent to the reactive site of a siloxane compound might be set to 1. It was made to sink into the crevice which piled up the platinum vacuum evaporationo glass of the coloring matter sensitization TiO2 electrode substrate (20mmx20mm) which produced the obtained solution as mentioned above, and the same size as this using capillarity, and introduced into the TiO2 electrode. This was left at 50 degrees C for 12 hours, polymerization reaction was performed, it closed by the epoxy system encapsulant, and the photoelectrochemical cell of an example 8 using the second electrolyte constituent of this invention was obtained. The photoelectrochemical cell of examples 9-14 using the second electrolyte constituent of this invention was obtained like the above-mentioned example 8 except having changed a solvent, a siloxane compound, and an electrophilic agent and its mole ratio, as shown in the following table 2. Moreover, it changed to what shows a siloxane compound in Table 2, and the photoelectrochemical cell of examples 15-17 using the second electrolyte constituent of this invention was obtained like the above-mentioned example 8 except having made the amount of the electrophilic agent used into 5 mass % to the siloxane compound. The coloring matter used for the photoelectrochemical cell of the above-mentioned examples 8-17, an electrophilic agent and its mole ratio, a siloxane compound and its mass ratio, an electrolyte salt and its concentration, the concentration of iodine, and a solvent are collectively shown in Table 2. In addition, AN in Table 2 expresses an acetonitrile, NMO expresses 3-methyl-2-oxazolidinone, PC expresses propylene carbonate, and MHIm expresses the iodine salt of 1-methyl-3-hexyl imidazolium. Moreover, among Table 2, the mass ratio of a siloxane compound is a mass ratio at the time of making a [solvent + electrolyte salt + siloxane compound] into 100 mass %, and the mole ratio of an electrophilic agent is a mole ratio of the electrophilic part of the electrophilic agent to the reactive site of a siloxane compound. However, not a mole ratio but the mass ratio (wt%) to a siloxane compound shows the amount of the electrophilic agent used used for the photoelectrochemical cell of examples 15-17. [0150]

[Table 2]

光電気 化学電池	色素	水電子和 (モル比又は質量比)	シロキサン化合物 (質量%)	電解質塩 (mol/l)	ョウ素 (mol/i)	溶媒
実施例8	R-1	E-3 (1)	1-4 (10)	MHIm (0.5)	0.05	AN
実施例9	R-1	E-3 (1)	1-4 (10)	MHIm (0.5)	0.05	NMO
実施例10	R-1	E-3 (1)	1-4 (10)	MHm (0.5)	0.05	PC
安施例11	R-1	E-3 (1)	1-6 (10)	MHIm (0.5)	0.05	AN
実施例12	R-1	E-12 (1)	1-4 (10)	MHtm (0.5)	0.05	AN
実施例13	R-1	E-12 (1)	1-6 (10)	MHIm (0.5)	0.05	AN
実施例14	R-1	E-3 (0.9), E-5 (0.1)	1-4 (10)	MHIm (0.5)	0.05	AN
	R-1	E-3 (5 wt%)	1-11 (10)	MH (0.5)	0.05	AN
実施例15		E-3 (5 w(%)	1-13 (10)	MHIm (0.5)	0.05	AN
実施例16	R-1	E-3 (5 wt%)	1-17 (10)	MHIm (0.5)	0.05	AN

[0151] The hexa ethylene glycol methacrylic ester ("BUREMMA PE-350" by the Nippon Oil & Fats chemistry company) of 3500mg of examples of comparison, 1g propylene carbonate, and the mixed liquor containing the 2mg polymerization initiator azobisuisobutironitoriru were prepared, and the 500mg iodation lithium was dissolved in this. Next, the vacuum deairing of this mixed liquor was carried out for 10 minutes, and it applied to the coloring matter sensitization TiO2 electrode substrate (20mmx20mm) produced as mentioned above. Then, after putting under reduced pressure of TiO2 electrode which applied mixed liquor and urging osmosis of a monomer except for the air bubbles in TiO2 electrode, at 60 degrees C, it heated for 1 hour and the polymerization was carried out. It **(ed) for 30 minutes under iodine atmosphere at the room temperature after the polymerization, and iodine was diffused in the obtained polymer. This was piled up with the counter electrode which deposited platinum, and the photoelectrochemical cell (photoelectrochemical cell using the electrolyte the Chemical Society of Japan, 7, and given in 484 page (1997)) of the example 3 of comparison was obtained.

[0152] 3-2. The fused salt A of the photoelectrochemical-cell examples 18-28 and the example 4 of comparison - 660 mass % using the electrolyte constituent containing room temperature fused salt, the fused salt B of 28 mass %, the iodine of 2 mass %, and the siloxane compound 1-4 of 10 mass % were mixed, and the uniform electrolyte constituent was prepared. After applying 5micro of obtained electrolyte constituents I to the coloring matter sensitization TiO2 electrode substrate produced as mentioned above, it put under reduced pressure of this electrode, and the electrolyte constituent was made to permeate. After the electrolyte constituent fully permeated and the air in an electrode fell out, platinum vacuum evaporationo glass was laid on top of this, and the photoelectrochemical cell of an example 18 using the first electrolyte constituent of this invention was obtained. The photoelectrochemical cell of examples 19-28 using the first electrolyte constituent of this invention was obtained like the above-mentioned example 18 except having changed fused salt, its mass ratio, and the siloxane compound, as shown in the following table 3. Moreover, don't add a siloxane compound but fused salt and its mass ratio should be shown in Table 3. Except having changed, the photoelectrochemical cell of the examples 4 and 5 of comparison was produced like the abovementioned example 18, it changed to the siloxane compound further, t-butyl pyridine was added, and the photoelectrochemical cell of the example 6 of comparison was produced like the abovementioned example 18 except having changed fused salt and its mass ratio, as shown in Table 3. However, the amount of t-butyl pyridine was made into 10 mass %. The coloring matter used for the photoelectrochemical cell of the above-mentioned examples 18-28 and the examples 4-6 of comparison, fused salt and its mass ratio, the mass ratio of iodine, a siloxane compound, and its mass ratio are collectively shown in Table 3. Moreover, the structure of fused salt A-D is shown below. [0153]

[Table 3]

光電気		溶融塩	ヨウ素	シロキサン化合物
化学管池	色素	(質量%)	(貴量%)	(黄量%)
実施例18	R-1	A (60) / B (28)	2	1-4 (10)
実施例19	R-1	A (60) / C (28)	2	1-4 (10)
実施例20	R-1	A (60) / C (28)	2	1-4 (10)
安施例21	R-1	A (60) / B (28)	2	1-8 (10)
実施例22	R-1	D (60) / C (28)	2	1-4 (10)
実施例23	R-1	D (60) / C (28)	2	1-4 (10)
実施例24	R-1	D (60) / C (28)	2	1-8 (10)
実施例25	R-1	D (60) / C (28)	2	1-4 (10)
実施例28	R-1	A (60) / C (28)	2	1-11 (10)
	+	 	/.	

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实施例27	R-1	A (60) / C (28)	2	1-13 (10)
実施例28	R-1	A (60) / C (28)	2	1-17 (10)
比较例4	R-1	A (70) / C (28)	2	\$L
比較例5	R-1	D (70) / C (28)	2	#L
比較例8	R-1	A (60) / C (28)	2	トプチルピリジン

[0154] [Formula 39]	CH Cy Cy Cy	s r
В ",	CH ₃	N(\$0 ₂ CF ₃) ₂
c	CH_3 $ \begin{bmatrix} N \\ N_+ \\ C_2H_5 \end{bmatrix} $	BF ₄
D		√ oei r

[0155] The fused salt A of an example 29 - 3960 mass %, the fused salt B of 28 mass %, the iodine of 2 mass %, and the siloxane compound 1-4 of 10 mass % were mixed, the electrophilic agent E-3 was added further, and the uniform electrolyte constituent was prepared. Here, the electrophilic agent was added so that the mole ratio of the electrophilic part of the electrophilic agent to the reactive site of a siloxane compound might be set to 1. After applying 5micro of obtained electrolyte constituents I to the coloring matter sensitization TiO2 electrode substrate produced as mentioned above, it put under reduced pressure of this electrode, and the electrolyte constituent was made to permeate. After the electrolyte constituent fully permeated and the air in an electrode fell out, platinum vacuum evaporationo glass was laid on top of this, it was left at 50 degrees C for 10 hours, polymerization reaction was performed, and the photoelectrochemical cell of an example 29 using the second electrolyte constituent of this invention was obtained. The photoelectrochemical cell of examples 30-39 using the second electrolyte constituent of this invention was obtained like the above-mentioned example 29 except having changed fused salt, siloxane compounds and those mass ratios, and an electrophilic agent and its mole ratio, as shown in the following table 4. The coloring matter used for the photoelectrochemical cell of the above-mentioned examples 29-39, fused salt and its mass ratio, the mass ratio of iodine, an electrophilic agent, its mole ratio, a siloxane compound, and its mass ratio are collectively shown in Table 4. In addition, the mole ratio of an electrophile agent is a mole ratio of the electrophilic part of the electrophile agent to the reactive site of a siloxane compound among

[0156]

[Table 4]

光電気 化学電池	色素	溶散塩 (質量%)	ヨウ素 (質量%)	求電子剤 (モル比)	シロキサン化合物 (質量%)
安施例29	R-1	A (60) / B (28)	2	E-3 (1)	1-4 (10)
	R-1	A (80) / C (28)	2	E3 (1)	1-4 (10)
実施例30	_	A (60) / C (28)	2	E-12 (1)	1-4 (10)
実施例31	R-1		2	E-3 (1)	1-6 (10)
実施例32	R-1	A (60) / B (28)	2	E-3 (1)	1-4 (10)
実施例33	R-1	D (60) / C (28)	2	E-12 (1)	1-4 (10)
実施例34	R-1	D (60) / C (28)	2	E-3 (1)	1-8 (10)
実施例35	R-1	D (60) / C (28)		E-3 (0.9), E-5 (0.1)	1-4 (10)
実施例38	R-1	D (60) / C (28)	2		1-11 (10)
賽施例37	R-1	A (60) / C (28)	2	E3 (1)	1-13 (10)
実施例38	R-1	A (60) / C (28)	2	E-3 (1)	
実施例39	R-1	A (60) / C (28)	2	E-3 (1)	1-17 (10)

[0157] The photoelectrochemical cell of the example 7 of comparison was produced like the above-mentioned example 3 of comparison except having changed to example of comparison 7 propylene carbonate, and having used the above-mentioned compound C.

[0158] 4. The simulation sunlight which does not include ultraviolet rays was generated by letting AM1.5 filter (product made from Oriel), and a sharp cut filter (Kenko L-42) pass for the light of the xenon lamp of measurement 500W of a photoelectric conversion efficiency (product made from USHIO Electrical and electric equipment). This luminous intensity was 86 mW/cm2. The electrical and electric equipment which irradiated the photoelectrochemical cell of the examples 1-39 produced at 50 degrees C and the examples 1-7 of comparison, and generated this simulation sunlight was measured in the current-potential measuring device (case rhe SMU238 type). The decreasing rate of the short-circuit current density (Jsc) of each photoelectrochemical cell called for by this, an open circuit voltage (Voc), a form factor (FF), a conversion efficiency (eta), and the conversion efficiency after 360-hour continuous irradiation is shown in Tables 5-8.

[Table 5]

光電気	恒絡電流密度	開放電圧 (Voc)	形状因子	変換効率 (7)	7低下率 (360時間後)
化学程池	(Jsc) mA/cm²	V	(FF)	% 5.24	78
実施例1	10.1	0.72	0.62	4.98	78
実施例2	9.75	0.72	0,62	5.20	77
実施例3	9.89	0.72	0.81	5.21	78
実施例4 実施例5	9.62	0.73	0.60	4.90	78
実施例6	9.43	0.74	0.61	4.92	77
実施例7	9.67	0.73 0.85	0.65	4.87	99
比較例1 比較例2	9,42	0.72	0.81	4.81	99

[0160] [Table 6]

	-		1	変換効率	7個下學
光電気 化学電池	短格電流密度 (Jsc)	開放電圧 (Voc)	排状因子 (FF)	(η) 96	(380時間後) %
16-1-46	mA/cm ²	- O CO	0.57	4.11	42
安施例8	9.12	0.68	0.58	3,86	36
実施例9	8.97	0.67	0.56	3.82	35
実施例10	8.89	0.67	0.57	3.98	41
実施例11	9.10	0.68		4.04	37
実施例12	9.12	0.68	0.58	3.91	33
実施例13		0.66	0.56	3.97	29
実施例14		0.67	0.58	3.40	33
実施例15		0.68	0.58		35
実施例16		0.69	0.57	3.47	37
		0.68	0.57	3.58	
実施例17 比较例3	2.22	0.64	0.65	1.07	62

[0161] [Table 7]

光電気 化学電池	短絡電流密度 (Jsc) mA/cm²	競放電圧 (Voc) V	影状因子 (FF)	変換効率 (カ)	7低下率 (380時間後)
実施例18	9.11	0.61	0.57	96	96
実施例19	9.08	0.62	0.58	3.68	18
突施例20	9.20	0.62		3.80	18
実施例21	9.11		0.58	3.85	18
実施例22	9.28	0.60	0.58	3.69	17
		0.60	0.57	3.69	17
实施例23	9.14	0.60	0.58	3.70	18
实施例24	9.13	0.61	0.57	3.69	
実施例25	9.09	0.61	0.58	3.74	16
実施例26	8.10	0.62	0.58		14
奥施例27	8.99	0.60		3.39	15
実施例28	8.98		0.57	3.58	16
比較例4		0.61	0.57	3.63	15
	7.85	0.52	0.58	2.75	35
比較例5	7.90	0.55	0.59	2.98	30
比較例8	7.20	0.62	0.56	2.91	
				2.71	45

[0162] [Table 8]

光體気 化学電池	短絡電波密度 (Jsc) mA/cm ²	開放電圧 (Voc) V	形状因子 (FF)	変換効率 (7)	カ低下率 (380時間後)
実施例29	8.11	0.57	0.55	96	96
実施例30	8.20	0.59	0.55	2.96	18
実施例31	8.20	0.59		3.09	18
実施例32	8.09	0.55	0.54	3.03	16
実施例33	8.28		0.55	2.85	17
実施例34	8.28	0.80	0.55	3.18	17
実施例35		0.61	0.54	3.17	16
実施例36	8.25	0.58	0.55	3.08	16
	8.27	0.58	0.54	3,01	14
実施例37	8.01	0.60	0.55	2.64	15
美施例38	7.11	0.61	0.54	2.72	
実施例39	7.05	0.60	0.54	2.68	14
比較例7	1.40	0.52	0.50		15
				0.42	14

[0163] To this causing [the open circuit voltage] a low photoelectric conversion efficiency low, as for the photoelectrochemical cell of the examples 1, 4, and 5 of comparison, an open circuit voltage is high and the conversion efficiency of the photoelectrochemical cell [the examples 1-7 and the photoelectrochemical cell of 18-28] using the first electrolyte constituent of this invention is improving in connection with it so that more clearly than Table 5 and 7. Moreover, although degradation after dark place preservation is remarkable in the photoelectrochemical cell of the examples 1 and 2 of comparison which contain many organic solvents in an electrolyte constituent, and examples 1-7, by using the first electrolyte constituent of this invention shows that endurance is improved. Moreover, Table 6 and 8 shows that the examples 8-17 and the photoelectrochemical cell of 29-39 using the second electrolyte constituent of this invention show the outstanding conversion efficiency and outstanding endurance as compared with the photoelectrochemical cell of the examples 3 and 7 of comparison using the conventional solid electrolyte.

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DESCRIPTION OF DRAWINGS

[Brief Description of the Drawings]

[Drawing 1] It is the fragmentary sectional view showing the structure of the desirable optoelectric transducer of this invention.

[Drawing 2] It is the fragmentary sectional view showing the structure of the desirable optoelectric transducer of this invention.

[Drawing 3] It is the fragmentary sectional view showing the structure of the desirable optoelectric transducer of this invention.

[Drawing 4] It is the fragmentary sectional view showing the structure of the desirable optoelectric transducer of this invention.

[Drawing 5] It is the fragmentary sectional view showing the structure of the desirable optoelectric transducer of this invention.

[Drawing 6] It is the fragmentary sectional view showing the structure of the desirable optoelectric transducer of this invention.

[Drawing 7] It is the fragmentary sectional view showing the structure of the desirable optoelectric transducer of this invention.

[Drawing 8] It is the fragmentary sectional view showing the structure of the desirable optoelectric transducer of this invention.

[Description of Notations]

10 ... Conductive layer

10a ... Transparent conductive layer

11 ... Metal lead

20 ... Photosensitive layer

21 ... Semiconductor particle

22 ... Coloring matter

23 ... Charge transportation material

30 ... Charge transporting bed

40 ... Counter electrode conductive layer

40a ... Transparent counter electrode conductive layer

50 ... Substrate

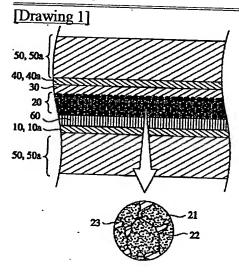
50a ... Transparent substrate

60 ... Under coat

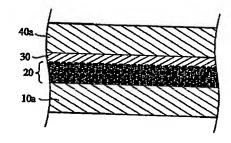
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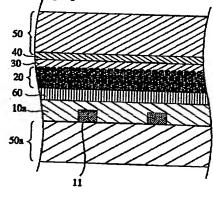
DRAWINGS



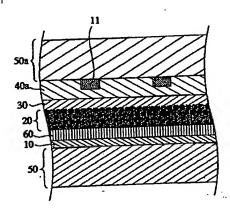
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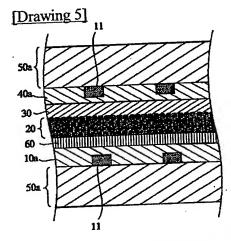


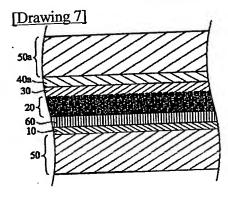
[Drawing 3]

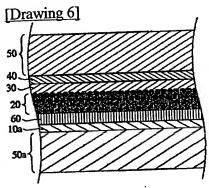


[Drawing 4]









[Drawing 8]

